

TM), European (AL, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HR, HU, IE, IS, IT, LT, LU, LV, MC, MK, MT, NL, NO, PL, PT, RO, RS, SE, SI, SK, SM, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, KM, ML, MR, NE, SN, TD, TG).

Published:

— *with international search report (Art. 21(3))*

ADAPTIVE BIAS DECODER FOR ANALOG NEURAL MEMORY ARRAY IN ARTIFICIAL NEURAL NETWORK

PRIORITY CLAIMS

[0001] This application claims priority to U.S. Provisional Patent Application No. 63/048,470, filed on July 6, 2020, and titled, "Adaptive Bias Decoder for Analog Neural Memory Array in Artificial Neural Network With Source Line Pulldown Mechanism," and U.S. Patent Application No. 17/140,924, filed on January 4, 2021, and titled "Adaptive Bias Decoder for Analog Neural Memory Array in Artificial Neural Network."

FIELD OF THE INVENTION

[0002] Numerous embodiments of analog neural memory arrays are disclosed.

BACKGROUND OF THE INVENTION

[0003] Artificial neural networks mimic biological neural networks (the central nervous systems of animals, in particular the brain) and are used to estimate or approximate functions that can depend on a large number of inputs and are generally unknown. Artificial neural networks generally include layers of interconnected "neurons" which exchange messages between each other.

[0004] Figure 1 illustrates an artificial neural network, where the circles represent the inputs or layers of neurons. The connections (called synapses) are represented by arrows, and have numeric weights that can be tuned based on experience. This makes the artificial neural network adaptive to inputs and capable of learning. Typically, artificial neural networks include a layer of multiple inputs. There are typically one or more intermediate layers of neurons, and an output layer of neurons that provide the output of the neural network. The neurons at each level individually or collectively make a decision based on the received data from the synapses.

[0005] One of the major challenges in the development of artificial neural networks for high-performance information processing is a lack of adequate hardware technology. Indeed, practical artificial neural networks rely on a very large number of synapses, enabling high

Attorney Docket Number: 351913-980132

connectivity between neurons, i.e. a very high computational parallelism. In principle, such complexity can be achieved with digital supercomputers or specialized graphics processing unit clusters. However, in addition to high cost, these approaches also suffer from mediocre energy efficiency as compared to biological networks, which consume much less energy primarily because they perform low-precision analog computation. CMOS analog circuits have been used for artificial neural networks, but most CMOS-implemented synapses have been too bulky given the high number of neurons and synapses.

[0006] Applicant previously disclosed an artificial (analog) neural network that utilizes one or more non-volatile memory arrays as the synapses in U.S. Patent Application No. 15/594,439, published as US Patent Publication 2017/0337466, which is incorporated by reference. The non-volatile memory arrays operate as an analog neuromorphic memory. The term neuromorphic, as used herein, means circuitry that implement models of neural systems. The analog neuromorphic memory includes a first plurality of synapses configured to receive a first plurality of inputs and to generate therefrom a first plurality of outputs, and a first plurality of neurons configured to receive the first plurality of outputs. The first plurality of synapses includes a plurality of memory cells, wherein each of the memory cells includes spaced apart source and drain regions formed in a semiconductor substrate with a channel region extending there between, a floating gate disposed over and insulated from a first portion of the channel region and a non-floating gate disposed over and insulated from a second portion of the channel region. Each of the plurality of memory cells is configured to store a weight value corresponding to a number of electrons on the floating gate. The plurality of memory cells is configured to multiply the first plurality of inputs by the stored weight values to generate the first plurality of outputs. An array of memory cells arranged in this manner can be referred to as a vector by matrix multiplication (VMM) array.

[0007] Examples of different non-volatile memory cells that can be used in VMMs will now be discussed.

Non-Volatile Memory Cells

[0008] Various types of known non-volatile memory cells can be used in the VMM arrays. For example, U.S. Patent 5,029,130 (“the ’130 patent”), which is incorporated herein by reference,

Attorney Docket Number: 351913-980132

discloses an array of split gate non-volatile memory cells, which are a type of flash memory cells. Such a memory cell 210 is shown in Figure 2. Each memory cell 210 includes source region 14 and drain region 16 formed in semiconductor substrate 12, with channel region 18 there between. Floating gate 20 is formed over and insulated from (and controls the conductivity of) a first portion of the channel region 18, and over a portion of the source region 14. Word line terminal 22 (which is typically coupled to a word line) has a first portion that is disposed over and insulated from (and controls the conductivity of) a second portion of the channel region 18, and a second portion that extends up and over the floating gate 20. The floating gate 20 and word line terminal 22 are insulated from the substrate 12 by a gate oxide. Bitline terminal 24 is coupled to drain region 16.

[0009] Memory cell 210 is erased (where electrons are removed from the floating gate) by placing a high positive voltage on the word line terminal 22, which causes electrons on the floating gate 20 to tunnel through the intermediate insulation from the floating gate 20 to the word line terminal 22 via Fowler-Nordheim tunneling.

[0010] Memory cell 210 is programmed (where electrons are placed on the floating gate) by placing a positive voltage on the word line terminal 22, and a positive voltage on the source region 14. Electron current will flow from the drain region 16 towards the source region 14 (source line terminal). The electrons will accelerate and become energized (heated) when they reach the gap between the word line terminal 22 and the floating gate 20. Some of the heated electrons will be injected through the gate oxide onto the floating gate 20 due to the attractive electrostatic force from the floating gate 20.

[0011] Memory cell 210 is read by placing positive read voltages on the drain region 16 and word line terminal 22 (which turns on the portion of the channel region 18 under the word line terminal). If the floating gate 20 is positively charged (i.e. erased of electrons), then the portion of the channel region 18 under the floating gate 20 is turned on as well, and current will flow across the channel region 18, which is sensed as the erased or “1” state. If the floating gate 20 is negatively charged (i.e. programmed with electrons), then the portion of the channel region under the floating gate 20 is mostly or entirely turned off, and current will not flow (or there will be little flow) across the channel region 18, which is sensed as the programmed or “0” state.

Attorney Docket Number: 351913-980132

[0012] Table No. 1 depicts typical voltage ranges that can be applied to the terminals of memory cell 110 for performing read, erase, and program operations:

Table No. 1: Operation of Flash Memory Cell 210 of Figure 2

	WL	BL	SL
Read 1	0.5-3V	0.1-2V	0V
Read 2	0.5-3V	0-2V	2-0.1V
Erase	~11-13V	0V	0V
Program	1-2V	1-3 μ A	9-10V

“Read 1” is a read mode in which the cell current is output on the bit line. “Read 2” is a read mode in which the cell current is output on the source line terminal.

[0013] Figure 3 shows memory cell 310, which is similar to memory cell 210 of Figure 2 with the addition of control gate (CG) terminal 28. Control gate terminal 28 is biased at a high voltage, e.g., 10V, in programming, low or negative in erase, e.g., 0v/-8V, low or mid range in read, e.g., 0v/2.5V. Other terminals are biased similarly to that of Figure 2.

[0014] Figure 4 depicts four-gate memory cell 410 comprising source region 14, drain region 16, floating gate 20 over a first portion of channel region 18, a select gate 22 (typically coupled to a word line, WL) over a second portion of the channel region 18, a control gate 28 over the floating gate 20, and an erase gate 30 over the source region 14. This configuration is described in U.S. Patent 6,747,310, which is incorporated herein by reference for all purposes. Here, all gates are non-floating gates except floating gate 20, meaning that they are electrically connected or connectable to a voltage source. Programming is performed by heated electrons from the channel region 18 injecting themselves onto the floating gate 20. Erasing is performed by electrons tunneling from the floating gate 20 to the erase gate 30.

[0015] Table No. 2 depicts typical voltage ranges that can be applied to the terminals of memory cell 410 for performing read, erase, and program operations:

Attorney Docket Number: 351913-980132

Table No. 2: Operation of Flash Memory Cell 410 of Figure 4

	WL/SG	BL	CG	EG	SL
Read 1	0.5-2V	0.1-2V	0-2.6V	0-2.6V	0V
Read 2	0.5-2V	0-2V	0-2.6V	0-2.6V	2-0.1V
Erase	-0.5V/0V	0V	0V/-8V	8-12V	0V
Program	1V	1 μ A	8-11V	4.5-9V	4.5-5V

“Read 1” is a read mode in which the cell current is output on the bit line. “Read 2” is a read mode in which the cell current is output on the source line terminal.

[0016] Figure 5 shows memory cell 510, which is similar to memory cell 410 of Figure 4 except that memory cell 510 does not contain an erase gate EG terminal. An erase is performed by biasing the substrate 18 to a high voltage and biasing the control gate CG terminal 28 to a low or negative voltage. Alternatively, an erase is performed by biasing word line terminal 22 to a positive voltage and biasing control gate terminal 28 to a negative voltage. Programming and reading is similar to that of Figure 4.

[0017] Figure 6 depicts a three-gate memory cell 610, which is another type of flash memory cell. Memory cell 610 is identical to the memory cell 410 of Figure 4 except that memory cell 610 does not have a separate control gate terminal. The erase operation (whereby erasing occurs through use of the erase gate terminal) and read operation are similar to that of the Figure 4 except there is no control gate bias applied. The programming operation also is done without the control gate bias, and as a result, a higher voltage must be applied on the source line terminal during a program operation to compensate for a lack of control gate bias.

[0018] Table No. 3 depicts typical voltage ranges that can be applied to the terminals of memory cell 610 for performing read, erase, and program operations:

Table No. 3: Operation of Flash Memory Cell 610 of Figure 6

	WL/SG	BL	EG	SL
Read 1	0.5-2.2V	0.1-2V	0-2.6V	0V

Attorney Docket Number: 351913-980132

Read 2	0.5-2.2V	0-2V	0-2.6V	2-0.1V
Erase	-0.5V/0V	0V	11.5V	0V
Program	1V	2-3 μ A	4.5V	7-9V

“Read 1” is a read mode in which the cell current is output on the bit line. “Read 2” is a read mode in which the cell current is output on the source line terminal.

[0019] Figure 7 depicts stacked gate memory cell 710, which is another type of flash memory cell. Memory cell 710 is similar to memory cell 210 of Figure 2, except that floating gate 20 extends over the entire channel region 18, and control gate terminal 22 (which here will be coupled to a word line) extends over floating gate 20, separated by an insulating layer (not shown). Programming is performed using hot electron injection from channel 18 to floating gate 20 in the channel region next to the drain region 16, and erasing is performed using by Fowler-Nordheim electron tunneling from floating gate 20 to substrate 12. The read operations operate in a similar manner to that described previously for memory cell 210.

[0020] Table No. 4 depicts typical voltage ranges that can be applied to the terminals of memory cell 710 and substrate 12 for performing read, erase, and program operations:

Table No. 4: Operation of Flash Memory Cell 710 of Figure 7

	CG	BL	SL	Substrate
Read 1	0-5V	0.1 – 2V	0-2V	0V
Read 2	0.5-2V	0-2V	2-0.1V	0V
Erase	-8 to -10V/0V	FLT	FLT	8-10V / 15-20V
Program	8-12V	3-5V/0V	0V/3-5V	0V

[0021] “Read 1” is a read mode in which the cell current is output on the bit line. “Read 2” is a read mode in which the cell current is output on the source line terminal. Optionally, in arrays comprising rows and columns of memory cells 210, 310, 410, 510, 610, or 710, source lines can

Attorney Docket Number: 351913-980132

be coupled to one row of memory cells or to two adjacent rows of memory cells. That is, source line terminals can be shared by adjacent rows of memory cells.

[0022] Figure 8 depicts twin split-gate memory cell 810. Memory cell 810 comprises floating gate (FG) 20 disposed over and insulated from the substrate 12, a control gate 28 (CG) disposed over and insulated from the floating gate 20, an erase gate 30 (EG) disposed adjacent to and insulated from the floating and control gates 20/28 and disposed over and insulated from the substrate 12, where the erase gate is created with a T shape such that a top corner of the control gate CG faces the inside corner of the T shaped erase gate to improve erase efficiency, and a drain region 16 (DR) in the substrate adjacent the floating gate 20 (with a bit line contact 24 (BL) connected to the drain diffusion regions 16 (DR)). The memory cells are formed as pairs of memory cells (A on the left and B on the right), sharing a common erase gate 30. This cell design differs from that the memory cells discussed above with reference to Figures 2-7 at least in that it lacks a source region under the erase gate EG, lacks a select gate (also referred to as a word line), and lacks a channel region for each memory cell. Instead, a single continuous channel region 18 extends under both memory cells (i.e. extends from the drain region 16 of one memory cell to the drain region 16 of the other memory cell). To read or program one memory cell, the control gate 28 of the other memory cell is raised to a sufficient voltage to turn on the underlying channel region portion via voltage coupling to the floating gate 20 there between (e.g. to read or program cell A, the voltage on FGB is raised via voltage coupling from CGB to turn on the channel region portion under FGB). Erasing is performed using Fowler Nordheim electron tunneling from floating gate 20 to erase gate 30. Programming is performed using hot electron injection from channel 18 to floating gate 20, this is indicated as PROGRAM 1 in Table 5. Alternatively programming is performed using Fowler Nordheim electron tunneling from erase gate 30 to floating gate 20, this is indicated as PROGRAM 2 in Table 5. Alternatively programming is performed using Fowler Nordheim electron tunneling from channel 18 to floating gate 20, in this case the condition is similar to PROGRAM 2 except the substrate is biased at a low voltage or negative voltage while erase gate is biased at a low positive voltage.

[0023] Table No. 5 depicts typical voltage ranges that can be applied to the terminals of memory cell 810 for performing read, erase, and program operations:

Attorney Docket Number: 351913-980132

Table No. 5: Operation of Flash Memory Cell 810 of Figure 8

	CGA	BLA	EG	CGB	BLB
READ	1.5-4V	0.1-0.8V	2.5V	1.5-4V	0
ERASE	0 V to -8V	0V	8V to 11.5V	0 V to 4V (V _{cginhe})	0V
PROGRAM 1	10.5V	4.5V	1.5V	4	I _{prog}
PROGRAM 2	4V to 11.5V	0V	-4V to -11.5V	0 V to -2V (V _{cginhp})	0V

[0024] In order to utilize the memory arrays comprising one of the types of non-volatile memory cells described above in an artificial neural network, two modifications are made. First, the lines are configured so that each memory cell can be individually programmed, erased, and read without adversely affecting the memory state of other memory cells in the array, as further explained below. Second, continuous (analog) programming of the memory cells is provided.

[0025] Specifically, the memory state (i.e. charge on the floating gate) of each memory cell in the array can be continuously changed from a fully erased state to a fully programmed state, independently and with minimal disturbance of other memory cells. In another embodiment, the memory state (i.e., charge on the floating gate) of each memory cell in the array can be continuously changed from a fully programmed state to a fully erased state, and vice-versa, independently and with minimal disturbance of other memory cells. This means the cell storage is analog or at the very least can store one of many discrete values (such as 16 or 64 different values), which allows for very precise and individual tuning of all the cells in the memory array, and which makes the memory array ideal for storing and making fine tuning adjustments to the synapsis weights of the neural network.

[0026] The methods and means described herein may apply to other non-volatile memory technologies such as FINFET split gate flash or stack gate flash memory, NAND flash, SONOS (silicon-oxide-nitride-oxide-silicon, charge trap in nitride), MONOS (metal-oxide-nitride-oxide-silicon, metal charge trap in nitride), ReRAM (resistive ram), PCM (phase change memory),

Attorney Docket Number: 351913-980132

MRAM (magnetic ram), FeRAM (ferroelectric ram), OTP (bi-level or multi-level one time programmable), and CeRAM (correlated electron ram), without limitation. The methods and means described herein may apply to volatile memory technologies used for neural network such as SRAM, DRAM, and other volatile synapse cells, without limitation.

Neural Networks Employing Non-Volatile Memory Cell Arrays

[0027] Figure 9 conceptually illustrates a non-limiting example of a neural network utilizing a non-volatile memory array of the present embodiments. This example uses the non-volatile memory array neural network for a facial recognition application, but any other appropriate application could be implemented using a non-volatile memory array based neural network.

[0028] S0 is the input layer, which for this example is a 32x32 pixel RGB image with 5 bit precision (i.e. three 32x32 pixel arrays, one for each color R, G and B, each pixel being 5 bit precision). The synapses CB1 going from input layer S0 to layer C1 apply different sets of weights in some instances and shared weights in other instances, and scan the input image with 3x3 pixel overlapping filters (kernel), shifting the filter by 1 pixel (or more than 1 pixel as dictated by the model). Specifically, values for 9 pixels in a 3x3 portion of the image (i.e., referred to as a filter or kernel) are provided to the synapses CB1, where these 9 input values are multiplied by the appropriate weights and, after summing the outputs of that multiplication, a single output value is determined and provided by a first synapse of CB1 for generating a pixel of one of the layers of feature map C1. The 3x3 filter is then shifted one pixel to the right within input layer S0 (i.e., adding the column of three pixels on the right, and dropping the column of three pixels on the left), whereby the 9 pixel values in this newly positioned filter are provided to the synapses CB1, where they are multiplied by the same weights and a second single output value is determined by the associated synapse. This process is continued until the 3x3 filter scans across the entire 32x32 pixel image of input layer S0, for all three colors and for all bits (precision values). The process is then repeated using different sets of weights to generate a different feature map of C1, until all the features maps of layer C1 have been calculated.

[0029] In layer C1, in the present example, there are 16 feature maps, with 30x30 pixels each. Each pixel is a new feature pixel extracted from multiplying the inputs and kernel, and therefore each feature map is a two dimensional array, and thus in this example layer C1 constitutes 16

Attorney Docket Number: 351913-980132

layers of two dimensional arrays (keeping in mind that the layers and arrays referenced herein are logical relationships, not necessarily physical relationships – i.e., the arrays are not necessarily oriented in physical two dimensional arrays). Each of the 16 feature maps in layer C1 is generated by one of sixteen different sets of synapse weights applied to the filter scans. The C1 feature maps could all be directed to different aspects of the same image feature, such as boundary identification. For example, the first map (generated using a first weight set, shared for all scans used to generate this first map) could identify circular edges, the second map (generated using a second weight set different from the first weight set) could identify rectangular edges, or the aspect ratio of certain features, and so on.

[0030] An activation function P1 (pooling) is applied before going from layer C1 to layer S1, which pools values from consecutive, non-overlapping 2x2 regions in each feature map. The purpose of the pooling function is to average out the nearby location (or a max function can also be used), to reduce the dependence of the edge location for example and to reduce the data size before going to the next stage. At layer S1, there are 16 15x15 feature maps (i.e., sixteen different arrays of 15x15 pixels each). The synapses CB2 going from layer S1 to layer C2 scan maps in S1 with 4x4 filters, with a filter shift of 1 pixel. At layer C2, there are 22 12x12 feature maps. An activation function P2 (pooling) is applied before going from layer C2 to layer S2, which pools values from consecutive non-overlapping 2x2 regions in each feature map. At layer S2, there are 22 6x6 feature maps. An activation function (pooling) is applied at the synapses CB3 going from layer S2 to layer C3, where every neuron in layer C3 connects to every map in layer S2 via a respective synapse of CB3. At layer C3, there are 64 neurons. The synapses CB4 going from layer C3 to the output layer S3 fully connects C3 to S3, i.e. every neuron in layer C3 is connected to every neuron in layer S3. The output at S3 includes 10 neurons, where the highest output neuron determines the class. This output could, for example, be indicative of an identification or classification of the contents of the original image.

[0031] Each layer of synapses is implemented using an array, or a portion of an array, of non-volatile memory cells.

[0032] Figure 10 is a block diagram of a system that can be used for that purpose. VMM system 32 includes non-volatile memory cells and is utilized as the synapses (such as CB1, CB2, CB3, and CB4 in Figure 6) between one layer and the next layer. Specifically, VMM system 32

Attorney Docket Number: 351913-980132

comprises VMM array 33 comprising non-volatile memory cells arranged in rows and columns, erase gate and word line gate decoder 34, control gate decoder 35, bit line decoder 36 and source line decoder 37, which decode the respective inputs for the non-volatile memory cell array 33. Input to VMM array 33 can be from the erase gate and wordline gate decoder 34 or from the control gate decoder 35. Source line decoder 37 in this example also decodes the output of VMM array 33. Alternatively, bit line decoder 36 can decode the output of VMM array 33.

[0033] VMM array 33 serves two purposes. First, it stores the weights that will be used by the VMM system 32. Second, VMM array 33 effectively multiplies the inputs by the weights stored in VMM array 33 and adds them up per output line (source line or bit line) to produce the output, which will be the input to the next layer or input to the final layer. By performing the multiplication and addition function, VMM array 33 negates the need for separate multiplication and addition logic circuits and is also power efficient due to its in-situ memory computation.

[0034] The output of VMM array 33 is supplied to a differential summer (such as a summing op-amp or a summing current mirror) 38, which sums up the outputs of VMM array 33 to create a single value for that convolution. The differential summer 38 is arranged to perform summation of both positive weight and negative weight inputs to output the single value.

[0035] The summed up output values of differential summer 38 are then supplied to an activation function circuit 39, which rectifies the output. The activation function circuit 39 may provide sigmoid, tanh, ReLU functions, or any other non-linear function. The rectified output values of activation function circuit 39 become an element of a feature map of the next layer (e.g. C1 in Figure 9), and are then applied to the next synapse to produce the next feature map layer or final layer. Therefore, in this example, VMM array 33 constitutes a plurality of synapses (which receive their inputs from the prior layer of neurons or from an input layer such as an image database), and summer 38 and activation function circuit 39 constitute a plurality of neurons.

[0036] The input to VMM system 32 in Figure 10 (WLx, EGx, CGx, and optionally BLx and SLx) can be analog level, binary level, digital pulses (in which case a pulses-to-analog converter PAC may be needed to convert pulses to the appropriate input analog level) or digital bits (in which case a DAC is provided to convert digital bits to appropriate input analog level) and the output can be analog level (e.g., current, voltage, or charge), binary level, digital pulses, or

Attorney Docket Number: 351913-980132

digital bits (in which case an output ADC is provided to convert output analog level into digital bits).

[0037] Figure 11 is a block diagram depicting the usage of numerous layers of VMM systems 32, here labeled as VMM systems 32a, 32b, 32c, 32d, and 32e. As shown in Figure 11, the input, denoted Inputx, is converted from digital to analog by a digital-to-analog converter 31, and provided to input VMM system 32a. The converted analog inputs could be voltage or current. The input D/A conversion for the first layer could be done by using a function or a LUT (look up table) that maps the inputs Inputx to appropriate analog levels for the matrix multiplier of input VMM system 32a. The input conversion could also be done by an analog to analog (A/A) converter to convert an external analog input to a mapped analog input to the input VMM system 32a. The input conversion could also be done by a digital-to-digital pulses (D/P) converter to convert an external digital input to a mapped digital pulse or pulses to the input VMM system 32a.

[0038] The output generated by input VMM system 32a is provided as an input to the next VMM system (hidden level 1) 32b, which in turn generates an output that is provided as an input to the next VMM system (hidden level 2) 32c, and so on. The various layers of VMM system 32 function as different layers of synapses and neurons of a convolutional neural network (CNN). Each VMM system 32a, 32b, 32c, 32d, and 32e can be a stand-alone, physical system comprising a respective non-volatile memory array, or multiple VMM systems could utilize different portions of the same physical non-volatile memory array, or multiple VMM systems could utilize overlapping portions of the same physical non-volatile memory array. Each VMM system 32a, 32b, 32c, 32d, and 32e can also be time multiplexed for various portion of its array or neurons. The example shown in Figure 11 contains five layers (32a,32b,32c,32d,32e): one input layer (32a), two hidden layers (32b,32c), and two fully connected layers (32d,32e). One of ordinary skill in the art will appreciate that this is merely exemplary and that a system instead could comprise more than two hidden layers and more than two fully connected layers.

VMM Arrays

[0039] Figure 12 depicts neuron VMM array 1200, which is particularly suited for memory cells 310 as shown in Figure 3, and is utilized as the synapses and parts of neurons between an input

Attorney Docket Number: 351913-980132

layer and the next layer. VMM array 1200 comprises memory array 1201 of non-volatile memory cells and reference array 1202 (at the top of the array) of non-volatile reference memory cells. Alternatively, another reference array can be placed at the bottom.

[0040] In VMM array 1200, control gate lines, such as control gate line 1203, run in a vertical direction (hence reference array 1202 in the row direction is orthogonal to control gate line 1203), and erase gate lines, such as erase gate line 1204, run in a horizontal direction. Here, the inputs to VMM array 1200 are provided on the control gate lines (CG0, CG1, CG2, CG3), and the output of VMM array 1200 emerges on the source lines (SL0, SL1). In one embodiment, only even rows are used, and in another embodiment, only odd rows are used. The current placed on each source line (SL0, SL1, respectively) performs a summing function of all the currents from the memory cells connected to that particular source line.

[0041] As described herein for neural networks, the non-volatile memory cells of VMM array 1200, i.e. the flash memory of VMM array 1200, are preferably configured to operate in a sub-threshold region.

[0042] The non-volatile reference memory cells and the non-volatile memory cells described herein are biased in weak inversion:

$$I_{ds} = I_0 * e^{(V_g - V_{th})/nV_t} = w * I_0 * e^{(V_g)/nV_t},$$

$$\text{where } w = e^{(-V_{th})/nV_t}$$

where I_{ds} is the drain to source current; V_g is gate voltage on the memory cell; V_{th} is threshold voltage of the memory cell; V_t is thermal voltage = $k*T/q$ with k being the Boltzmann constant, T the temperature in Kelvin, and q the electronic charge; n is a slope factor = $1 + (C_{dep}/C_{ox})$ with C_{dep} = capacitance of the depletion layer, and C_{ox} capacitance of the gate oxide layer; I_0 is the memory cell current at gate voltage equal to threshold voltage, I_0 is proportional to $(W_t/L)*u*C_{ox}*(n-1)*V_t^2$ where u is carrier mobility and W_t and L are width and length, respectively, of the memory cell.

[0043] For an I-to-V log converter using a memory cell (such as a reference memory cell or a peripheral memory cell) or a transistor to convert input current I_{ds} , into an input voltage, V_g :

$$V_g = n*V_t*\log [I_{ds}/w_p*I_0]$$

Here, w_p is w of a reference or peripheral memory cell.

Attorney Docket Number: 351913-980132

[0044] For an I-to-V log converter using a memory cell (such as a reference memory cell or a peripheral memory cell) or a transistor to convert input current I_{ds} , into an input voltage, V_g :

$$V_g = n * V_t * \log [I_{ds} / w_p * I_o]$$

[0045] Here, w_p is w of a reference or peripheral memory cell.

[0046] For a memory array used as a vector matrix multiplier VMM array, the output current is:

$$I_{out} = w_a * I_o * e^{(V_g)/nV_t}, \text{ namely}$$

$$I_{out} = (w_a/w_p) * I_{in} = W * I_{in}$$

$$W = e^{(V_{thp} - V_{tha})/nV_t}$$

$$I_{in} = w_p * I_o * e^{(V_g)/nV_t}$$

Here, $w_a = w$ of each memory cell in the memory array.

[0047] A wordline or control gate can be used as the input for the memory cell for the input voltage.

[0048] Alternatively, the non-volatile memory cells of VMM arrays described herein can be configured to operate in the linear region:

$$I_{ds} = \beta * (V_{gs} - V_{th}) * V_{ds}; \beta = \mu * C_{ox} * W_t/L,$$

$$W \propto (V_{gs} - V_{th}),$$

meaning weight W in the linear region is proportional to $(V_{gs} - V_{th})$

[0049] A wordline or control gate or bitline or sourceline can be used as the input for the memory cell operated in the linear region. The bitline or sourceline can be used as the output for the memory cell.

[0050] For an I-to-V linear converter, a memory cell (such as a reference memory cell or a peripheral memory cell) or a transistor operating in the linear region or a resistor can be used to linearly convert an input/output current into an input/output voltage.

[0051] Alternatively, the memory cells of VMM arrays described herein can be configured to operate in the saturation region:

$$I_{ds} = \frac{1}{2} * \beta * (V_{gs} - V_{th})^2; \beta = \mu * C_{ox} * W_t/L$$

$$W \propto (V_{gs} - V_{th})^2, \text{ meaning weight } W \text{ is proportional to } (V_{gs} - V_{th})^2$$

[0052] A wordline, control gate, or erase gate can be used as the input for the memory cell operated in the saturation region. The bitline or sourceline can be used as the output for the output neuron.

Attorney Docket Number: 351913-980132

[0053] Alternatively, the memory cells of VMM arrays described herein can be used in all regions or a combination thereof (sub threshold, linear, or saturation) for each layer or multi layers of a neural network.

[0054] Figure 13 depicts neuron VMM array 1300, which is particularly suited for memory cells 210 as shown in Figure 2, and is utilized as the synapses between an input layer and the next layer. VMM array 1300 comprises a memory array 1303 of non-volatile memory cells, reference array 1301 of first non-volatile reference memory cells, and reference array 1302 of second non-volatile reference memory cells. Reference arrays 1301 and 1302, arranged in the column direction of the array, serve to convert current inputs flowing into terminals BLR0, BLR1, BLR2, and BLR3 into voltage inputs WL0, WL1, WL2, and WL3. In effect, the first and second non-volatile reference memory cells are diode-connected through multiplexors 1314 (only partially depicted) with current inputs flowing into them. The reference cells are tuned (e.g., programmed) to target reference levels. The target reference levels are provided by a reference mini-array matrix (not shown).

[0055] Memory array 1303 serves two purposes. First, it stores the weights that will be used by the VMM array 1300 on respective memory cells thereof. Second, memory array 1303 effectively multiplies the inputs (i.e. current inputs provided in terminals BLR0, BLR1, BLR2, and BLR3, which reference arrays 1301 and 1302 convert into the input voltages to supply to wordlines WL0, WL1, WL2, and WL3) by the weights stored in the memory array 1303 and then adds all the results (memory cell currents) to produce the output on the respective bit lines (BL0 - BLN), which will be the input to the next layer or input to the final layer. By performing the multiplication and addition function, memory array 1303 negates the need for separate multiplication and addition logic circuits and is also power efficient. Here, the voltage inputs are provided on the word lines WL0, WL1, WL2, and WL3, and the output emerges on the respective bit lines BL0 - BLN during a read (inference) operation. The current placed on each of the bit lines BL0 - BLN performs a summing function of the currents from all non-volatile memory cells connected to that particular bitline.

[0056] Table No. 6 depicts operating voltages for VMM array 1300. The columns in the table indicate the voltages placed on word lines for selected cells, word lines for unselected cells, bit lines for selected cells, bit lines for unselected cells, source lines for selected cells, and source

Attorney Docket Number: 351913-980132

lines for unselected cells, where FLT indicates floating, i.e. no voltage is imposed. The rows indicate the operations of read, erase, and program.

Table No. 6: Operation of VMM Array 1300 of Figure 13:

	WL	WL -unsel	BL	BL -unsel	SL	SL -unsel
Read	0.5-3.5V	-0.5V/0V	0.1-2V (Ineuron)	0.6V-2V/FLT	0V	0V
Erase	~5-13V	0V	0V	0V	0V	0V
Program	1-2V	-0.5V/0V	0.1-3 uA	Vinh ~2.5V	4-10V	0-1V/FLT

[0057] Figure 14 depicts neuron VMM array 1400, which is particularly suited for memory cells 210 as shown in Figure 2, and is utilized as the synapses and parts of neurons between an input layer and the next layer. VMM array 1400 comprises a memory array 1403 of non-volatile memory cells, reference array 1401 of first non-volatile reference memory cells, and reference array 1402 of second non-volatile reference memory cells. Reference arrays 1401 and 1402 run in row direction of the VMM array 1400. VMM array is similar to VMM 1300 except that in VMM array 1400, the word lines run in the vertical direction. Here, the inputs are provided on the word lines (WLA0, WLB0, WLA1, WLB2, WLA2, WLB2, WLA3, WLB3), and the output emerges on the source line (SL0, SL1) during a read operation. The current placed on each source line performs a summing function of all the currents from the memory cells connected to that particular source line.

[0058] Table No. 7 depicts operating voltages for VMM array 1400. The columns in the table indicate the voltages placed on word lines for selected cells, word lines for unselected cells, bit lines for selected cells, bit lines for unselected cells, source lines for selected cells, and source lines for unselected cells. The rows indicate the operations of read, erase, and program.

Table No. 7: Operation of VMM Array 1400 of Figure 14

Attorney Docket Number: 351913-980132

	WL	WL -unsel	BL	BL -unsel	SL	SL -unsel
Read	0.5-3.5V	-0.5V/0V	0.1-2V	0.1V-2V/FLT	~0.3-1V (Ineuron)	0V
Erase	~5-13V	0V	0V	0V	0V	SL-inhibit (~4-8V)
Program	1-2V	-0.5V/0V	0.1-3 uA	Vinh ~2.5V	4-10V	0-1V/FLT

[0059] Figure 15 depicts neuron VMM array 1500, which is particularly suited for memory cells 310 as shown in Figure 3, and is utilized as the synapses and parts of neurons between an input layer and the next layer. VMM array 1500 comprises a memory array 1503 of non-volatile memory cells, reference array 1501 of first non-volatile reference memory cells, and reference array 1502 of second non-volatile reference memory cells. Reference arrays 1501 and 1502 serve to convert current inputs flowing into terminals BLR0, BLR1, BLR2, and BLR3 into voltage inputs CG0, CG1, CG2, and CG3. In effect, the first and second non-volatile reference memory cells are diode-connected through multiplexors 1512 (only partially shown) with current inputs flowing into them through BLR0, BLR1, BLR2, and BLR3. Multiplexors 1512 each include a respective multiplexor 1505 and a cascoding transistor 1504 to ensure a constant voltage on the bitline (such as BLR0) of each of the first and second non-volatile reference memory cells during a read operation. The reference cells are tuned to target reference levels.

[0060] Memory array 1503 serves two purposes. First, it stores the weights that will be used by the VMM array 1500. Second, memory array 1503 effectively multiplies the inputs (current inputs provided to terminals BLR0, BLR1, BLR2, and BLR3, for which reference arrays 1501 and 1502 convert these current inputs into the input voltages to supply to the control gates (CG0, CG1, CG2, and CG3) by the weights stored in the memory array and then add all the results (cell currents) to produce the output, which appears on BL0 – BLN, and will be the input to the next layer or input to the final layer. By performing the multiplication and addition function, the

Attorney Docket Number: 351913-980132

memory array negates the need for separate multiplication and addition logic circuits and is also power efficient. Here, the inputs are provided on the control gate lines (CG0, CG1, CG2, and CG3), and the output emerges on the bitlines (BL0 – BLN) during a read operation. The current placed on each bitline performs a summing function of all the currents from the memory cells connected to that particular bitline.

[0061] VMM array 1500 implements uni-directional tuning for non-volatile memory cells in memory array 1503. That is, each non-volatile memory cell is erased and then partially programmed until the desired charge on the floating gate is reached. This can be performed, for example, using the precision programming techniques described below. If too much charge is placed on the floating gate (such that the wrong value is stored in the cell), the cell must be erased and the sequence of partial programming operations must start over. As shown, two rows sharing the same erase gate (such as EG0 or EG1) need to be erased together (which is known as a page erase), and thereafter, each cell is partially programmed until the desired charge on the floating gate is reached.

[0062] Table No. 8 depicts operating voltages for VMM array 1500. The columns in the table indicate the voltages placed on word lines for selected cells, word lines for unselected cells, bit lines for selected cells, bit lines for unselected cells, control gates for selected cells, control gates for unselected cells in the same sector as the selected cells, control gates for unselected cells in a different sector than the selected cells, erase gates for selected cells, erase gates for unselected cells, source lines for selected cells, and source lines for unselected cells. The rows indicate the operations of read, erase, and program.

Table No. 8: Operation of VMM Array 1500 of Figure 15

	WL	WL - unsel	BL	BL - unsel	CG	CG - unsel same sector	CG - unsel	EG	EG - unsel	SL	SL - unsel
Read	0.5-2V	-0.5V/ 0V	0.1-2V (Inuron)	0V/FLT	0-2.6V	0-2.6V	0-2.6V	0-2.6V	0-2.6V	0V	0V
Erase	0V	0V	0V	0V	0V	0-2.6V	0-2.6V	5-12V	0-2.6V	0V	0V

Attorney Docket Number: 351913-980132

				Vinh							
Program	0.7-1V	-0.5V/ 0V	0.1-1uA	(1-2V)	4-11V	0-2.6V	0-2.6V	4.5-5V	0-2.6V	4.5-5V	0-1V

[0063] Figure 16 depicts neuron VMM array 1600, which is particularly suited for memory cells 310 as shown in Figure 3, and is utilized as the synapses and parts of neurons between an input layer and the next layer. VMM array 1600 comprises a memory array 1603 of non-volatile memory cells, reference array 1601 of first non-volatile reference memory cells, and reference array 1602 of second non-volatile reference memory cells. EG lines EGR0, EG0, EG1 and EGR1 are run vertically while CG lines CG0, CG1, CG2 and CG3 and SL lines WL0, WL1, WL2 and WL3 are run horizontally. VMM array 1600 is similar to VMM array 1600, except that VMM array 1600 implements bi-directional tuning, where each individual cell can be completely erased, partially programmed, and partially erased as needed to reach the desired amount of charge on the floating gate due to the use of separate EG lines. As shown, reference arrays 1601 and 1602 convert input current in the terminal BLR0, BLR1, BLR2, and BLR3 into control gate voltages CG0, CG1, CG2, and CG3 (through the action of diode-connected reference cells through multiplexors 1614) to be applied to the memory cells in the row direction. The current output (neuron) is in the bitlines BL0 – BLN, where each bit line sums all currents from the non-volatile memory cells connected to that particular bitline.

[0064] Table No. 9 depicts operating voltages for VMM array 1600. The columns in the table indicate the voltages placed on word lines for selected cells, word lines for unselected cells, bit lines for selected cells, bit lines for unselected cells, control gates for selected cells, control gates for unselected cells in the same sector as the selected cells, control gates for unselected cells in a different sector than the selected cells, erase gates for selected cells, erase gates for unselected cells, source lines for selected cells, and source lines for unselected cells. The rows indicate the operations of read, erase, and program.

Table No. 9: Operation of VMM Array 1600 of Figure 16

						CG -unsel					
	WL	WL -	BL	BL -	CG	same	CG -	EG	EG -	SL	SL -
		unsel		unsel		sector	unsel		unsel		unsel

Attorney Docket Number: 351913-980132

Read	1.0-2V	-0.5V/ 0V	0.6-2V (Ineuron)	0V/FLT	0-2.6V	0-2.6V	0-2.6V	0-2.6V	0-2.6V	0V	0V/FLT
Erase	0V	0V	0V	0V	0V	4-9V	0-2.6V	5-12V	0-2.6V	0V	0V
Program	0.7-1V	-0.5V/ 0V	0.1-1uA	Vinh (1-2V)	4-11V	0-2.6V	0-2.6V	4.5-5V	0-2.6V	4.5- 5V	0-1V

[0065] The input to the VMM arrays can be an analog level, a binary level, timing pulses, or digital bits and the output can be an analog level, a binary level, timing pulses, or digital bits (in this case an output ADC is needed to convert output analog level current or voltage into digital bits).

[0066] For each memory cell in a VMM array, each weight w can be implemented by a single memory cell or by a differential cell or by two blend memory cells (average of 2 or more cells). In the differential cell case, two memory cells are needed to implement a weight w as a differential weight ($w = w^+ - w^-$). In the two blend memory cells, two memory cells are needed to implement a weight w as an average of two cells.

[0067] One drawback of prior art arrays of non-volatile memory cells is that a relatively significant amount of time is needed to pull source lines to ground to perform a read or erase operation.

[0068] What is needed is an improved VMM system that is able to pull a source line down to ground more accurately than in prior art systems. What is further needed is an adaptive bias circuit that is able to change the bias applied to the input and/or output lines to the VMM system in those instances where the source line is pulled down to a voltage greater than 0V (i.e., where the “ground” line is not actually at 0V).

SUMMARY OF THE INVENTION

[0069] Numerous embodiments of analog neural memory arrays are disclosed. Certain embodiments contain improved mechanisms for pulling source lines down to ground accurately. This is useful, for example, to minimize the voltage drop for a read, program, or erase operation. Other embodiments contain implementations for negative and positive inputs with negative and

Attorney Docket Number: 351913-980132

positive weights. Other embodiments include an adaptive bias circuit that is able to change the bias to the input or output lines to the VMM system in those instances where the source line is pulled down to a voltage greater than 0V (i.e., where the “ground” line is not actually at 0V).

BRIEF DESCRIPTION OF THE DRAWINGS

[0070] Figure 1 depicts a prior art artificial neural network.

[0071] Figure 2 depicts a prior art split gate flash memory cell.

[0072] Figure 3 depicts another prior art split gate flash memory cell

[0073] Figure 4 depicts another prior art split gate flash memory cell.

[0074] Figure 5 depicts another prior art split gate flash memory cell.

[0075] Figure 6 depicts another prior art split gate flash memory cell.

[0076] Figure 7 depicts a prior art stacked gate flash memory cell.

[0077] Figure 8 depicts a twin split-gate memory cell.

[0078] Figure 9 depicts different levels of an exemplary artificial neural network utilizing one or more VMM arrays.

[0079] Figure 10 depicts a VMM system comprising a VMM array and other circuitry.

[0080] Figure 11 depicts an exemplary artificial neural network utilizing one or more VMM systems.

[0081] Figure 12 depicts an embodiment of a VMM array.

[0082] Figure 13 depicts another embodiment of a VMM array.

[0083] Figure 14 depicts another embodiment of a VMM array.

[0084] Figure 15 depicts another embodiment of a VMM array.

[0085] Figure 16 depicts another embodiment of a VMM array.

[0086] Figure 17 depicts a VMM system.

[0087] Figures 18A, 18B, and 18C depict a prior art VMM array.

[0088] Figures 19A, 19B, and 19C depicts an improved VMM array.

[0089] Figure 20 depicts another improved VMM array.

[0090] Figure 21 depicts a VMM system with an improved source line pull down mechanism.

[0091] Figure 22 depicts another VMM system with an improved source line pull down mechanism.

Attorney Docket Number: 351913-980132

[0092] Figure 23 depicts another VMM system with an improved source line pull down mechanism.

[0093] Figure 24 depicts another VMM system with an improved source line pull down mechanism.

[0094] Figure 25 depicts an exemplary layout diagram of a VMM system with an improved source line pull down mechanism.

[0095] Figure 26 depicts another exemplary layout diagram of a VMM system with an improved source line pull down mechanism.

[0096] Figure 27A, 27B, and 27C depict other improved VMM arrays.

[0097] Figure 28 depicts another improved VMM array comprising a redundant array.

[0098] Figure 29 depict another improved VMM system that comprises two VMM arrays and shared dummy bit line switching circuitry.

[0099] Figure 30 depicts another improved VMM system.

[00100] Figure 31 depicts an embodiment of a summer circuit.

[00101] Figure 32 depicts another embodiment of a summer circuit.

[00102] Figures 33A and 33B depicts other embodiments of a summer circuit.

[00103] Figures 34A, 34B, and 34C depicts embodiments of an output circuit.

[00104] Figure 35 depicts a neuron output circuit.

[00105] Figure 36 depicts an embodiment of an analog-to-digital converter.

[00106] Figure 37 depicts another embodiment of an analog-to-digital converter.

[00107] Figure 38 depicts another embodiment of an analog-to-digital converter.

[00108] Figure 39 depicts another embodiment of an analog-to-digital converter.

[00109] Figure 40 depicts a desired voltage difference between a control gate line and a source line in a VMM array.

[00110] Figure 41 depicts a desired voltage difference between a word line and a source line in a VMM array.

[00111] Figure 42 depicts a desired voltage difference between a bit line and a source line in a VMM array.

[00112] Figure 43 depicts a typical change in voltage for a terminal in a VMM array in response to a change in temperature.

Attorney Docket Number: 351913-980132

- [00113] Figure 44A and 44B depicts adaptive bias circuits.
- [00114] Figure 45A and 45B depicts regulator circuits.
- [00115] Figure 46A depicts a digital-to-analog converter.
- [00116] Figure 46B depicts an analog-to-digital converter.
- [00117] Figure 47 depicts a decoder.
- [00118] Figure 48 depicts a current-to-voltage summer.
- [00119] Figure 49 depicts another current-to-voltage summer.
- [00120] Figure 50 depicts another current-to-voltage summer.
- [00121] Figure 51 depicts another current-to-voltage summer.
- [00122] Figure 52 depicts another current-to-voltage summer.
- [00123] Figure 53 depicts high voltage decoding circuitry for an erase gate decoder, control gate decoder, and source line decoder.

DETAILED DESCRIPTION OF THE INVENTION

The artificial neural networks of the present invention utilize a combination of CMOS technology and non-volatile memory arrays.

Embodiments of Improved VMM Systems

[00124] Figure 17 depicts a block diagram of VMM system 1700. VMM system 1700 comprises VMM array 1701, row decoders 1702, high voltage decoders 1703, column decoders 1704, bit line drivers 1705, input circuit 1706, output circuit 1707, control logic 1708, and bias generator 1709. VMM system 1700 further comprises high voltage generation block 1710, which comprises charge pump 1711, charge pump regulator 1712, and high voltage level generator 1713. VMM system 1700 further comprises algorithm controller 1714, analog circuitry 1715, control logic 1716, and test control logic 1717. The systems and methods described below can be implemented in VMM system 1700.

[00125] The input circuit 1706 may include circuits such as a DAC (digital to analog converter), DPC (digital to pulses converter), AAC (analog to analog converter, such as current to voltage converter), PAC (pulse to analog level converter), or any other type of converters. The input circuit 1706 may implement normalization, scaling functions, or arithmetic functions. The

Attorney Docket Number: 351913-980132

input circuit 1706 may implement temperature compensation function for input. The input circuit 1706 may implement activation function such as ReLU or sigmoid. The output circuit 1707 may include circuits such as a ADC (analog to digital converter, to convert neuron analog output to digital bits), AAC (analog to analog converter, such as current to voltage converter), APC (analog to pulse(s) converter), or any other type of converters. The output circuit 1707 may implement activation function such as ReLU or sigmoids. The output circuit 1707 may implement statistic normalization, regularization, up/down scaling functions, statistical rounding, or arithmetic functions (e.g., add, subtract, divide, multiply, shift, log) for neuron outputs. The output circuit 1707 may implement temperature compensation function for neuron outputs or array outputs (such as bitline output) such as to keep power consumption of the array approximately constant or to improve precision of the array (neuron) outputs such as by keeping the IV slope approximately the same.

[00126] Figure 18A depicts prior art VMM system 1800. VMM system 1800 comprises exemplary cells 1801 and 1802, exemplary bit line switch 1803 (which connects bit lines to sensing circuitry), exemplary dummy bit line switch 1804 (which couples to a low level such as ground level in read), exemplary dummy cells 1805 and 1806 (source line pull down cells). Bit line switch 1803 is coupled to a column of cells, including cells 1801 and 1802, that are used to store data in VMM system 1800. Dummy bit line switch 1804 is coupled to a column (bitline) of cells that are dummy cells are not used to store data in VMM system 1800. This dummy bitline (aka source line pulldown bitline) is used as source line pull down in read, meaning used to pull the source line SL to low level such ground level through the memory cells in the dummy bitline.

[00127] One drawback of VMM system 1800 is that the input impedance for each cell varies due to the length of the electrical path through the relevant bit line switch, the cell itself, and the relevant dummy bit line switch. For example, Figure 18B shows the electrical path through bit line switch 1803, cell 1801, dummy cell 1805, and dummy bit line switch 1804. Similarly, Figure 18C shows the electrical path through bit line switch 1803, vertical metal bitline 1807, cell 1802, dummy cell 1808, vertical metal bitline 1808, and dummy bit line switch 1804. As can be seen, the path through cell 1802 traverses a significantly larger length of bit line and dummy bit line, which is associated with a higher capacitance and higher resistance. This results

Attorney Docket Number: 351913-980132

in cell 1802 having a greater parasitic impedance in the bit line or source line than cell 1801. This variability is a drawback, for instance, because it results in a variance in the precision of the cell output as applied to read or verify (for program/erase tuning cycles) cells depending on their location within the array.

[00128] Figure 19A depicts improved VMM system 1900. VMM system 1900 comprises exemplary cells 1901 and 1902, exemplary bit line switch 1903 (which connects the bit lines to sensing circuitry), exemplary dummy cells 1905 and 1906 (source line pull down cells), and exemplary dummy bit line switch 1904 (which couples to a low level such as ground level in read, this switch connects to dummy bit line that connects to dummy cells used as source line pull down). As can be seen, exemplary dummy bit line switch 1904 and the other dummy bit line switches are located on the opposite end of the array from bit line switch 1903 and the other bit line switches.

[00129] The benefit of this design can be seen in Figures 19B and 19C. Figure 19B depicts the electrical path through bit line switch 1903, cell 1901, dummy cell 1905 (source line pull down cell), vertical metal bit line 1908, and dummy bit line switch 1904 (which couples to a low level such as ground level in read). Figure 19C depicts the electrical path through bit line switch 1903, vertical metal line 1907, cell 1902, dummy cell 1906 (source line pull down cell), and dummy bit line switch 1904. The paths are substantially the same (cells, interconnect lengths), which is true for all cells in VMM system 1900. As a result, the impedance of the bit line impedance plus source line impedance of each cell is substantially the same, which means that the variance in the amount of parasitic voltage drop drawn to read or verify operation of the various cells in the array is relatively same .

[00130] Figure 20 depicts VMM system 2000 with global source line pulldown bitline. VMM system 2000 is similar to VMM system 1900, except that: the dummy bit lines 2005a-2005n or 2007a-2007n are connected together (to act as global source line pulldown lines to pull memory cell source lines to ground level during read or verify), the dummy bit line switches, such as dummy bit line switch 2001 and 2002, are connected or coupled to a common ground denoted ARYGND; and the source lines are coupled together to source line switch 2003, which selectively pulls the source lines to ground. These changes further decrease the variance in

Attorney Docket Number: 351913-980132

(array) parasitic impedance among cells during read or verify operations. The source lines are connected together as SLARY 2888.

[00131] Figure 21 depicts VMM system 2100. VMM system 2100 comprises bit line switch 2101, pull down bit line switch 2102, pull down bit line switch 2103, bit line switch 2104, data cell 2105 (herein, a “data cell” is a memory cell used to store a weight value for a neural network), pull down cell 2106, pull down cell 2107, and data cell 2108. Note that the pulldown cells 2106 and 2107 are adjacent to each other. This allows vertical metal lines BLpdx of the two pulldown cells 2106 and 2107 to be connected together (line 2111) to reduce parasitic resistance due to the resulting wider metal line. During a read or verify (for program/erase tuning cycles) operation of data cell 2105, current will flow through bit line switch 2101 into the bit line terminal of cell 2105 and out to the source line terminal of cell 2105, where it then flows into source line 2110, where it flows into the source line terminals of pull down cells 2106 and 2107 and through pull down bit line switches 2102 and 2103. During a read or verify (for program/erase tuning cycles) operation of cell 2104, current will flow through bit line switch 2104 into the bit line terminal of data cell 2108 and out to the source line terminal of cell 2108, where it then flows into source line 2110, where it flows into the source line terminals of pull down cells 2106 and 2107 and through pull down bit line switches 2102 and 2103. This pattern of columns repeats throughout the array, where every four columns contains two columns of data cells and two adjacent array columns used for pull down operations. In another embodiment, the diffusion of the two pull down cells of the two adjacent columns can be merged together into one bigger diffusion to increase the pull down capability. In another embodiment, the diffusion of the pull down cell can be made to be bigger than that of the data cell diffusion to increase the pull down capability. In another embodiment, each pull down cell has a bias condition different than a bias condition of a selected data cell.

[00132] In one embodiment, the pull down cell has the same physical structure as a regular data memory cell. In another embodiment, the pull down cell has a different physical structure than a regular data memory cell, for example, the pull down cell can be a modified version of a regular data memory cell such as by modifying one or more physical dimensions (width, length, etc.) for electrical parameters (layer thickness, implant, etc.). In another embodiment, the pull down cell is a regular transistor (without a floating gate) such as an IO or high voltage transistor.

Attorney Docket Number: 351913-980132

[00133] Figure 22 depicts VMM system 2200. VMM system 2200 comprises bit line 2201, pull down bit line 2202, data cells 2203 and 2206, pull down cells 2204 and 2205, and source line 2210. During a read or verify operation of cell 2203, current will flow through bit line switch 2201 into the bit line terminal of cell 2203 and out to the source line terminal of cell 2203, where it then flows into source line 2210 and into the source line terminals of pull down cell 2204 and through pull down bit line BLpd 2202. This design is repeated for every column, with the net result that the row containing pull down cell 2204 is a row of pull down cells.

[00134] During a read or verify (for program/erase tuning cycles) operation of cell 2206, current will flow through bit line switch 2201 into the bit line terminal of cell 2206 and out to the source line terminal of cell 2206, where it then flows into source line 2211 and into the source line terminals of pull down cell 2205 and through pull down bit line 2202. This design is repeated for every column, with the net result that the row containing pull down cell 2205 is a row of pull down cells. As shown in Figure 22, there are four rows, the two middle adjacent rows are used for pull down cells, the top and bottom rows are data cells.

[00135] Table No. 10 depicts operating voltages for VMM system 2200. The columns in the table indicate the voltages placed on bit lines for selected cells, bit line pull downs, word lines for selected cells, control gates for selected cells, word lines WLS for selected pull down cells, control gates CGS for selected pull down cells, erase gates for all cells, and source lines for all cells. The rows indicate the operations of read, erase, and program. Note that the voltage bias for CGS and WLS in read are higher than that of the regular WL and CG biases to enhance the drive capability of the pull down cells. The voltage biased for WLS and CGS can be negative in programming to reduce disturb.

Attorney Docket Number: 351913-980132

Table No. 10: Operation of VMM Array 2200 of Figure 22

Op Table								
	BL	BLpd	WL	CG	WLS	CGS	EG	SL
Erase	0V	0V	0V	0V	0V	0V	11.5V	0V
Program	Iprog	VINH	~0.7V	~10.5V	-0.5V to 0V	-2V to 0V	~4.5V	~4.5V
Read	0.6V	0V	~0-1.1V	~0-1.5V	1.1-1.3V	1.8-3V	0V	0V

[00136] Figure 23 depicts VMM system 2300. VMM system 2300 comprises bit line 2301, bit line 2302, data cells 2303 and 2306, and pull down cells 2304 and 2305. During a read or verify (for program/erase tuning cycles) operation of cell 2303, current will flow through bit line 2301 into the bit line terminal of cell 2303 and out to the source line terminal of cell 2303, where it then flows into source line terminals of pull down cell 2304 and through bit line 2302 (acting as pull down bit line in this case). This design is repeated for every column, with the net result that the row containing pull down cell 2304, in a first mode, is a row of pull down cells. During a read or verify (for program/erase tuning cycles) operation of data cell 2306, current will flow through bit line 2301 into the bit line terminal of cell 2306 and out to the source line terminal of cell 2306, where it then flows into source line terminals of pull down cell 2305 and through bit line 2302 (acting as pull down bit line in this case). This design is repeated for every column, with the net result that the row containing pull down cell 2305, in a second mode, is a row of pull down cells. As shown in Figure 23, there are four rows, the alternative odd (or even) rows are used for pull down cells, the alternative even (or odd) rows are data cells.

[00137] Notably, during a second mode, cells 2305 and 2306 are active in read or verify and cells 2303 and 2305 are used for the pull down process, with the roles of bit lines 2301 and 2302 being reversed.

[00138] Table No. 11 depicts operating voltages for VMM system 2300. The columns in the table indicate the voltages placed on bit lines for selected data cells, bit lines for selected pull down cells, word lines for selected data cells, control gates for selected data cells, word lines WLS for selected pull down cells, control gates CGS for selected pull down cells, erase gates for

Attorney Docket Number: 351913-980132

all cells, and source lines for all cells. The rows indicate the operations of read, erase, and program.

Table No. 11: Operation of VMM System 2300 of Figure 23

Op Table								
	BL0A	BL0B	WL	CG	WLS	CGS	EG	SL
Erase	0V	0V	0V	0V	0V	0V	11.5V	0V
Program	Iprog	VINH	~0.7V	~10.5V	-0.5V to 0V	-2V to 0V	~4.5V	~4.5V
Read	0.6V/0V	0v/0.6V	~0-1.1V	~0-1.5V	1.1-1.3V	1.8-3V	0V	0V

[00139] Figure 24 depicts VMM system 2400. VMM system 2400 comprises bit line 2401, pull down bit line 2402, (data) cell 2403, source line 2411, and pull down cells 2404, 2405, and 2406. During a read or verify operation of cell 2403, current will flow through bit line 2401 into the bit line terminal of cell 2403 and out to the source line terminal of cell 2403, where it then flows into source line 2411, and where it then flows into the source line terminal of pull down cells 2404, 2405, and 2406, from which it flows through pull down bit line 2402. This design is repeated for every column, with the net result that the rows containing pull down cells 2404, 2405, and 2406 each are rows of pull down cells. This maximizes the pull down applied to the source line terminal of cell 2403, as current is drawn through three cells into pull down bit line 2402. Note the source lines of the four rows are connected together.

[00140] Table No. 12 depicts operating voltages for VMM system 2400. The columns in the table indicate the voltages placed on bit lines for selected cells, bit line pull downs, word lines for selected cells, control gates for selected cells, erase gates for selected cells, word lines WLS for selected pull down cells, control gates CGS for selected pull down cells, erase gates for selected pulldown cells, and source lines for all cells. The rows indicate the operations of read, erase, and program.

Table No. 12: Operation of VMM System 2400 of Figure 24

Op Table									
	BL	BPpd	WL	CG	WLS	CGS	EG	EGS	SL
Erase	0V	0V	0V	0V	0V	0V	11.5V	11.5V	0V

Attorney Docket Number: 351913-980132

Program	Iprog	VINH	~0.7V	~10.5V	-0.5V to 0V	-2V to 0V	~4.5V	0V	~4.5V
Read	0.6V	0V	~0-1.1V	~0-1.5V	1.1-1.3V	1.8-3V	0V	~2.5V	0V

[00141] Figure 25 depicts an exemplary layout 2500 for VMM system 2200 of Figure 22.

The light squares indicate metal contacts to bit lines such as bit line 2201 and pull down bit lines such as pull down bit line 2202.

[00142] Figure 26 depicts an alternative layout 2600 for a VMM system similar to the VMM system 2200 of Figure 22, with the difference that pull down bit line 2602 is extremely wide and traverses two columns of pull down cells. That is, the diffusion area for pull down bit line 2602 is wider than the diffusion area for bit line 2601. Layout 2600 further shows cells 2603 and 2604 (pull down cell), source line 2610, and bit line 2601. In another embodiment, the diffusion of the two pull down cells (left and right) can be merged together into one bigger diffusion.

[00143] Figure 27A depicts VMM system 2700. To implement negative and positive weights of a neural network, half of the bit lines are designated as $w+$ lines (bit lines connecting to memory cells implementing positive weights), and the other half of the bit lines are designated as $w-$ lines (bit lines connecting to memory cells implementing negative weights) and are interspersed among the $w+$ lines in an alternating fashion. The negative operation is done at the output of the $w-$ bit line (neuron output) by a summation circuit, such as summation circuits 2701 and 2702. The output of a $w+$ line and the output of a $w-$ line are combined together to give effectively $w = w+ - w-$ for each pair of ($w+$, $w-$) cells for all pairs of ($w+$, $w-$) lines. The dummy bitlines or source line pulldown bitlines used to avoid FG-FG coupling and/or reduce IR voltage drop in the source line in read are not shown in the figure. The input (such as to CG or WL) to the system 2700 can have positive value or negative value input. For the case of the input has negative value, since actual input to array is still positive (such as a voltage level on CG or WL), the array output (bitline output) is negated before output to realize the equivalent function of the negative value input.

[00144] Alternatively, with reference to Figures 27B, positive weights can be implemented in a first array 2711 and negative weights can be implemented in a second array 2712, separate from the first array, and the resulting weights are appropriately combined together by summation

Attorney Docket Number: 351913-980132

circuits 2713. Similarly, the dummy bitlines (not shown) or source line pulldown bitlines (not shown) are used to avoid FG-FG coupling and/or reduce IR voltage drop in the source line in read.

[00145] Alternatively, Figure 27C depicts VMM system 2750 to implement negative and positive weights of a neural network with positive or negative input. First array 2751 implements positive value inputs with negative and positive weights and second array 2752 implements negative value inputs with negative and positive weights. The output of the second array is negated before adding to the output of the first array by the summer 2755 since any input to any array only has positive value (such as an analog voltage level on CG or WL).

[00146] Table 10A shows an exemplary layout of a physical array arrangement of a (w⁺, w⁻) pair of bit lines BL0/1 and BL2/3, where 4 rows are coupled to source line pulldown bit lines BLPWDNs. Pair of (BL0,BL1) bit lines is used to implement (w⁺, w⁻) lines. Between the (w⁺, w⁻) line pair, there is a source line pull down bit line (BLPWDN). This is used to prevent coupling (e.g., FG to FG coupling) from adjacent (w⁺, w⁻) lines into the current (w⁺, w⁻) lines. Basically, the source line pull down bit line (BLPWDN) serves as physical barrier between pair of (w⁺, w⁻) lines.

[00147] Additional details regarding the FG to FG coupling phenomena and mechanisms for counteracting that phenomena are found in U.S. Provisional Patent Application No. 62/981,757, filed on February 26, 2020 by the same assignee, and titled “Ultra-Precise Tuning of Analog Neural Memory Cells in a Deep Learning Artificial Neural Network,” which is incorporated by reference herein.

[00148] Table 10B shows different exemplary weight combination. ‘1’ means that the cell is used and has a real output value, whereas ‘0’ means the cell is not used and has no value or no significant output value.

[00149] In another embodiment, dummy bit lines instead of source line pull down bit lines can be used.

[00150] In another embodiment, dummy rows can also be used as physical barriers to avoid coupling between rows.

Attorney Docket Number: 351913-980132

Table 10A: Exemplary Layout

	<u>BLPWDN</u>	<u>BL0</u>	<u>BL1</u>	<u>BLPWDN</u>	<u>BL2</u>	<u>BL3</u>	<u>BLPWDN</u>
row0		w01+	w01-		w02+	w02-	
row1		w11+	w11-		w12+	w12-	
row2		w21+	w21-		w22+	w22-	
row3		w31+	w31-		w32+	w32-	

Table 10B: Exemplary Weight Combinations

	<u>BLPWDN</u>	<u>BL0</u>	<u>BL1</u>	<u>BLPWDN</u>	<u>BL2</u>	<u>BL3</u>	<u>BLPWDN</u>
row0		1	0		1	0	
row1		0	1		0	1	
row2		0	1		1	0	
row3		1	1		1	1	

[00151] Table 11A shows another array embodiment of a physical arrangement of (w+, ,w-) pair lines BL0/1 and BL2/3 with redundant lines BL01,BL23 and source line pulldown bit lines BLPWDN. BL01 is used to weight re-mapping for pair BL0/1 and BL23 is used to weight re-mapping for pair BL2/3.

[00152] Table 11B shows a case of distributed weight that needs no re-mapping, basically there is no adjacent '1' between BL1 and BL3, which causes adjacent bit line coupling. Table 11C shows a shows a case of distributed weight that needs re-mapping, basically there is adjacent '1' between BL1 and BL3, which causes adjacent bit line coupling. This re-mapping is shown in Table 11D, resulting in no '1' value between any adjacent bit lines. Furthermore by re-mapping, meaning re-distributing the weights, the '1' real value weight among the bit lines, the total current along the bit line is now reduced leading to more precise value in the bit line (output neuron). In this case, additional columns (bitline) are needed (BL01, BL23) to act as redundant columns.

Tables 11E and 11F depict another embodiments of remapping noisy cells (or defective cells) into the redundant (spare) columns such as BL01, BL23 in Table 10E or BL0B and BL1B in Table 11F. A summer is used to sum up the bit line outputs with mapping appropriately.

Attorney Docket Number: 351913-980132

Table 11A: Exemplary Layout

	<u>BLPWDN</u>	<u>BL01</u>	<u>BL0</u>	<u>BL1</u>	<u>BL2</u>	<u>BL3</u>	<u>BL23</u>	<u>BLPWDN</u>
row0			w01+	w01-	w02+	w02-		
row1			w11+	w11-	w12+	w12-		
row2			w21+	w21-	w22+	w22-		
row3			w31+	w31-	w32+	w32-		

Table 11B: Exemplary Weight Combinations

	<u>BLPWDN</u>	<u>BL01</u>	<u>BL0</u>	<u>BL1</u>	<u>BL2</u>	<u>BL3</u>	<u>BL23</u>	<u>BLPWDN</u>
row0			1	0	1	0		
row1			0	1	0	1		
row2			1	0	1	0		
row3			0	1	0	1		

Table 11C: Exemplary Weight Combinations

	<u>BLPWDN</u>	<u>BL01</u>	<u>BL0</u>	<u>BL1</u>	<u>BL2</u>	<u>BL3</u>	<u>BL23</u>	<u>BLPWDN</u>
row0			0	1	1	0		
row1			0	1	1	0		
row2			0	1	1	0		
row3			0	1	1	0		

Table 11D: Remapped Weight Combinations

	<u>BLPWDN</u>	<u>BL01</u>	<u>BL0</u>	<u>BL1</u>	<u>BL2</u>	<u>BL3</u>	<u>BL23</u>	<u>BLPWDN</u>
row0		0	0	1	0	0	1	
row1		1	0	0	1	0	0	
row2		0	0	1	0	0	1	
row3		1	0	0	1	0	0	

Table 11E: Remapped Weight Combinations

	<u>BLPWD</u> <u>N</u>	<u>BL0</u> <u>1</u>	<u>BL</u> <u>0</u>	<u>BL1</u>	<u>BL2</u>	<u>BL3</u>	<u>BL23</u>	<u>BLPWD</u> <u>N</u>
row0		0	0	1	0	0	1	
row1		1	0	noisy or defective cell (not used)	1	0	0	
row2		0	0	1	noisy or defective	0	1	

Attorney Docket Number: 351913-980132

					cell (not used)			
row3		1	0	0	1	0	0	

Table 11F: Remapped Weight Combinations

	<u>BLPWDN</u>	<u>BL0A</u>	<u>BL0B</u>	<u>BL1A</u>	<u>BL1B</u>	<u>BLPWDN</u>
row0		1	0	0	0	
row1		noisy or defective cell (not used)	1	1	0	
row2		1	0	noisy or defective cell (not used)	1	
row3		0	0	1	0	

[00153] Table 11G shows an embodiment of array physical arrangement that is suitable for Figure 27B. Since each array has either positive weight or negative weight, a dummy bitline acting as source line pull down and physical barrier to avoid FG-FG coupling is needed for each bit line.

Table 11G: Exemplary Layout

	<u>BLPWDN</u>	<u>BL0</u>	<u>BLPWDN</u>	<u>BL1</u>	<u>BLPWDN</u>
row0		w01+/-		w02+/-	
row1		w11+/-		w12+/-	
row2		w21+/-		w22+/-	
row3		w31+/-		w32+/-	

[00154] Another embodiment has a tuning bit line as an adjacent bit line to a target bitline to tune the target bit line to final target by virtue of FG-FG coupling. In this case source line pull down bitline (BLPWDN is inserted on one side of the target bit line that does not border the tuning bitline.

[00155] Alternative embodiment for mapping noisy or defective cells are to designate these cells (after identify them as noisy or defective by sensing circuitry) as non-used cells, meaning they are to be (deeply) programed to not contribute any value to the neuron output.

Attorney Docket Number: 351913-980132

[00156] An embodiment for handling fast cells are first to identify these cells, then apply a more precision algorithm to these cells such as smaller or no voltage increment pulses or using floating gate coupling algorithm.

[00157] Figure 28 depicts an optional redundant array 2801 that can be included in any of the VMM arrays discussed thus far. Redundant array 2801 can be used as redundancy to replace defective columns if any of the columns attached to bit line switches are deemed defective. The redundant array can have its own redundant neuron outputs (e.g., bit lines) and ADC circuits for redundancy purpose. For the case of redundancy is needed, the output of redundancy ADC is to replace the output of the ADC of the bad bit line. Redundant array 2801 can also be used for weight mapping such as described in Table 10x for power distribution across bit lines.

[00158] Figure 29 depicts VMM system 2900, which comprises array 2901, array 2902, column multiplexors 2903, local bit lines LBL 2905a-d, global bit line GBL 2908 and 2909, and dummy bit line switches 2905. The column multiplexors 2903 is used to select top local bit line 2905 of the array 2901 or bottom local bit line 2905 of the array 2902 into the global bit line 2908. In one embodiment, the (metal) global bit line 2908 has the same number of lines as number of the local bit lines, e.g. 8 or 16. In another embodiment, the global bit line 2908 has only one (metal) line per N number of local bit lines, such as one global bit line per 8 or 16 local bit lines.. The column multiplexors 2903 further includes multiplexing (muxing) the adjacent global bit line (such as GBL 2909) into the current global bit line (such as GBL 2908) to effectively increase the width of the current global bit line. This reduces the voltage drop across the global bit line.

[00159] Figure 30 depicts VMM system 3000. VMM system 3000 comprises array 3010, (shift registers) SRs 3001, digital-to-analog converters 3002 (which receives the input from the SRs 3001 and output an equivalent (analog or pseudo-analog) level or info) to respective control gate lines CG, summer circuits 3003, analog-to-digital converters 3004, and bit line switches 3005. Dummy bit lines and dummy bit line switches are present but not shown. As shown, ADC circuits can be combined together to create a single ADC with greater precision (i.e., greater number of bits). The source lines are connected together as SLARY 3888.

Attorney Docket Number: 351913-980132

[00160] Summer circuits 3003 can include the circuits that are shown in Figures 31-33. It may include circuits for normalization, scaling, arithmetic operations, activation, statistical rounding, etc.

[00161] Figure 31 depicts current-to-voltage summer circuit 3100 adjustable by a variable resistor, which comprises current source 3101-1, ..., 3101-n drawing current $I_{neu}(1)$, ..., $I_{neu}(n)$, respectively (which are the currents received from bit line(s) of a VMM array), operational amplifier 3102, variable holding capacitor 3104, and variable resistor 3103. Operational amplifier 3102 outputs a voltage, $V_{neuout} = R_{3103} * (I_{neu1} + I_{neu0})$, which is proportional to the current I_{neu} . The holding capacitor 3104 is used to hold the output voltage when switch 3106 is open. This holding output voltage is used for example to be converted into digital bits by an ADC circuit. V_{REF} is a reference voltage for example 0.1V to 1.0V. This is voltage that can be imposed on the bitlines of the array in read.

[00162] Figure 32 depicts current-to-voltage summer circuit 3200 adjustable by a variable capacitor (basically an integrator), which comprises current source 3201-1, ..., 3201-n drawing current $I_{neu}(1)$, ... $I_{neu}(n)$, respectively (which are the currents received from bit line(s) of a VMM array), operational amplifier 3202, variable capacitor 3203, and switch 3204. Operational amplifier 3202 outputs a voltage, $V_{neuout} = I_{neu} * \text{integration time} / C_{3203}$, which is proportional to the current $I_{neu}(s)$.

[00163] Figure 33A depicts voltage summer 3300 adjustable by variable capacitors (i.e., a switch cap SC circuit), which comprises switches 3301 and 3302, variable capacitors 3303 and 3304, operational amplifier 3305, variable capacitor 3306, and switch 3306. When switch 3301 is closed, input V_{in0} is provided to operational amplifier 3305. When switch 3302 is closed, input V_{in1} is provided to operational amplifier 3305. Optionally, switches 3301 and 3302 are not closed at the same time. Operational amplifier 3305 generates an output V_{out} , that is an amplified version of the input (either V_{in0} and/or V_{in1} , depending on which switch is closed among switches 3301 and 3302). That is $V_{out} = C_{in} / C_{out} * (V_{in})$, C_{in} is C_{3303} or C_{3304} , C_{out} is C_{3306} . For example $V_{out} = C_{in} / C_{out} * \sum (V_{inx})$, $C_{in} = C_{3303} = C_{3304}$. In one embodiment, V_{in0} is a $W+$ voltage and V_{in1} is a $W-$ voltage, and voltage summer 3300 adds them together to generate output voltage V_{out} .

Attorney Docket Number: 351913-980132

[00164] Figure 33B depicts voltage summer 3350, which comprises switches 3351, 3352, 3353, and 3354, variable input capacitors 3358, operational amplifier 3355, variable feedback capacitor 3356, and switch 3357. In one embodiment, Vin0 is a W+ voltage and Vin1 is a W- voltage, and voltage summer 3300 adds them together to generate output voltage Vout.

[00165] For Input = Vin0: when switch 3354 and 3351 are closed, input Vin0 is provided to top terminal of the capacitor 3358. Then switch 3351 is open and switch 3353 is closed to transfer the charge from the capacitor 3358 into the feedback capacitor 3356. Basically then the output $V_{OUT} = (C_{3358}/C_{3356}) * V_{in0}$ (for case of with $V_{REF} = 0$ as example).

[00166] For Input = Vin1: when switch 3353 and 3354 are closed, both terminals of the capacitor 3358 are discharged to VREF. Then switch 3354 is open and switch 3352 is closed, charging the bottom terminal of the capacitor 3358 to Vin1, which in turn charges up the feedback capacitor 3356 to $V_{OUT} = -(C_{3358}/C_{3356}) * V_{in1}$ (for case of $V_{REF} = 0$).

[00167] Hence, if Vin1 input is enabled after Vin0 input is enabled, $V_{OUT} = (C_{3358}/C_{3356}) * (V_{in0} - V_{in1})$, for case of $V_{REF} = 0$ as example. This is used for example to realize $w = w^+ - w^-$.

[00168] Methods of input and output operation to Figure 2 which applies to the VMM arrays discussed above can be in digital or analog form. Methods include:

- Sequential Inputs IN [0:q] to DACs:
 - Operate sequentially IN0, then IN1, ..., then INq; all input bits has same VCGin; all bit line (neuron) outputs are summed with adjusting binary index multiplier; either before ADC or after ADC
 - Adjusting neuron (bit line) binary index multiplier method: as shown in Fig. 20, the example summer has two bit lines BL0 and BLn. A weight is distributed across multiple bit lines BL0 to BLn. For example there are 4 bit lines BL0, BL1, BL2, BL3. The output from bitline BL0 is to be multiplied by $2^0 = 1$. The output from bit line BLn, which stand for nth binary bit position, is multiplied by 2^n , for example $2^3 = 8$ for $n = 3$. Then the output from all bit lines after being multiplied appropriately by binary bit position 2^n , are summed together. Then this is digitized by the ADC. This method means all cells have only binary range, the multi level

Attorney Docket Number: 351913-980132

range (n-bit) is accomplished by the peripheral circuit (meaning by the summer circuit). Hence the voltage drop for all the bit lines is approximately the same for highest bias level of memory cell.

- Operate sequentially $IN_0, IN_1, \dots$, then IN_q ; each input bit has a corresponding analog value VC_{Gin} ; all neuron outputs are summed for all input bit evaluation; either before ADC or after ADC
- Parallel Inputs to DACs:
 - Each input $IN[0:q]$ has a corresponding analog value VC_{Gin} ; all neuron outputs are summed with adjusting binary index multiplier method; either before ADC or after ADC

[00169] By sequentially operates on the arrays, the power is more evenly distributed. The neuron (bit line) binary index method also reduce the power in the array since each cell in the bit line only has binary levels, the 2^n level is accomplished by the summer circuit 2603.

[00170] Each ADC as shown in Figure 33 can be configured to combine with next ADC for higher bit implementation with appropriate design of the ADC.

[00171] Figures 34A, 34B, and 34C depict output circuits that can be used for summer circuits 3003 and analog-to-digital converters 3004 in Figure 30.

[00172] Figure 34A depicts output circuit 3400, which comprises analog-to-digital converter 3402, which receives neuron output 3401 and outputs output digital bits 3403.

[00173] Figure 34B depicts output circuit 3410, which comprises neuron output circuit 3411 and analog-to-digital converter 3412, which together receive neuron output 3401 and generates outputs 3413.

[00174] Figure 34C depicts output circuit 3420, which comprises neuron output circuit 3421 and converter 3422, which together receive neuron output 3401 and generates outputs 3423.

[00175] Neuron output circuit 3411 or 3411 can, for example, perform summing, scaling, normalization, arithmetic operations, etc. Converter 3422, for example, can perform ADC, PDC, AAC, APC operation, etc.

[00176] Figure 35 depicts neuron output circuit 3500, which comprises adjustable (scaling) current source 3501 and adjustable (scaling) current source 3502, which together generate output i_{OUT} , which is the neuron output. This circuit can perform summation of positive weight and

Attorney Docket Number: 351913-980132

negative weights, i.e., $w = w^+ - w^-$, and up or down scaling of the output neuron current at the same time.

[00177] Figure 36 depicts configurable neuron serial analog-to-digital converter 3600. It includes integrator 3670 which integrates the neuron output current into the integrating capacitor 3602. One embodiment is that the digital output (count output) 3621 is produced by clocking the ramping VRAMP 3650 until the comparator 3604 switches polarity or another embodiment is by ramping down node VC 3610 by the ramp current 3651 until the VOUT 3603 reaches the VREF 3650, at which point the EC 3605 signal disables the counter 3620. The (n-bit) ADC is configurable to have lower number of bit precision $< n$ -bits or higher number of bit precision $> n$ -bits depending on target application. The configurability is done such as by configuring the capacitor 3602, the current 3651, or ramping rate of the VRAMP 3650, the clocking 3641, etc. In another embodiment the ADC circuits of a VMM array is configured to have lower precision $< n$ -bits and the ADC circuits of another VMM array is configured to have high precision $> n$ -bits. Further this ADC circuit of one neuron circuit can be configured to combine with the next ADC of the next neuron circuit to produce higher n-bit ADC precision such as by combining the integrating capacitor 3602 of the two ADC circuits.

[00178] Figure 37 depicts configurable neuron SAR (successive approximation register) analog-to-digital converter 3700. This circuit is a successive approximation converter that bases on charge redistribution using binary capacitors. It includes a binary CDAC (DAC basing on capacitors) 3701, op-amp/comparator 3702, SAR logic 3703. As shown GndV 3704 is a low voltage reference level, for example ground level.

[00179] Figure 38 depicts a configurable neuron combo SAR analog-to-digital converter 3800. This circuit combines two ADCs from two neuron circuits into one to achieve higher precision n-bit, for example for 4-bit ADC for one neuron circuit, this circuit can achieve > 4 -bit precision such as 8-bit ADC precision by combining two 4-bit ADCs. The combo circuit topology is equivalent to a split cap (bridge capacitor (cap) or attention cap) SAR ADC circuit, for example a 8-bit 4C-4C SAR ADC resulted by combining two adjacent 4-bit 4C SAR ADC circuits. A bridge circuit 3804 is needed to accomplish this, the capacitance of capacitor of this circuit is $= (\text{total number of CDAC cap unit} / \text{total number of CDAC cap unit} - 1)$.

Attorney Docket Number: 351913-980132

[00180] Figure 39 depicts a configurable neuron, pipelined SAR CDAC ADC circuit 3900 that can be used to combine with the next SAR ADC to increase the number of bits in a pipelined fashion. Residue voltage 3906 is generated by capacitor 3930 C_f to provide as input to next stage of pipelined ADC (e.g. to provide gain of 2 (ratio of C_f to C of all caps in DAC 3901) as input to next SAR CDAC ADC).

[00181] Additional implementation details regarding configurable output neuron (such as configurable neuron ADC) circuits can be found in U.S. Patent Application No. 16/449,201, filed on June 21, 2019 by the same assignee, and titled “Configurable Input Blocks and Output Blocks and Physical Layout for Analog Neural Memory in a Deep Learning Artificial Neural Network,” which is incorporated by reference herein.

Adaptive Bias Circuit

[00182] With reference again to Figure 20, applicant has determined that during operation, the node “ARYGND” (array ground) will not always stay at 0V. Specifically, as current is injected into ARYGND from various source lines, the voltage of ARYGND will float above 0V, for example at 0.1-0.5V. This adversely affects the accuracy of VMM system 2000, because this will affect the reading and programming of the various cells, which are affected by the difference in voltage between the input lines WL, CG, EG, and BL and the source line that is pulled down to ARYGND.

[00183] In one embodiment, there is only one source line (SLARY) for the whole array, as shown as SLARY 2888 in Figure 20 or SLARY 3888 in Figure 30. A voltage bias can be applied by a regulator, as shown in Figure 45A (which is a buffer regulator) or 45B (which is a force/sense regulator), directly to SLARY 2888 or 3888 to maintain a fixed bias, e.g., 20mV. In another embodiment, there are multiple SLARY lines, and there are multiple regulators such as regulators 4510 or 4520 to maintain fixed bias on these SLARAY lines.

[00184] Figures 40-42 depict the adaptive voltage differential between control gate lines, word lines, and bit lines on the one hand, and source lines on the other hand.

[00185] In Figure 40, graph 4000 indicates that it is desired that the difference between a control gate line and a source line (labeled $d(CG-SL)$) for a selected cell(s) is such that the current from selected cell(s) or bitline remains constant as the source line voltage increases.

Attorney Docket Number: 351913-980132

Here, the x axis tracks the SL voltage, and the y axis tracks the difference between the CG voltage and SL voltage. For example, when ARYGND creeps up above 0V (which means that the source line also will creep above 0V), it is desired that the difference between a control gate line and a source line will change adaptively to maintain the cell or bitline current at a constant level. In this example, the voltage on CG will be adaptively increased as a function of source line voltage to compensate for different effects from source voltage changes. The effects to be compensated for are such as from effective reduced gate-to-source voltage due to increasing source voltage or from increasing body effect on threshold voltage due to increasing source voltage. It also may compensate for the effect caused by reduced drain-to-source voltage due to increasing source voltage. It also compensates for the effect caused by coupling from control gate CG and source voltage into the floating gate FG. The appropriate compensation function or look-up-table data can be characterized from silicon data.

[00186] In Figure 41, graph 4100 indicates that it is desired that the difference between a word line and a source line for a selected cell (labeled as $d(WL-SL)$) is such that the current from the selected cell(s) or bitline remains constant as the source line voltage increases. For example, when ARYGND creeps up above 0V (which means that the source line also will creep above 0V), it is desired that the difference between a word line and a source line will be increased adaptively to maintain the current of the cell or bitline at a constant level. The voltage on word line WL, for example, will be adaptively changed as a function of source line voltage to compensate for different effects from source voltage changes similarly as described above for Figure 40. The word line voltage adaptation preferably also compensates for voltage coupling between the WL and FG terminals.

[00187] In Figure 42, graph 4000 indicates that it is desired that the difference between a bit line and a source line for a selected cell (labeled as $d(BL-SL)$) is such that the current from the selected cell(s) or bitline remains constant as the source line voltage increases. For example, when ARYGND creeps up above 0V (which means that the source line also will creep above 0V), it is desired that the difference between a bit line and a source line is such that the current from the selected cell(s) or bitline remains at a constant level. The voltage on bit line BL, for example, will be adaptively increased as a function of source line voltage to compensate for

Attorney Docket Number: 351913-980132

different effects such as from reduced drain-to-source voltage, body effect modulated threshold voltage, voltage coupling from source to FG, or other electrical effects.

[00188] In Figure 43, it can be seen in graph 4300 that as temperature of a VMM array increases (as will naturally happen during operation of the VMM array or due to changes in the environment), the bias voltage that should be applied to the control gate line, and/or erase gate line, and/or word line to effect the same operation will decrease as a function of increasing temperature for the sub-threshold operation region. The bias voltage may increase as a function of increasing temperature in the linear or saturation operation region. The appropriate compensation function or a look-up-table, for example, can be characterized from silicon data. That is, in addition to changes in the voltage of ARYGND, changes in temperature also may affect the operation and accuracy of a VMM array. In one embodiment, an on-chip temperature sensor is implemented to detect the change in temperature and apply the compensation function for bias voltages accordingly.

[00189] Figure 44A depicts an adaptive bias circuit 4410, which comprises adjustable current source 4401 and adjustable resistor 4402. One end of resistor 4402 is coupled to adjustable current source 4401 at node VREF_AB 4403, and the other end of resistor 4402 is connected to the node ARYGND from Figure 20 or Figure 30. When the voltage of ARYGND changes, the voltage of node VREF_AB will change by approximately the same amount, as the voltage drop across resistor 4402 will remain constant for a constant current generated by adjustable current source 4401. The resistor 4402 can be adjusted to change the voltage VREF_AB according to a defined compensation function or a look-up-table to change as a function of ARYGND voltage. Similarly, the resistance of resistor 4402 may be changed as a function of temperature changes. In addition to, or in place of, or in combination with, any adjustment to the resistance of resistor 4402, the amount of current provided by adjustable current source 4401 can be adjusted according to a defined compensation function or a look-up-table to change as a function of either temperature or changes in the voltage of ARYGND. VREF_AB therefore will reflect any real-time changes in the voltage of ARYGND and temperature and can be utilized by various circuits during read or programming operations.

[00190] Figure 44B depicts adaptive bias circuit 4420, which consists of adjustable resistor 4421, adjustable resistor 4422, and op-amp 4423. The resistance of resistor 4421 and/or resistor

Attorney Docket Number: 351913-980132

4422 can be adjusted according to a defined compensation function or a look-up-table to change as a function of ARYGND voltage so as to provide a desired voltage VREF_AB at node 4424. The resistance of resistor 4421 and/or resistor 4422 can be adjusted according to a defined compensation function or a look-up-table to change as a function of temperature.

[00191] Figures 45A and 45B depict regulator 4500 (comprising regulator 4510 or regulator 4520, respectively) that optionally can receive the voltage VREF_AB from adaptive bias circuit 4400 at node IN to provide a regulated voltage output at node OUT. Regulator 4520 is used in a force/sense configuration to compensate, for example, for interconnect metal line voltage drop of power bus routing, where the voltage at output node OUT is switchably connected to a feedback voltage FB, so as to force the voltage at output node OUT to follow the feedback voltage FB. When applied to VMM system 2000, the voltage OUT can be applied to node SLARY 2888, as discussed above with reference to Figure 20.

[00192] The voltage VREF_AB at node IN is determined from a lookup table or a function based on characterization data. The output voltage at node OUT, can be used to provide bias to ARYGND or SLARY. For example, node OUT can be used as a supply a SL bias for the whole array, such as SLARY, e.g., 0v or 15mV. Node OUT also can be used as a bias applied to one or more bit lines, for example, to compensate for coupling mismatch, body effect mismatch, or PVT mismatch, without limitation. Node OUT also can be used as a bias voltage for Vcg, for example, to compensate for coupling mismatch, body effect mismatch, or PVT mismatch, without limitation.

[00193] Figure 46A depicts an adaptive bias circuit comprising input digital-to-analog converter 4600. Input digital-to-analog converter 4600 received digital input signal DIN[7:0] and generates an analog signal that can be applied to an input line of a VMM array, such as a control gate line, a word line, an erase gate line, or a source line to program one or more selected cells in the VMM array. Notably, input digital-to-analog converter 4600 utilizes voltage source VREF_AB from Figures 44 and 45, and it utilizes ARYGND from Figures 20 and 44A as its ground. Input digital-to-analog converter 4600 automatically compensates for variations in ARYGND through its usage of the VREF_AB voltage.

[00194] Figure 46B depicts an adaptive bias circuit comprising an output analog-to-digital converter 4650. Output analog-to-digital converter 4650 receives array output such as current or

Attorney Docket Number: 351913-980132

voltage and generates digital output bits. Notably, output analog-to-digital converter 4650 utilizes voltage source VREF_AB from Figures 44A and/or 44B, and it utilizes ARYGND from Figures 20 and 44A as its ground. Thus, output analog-to-digital converter 4650 will compensate for variations in ARYGND through its usage of the VREF_AB voltage.

[00195] Figure 47 depicts adjustable bias row decoder 4700, which comprises word line decoder 4701 coupled to control gate decoder 4702. In this example, adjustable bias row decoder 4700 is used for row 0 in a VMM array. All of the other rows in the array will have a similar adjustable bias row decoder assigned to it.

[00196] Word line decoder 4701 comprises PMOS transistor 4703 and NMOS transistor 4704 arranged as an inverter and NAND gate 4705, configured as shown. Control gate decoder 4702 comprises input digital-to-analog converter 4600 from Figure 46, inverter 4706, switch 4707, switch 4708, and NMOS transistor 4709 acting as a pass gate, configured as shown. Here, the word line WL0 and the control gate line CG0 will be activated when NAND dated 4705 receives address signals corresponding to the row assigned to adjustable bias row decoder 4700 (here, row 0). In that instance when WL0 and CG0 are activated, the analog output voltage of input digital-to-analog converter 4600 will be applied to control gate CG0. Here, the control gate line CG0 receives a compensated bias voltage provided by input digital-to-analog converter 4600. Similar means for EG or WL compensation can be used as well.

[00197] Figure 48 depicts current-to-voltage summer circuit 4800, which is used to convert array output (BL) current into a voltage, which is identical to current-to-voltage summer circuit 3100 in Figure 31 except that operational amplifier 3102 receives VREF_AB (from Figures 44 and 45) instead of VREF on its non-inverting input and the array output currents refers to virtual ground node ARYGND.

[00198] Figure 49 depicts current-to-voltage summer circuit 4900 comprising operational amplifier 4901, variable resistor 4902, and current source 4903 drawing current Ineu (which is a current received from a bit line of a VMM array). Operational amplifier receives VREF_AB (from Figures 44A and/or 45B) on its non-inverting input. Operational amplifier 4901 outputs a voltage, Vneuout. The array output currents refers to virtual ground node ARYGND.

[00199] Figure 50 depicts current-to-voltage summer 5000, which is identical to current-to-voltage summer 3200 in Figure 32 except that operational amplifier 3202 receives VREF_AB

Attorney Docket Number: 351913-980132

(from Figures 44A and/or 44B) instead of VREF on its non-inverting input. The array output currents refers to virtual ground node ARYGND.

[00200] Figure 51 depicts voltage summer 5100, which is identical to voltage summer 3300 in Figure 33A except that it utilizes voltage VREF_AB (from Figures 44A and/or 44B) instead of VREF. The array output voltage Vinx refer to virtual ground node ARYGND.

[00201] Figure 52 depicts voltage summer 5200, which is identical to voltage summer 3350 in Figure 33B except that it utilizes voltage VREF_AB (from Figures 44A and/or 44B) instead of VREF. The array output voltage Vinx refer to virtual ground node ARYGND.

[00202] Figure 53 depicts VMM high voltage decode circuits, comprising erase gate decoder circuit 5301, control gate decoder circuit 5304, source line decoder circuit 5307, and high voltage level shifter 5311, which are appropriate for use with memory cells of the type shown in Figure 3.

[00203] Erase gate decoder circuit 5301 comprises PMOS select transistor 5302 (controlled by signal HVO_B) and NMOS de-select transistor 5303 (controlled by signal HVO_B), configured as shown.

[00204] Control gate decoder circuit 5304 comprises PMOS select transistor 5304 (controlled by signal HVO_B) and NMOS de-select transistor 5306 (controlled by signal HVO_B), configured as shown.

[00205] Source line decoder circuit 5307 comprises NMOS monitor transistor 5308 (controlled by signal SL_MON), driving transistor 5309 (controlled by signal HVO , and de-select transistor 5310 (controlled by signal HVO_B), configured as shown.

[00206] High voltage level shifter 5311 receives enable signal EN and outputs high voltage signal HV and its complement HVO_B, and receives for its voltage rails HVSUP (a high voltage) and HVSUP_LOW.

[00207] It should be noted that, as used herein, the terms “over” and “on” both inclusively include “directly on” (no intermediate materials, elements or space disposed therebetween) and “indirectly on” (intermediate materials, elements or space disposed therebetween). Likewise, the term “adjacent” includes “directly adjacent” (no intermediate materials, elements or space disposed therebetween) and “indirectly adjacent” (intermediate materials, elements or space disposed there between), “mounted to” includes “directly mounted to” (no intermediate

Attorney Docket Number: 351913-980132

materials, elements or space disposed there between) and “indirectly mounted to” (intermediate materials, elements or spaced disposed there between), and “electrically coupled” includes “directly electrically coupled to” (no intermediate materials or elements there between that electrically connect the elements together) and “indirectly electrically coupled to” (intermediate materials or elements there between that electrically connect the elements together). For example, forming an element “over a substrate” can include forming the element directly on the substrate with no intermediate materials/elements therebetween, as well as forming the element indirectly on the substrate with one or more intermediate materials/elements there between.

Attorney Docket Number: 351913-980132

What is claimed is:

1. A non-volatile memory system, comprising:
an array of non-volatile memory cells arranged in rows and columns, each non-volatile memory cell comprising a source and a drain;
a plurality of bit lines, each of the plurality of bit lines coupled to the drain of each non-volatile memory cell in a column of non-volatile memory cells;
a source line coupled to the source of each non-volatile memory cell; and
an adaptive bias decoder for providing a voltage to a control gate line of the array during an operation, wherein the adaptive bias decoder adjusts the voltage provided to the control gate line in response to changes in a voltage of the source line.
2. The non-volatile memory system of claim 1, further comprising a plurality of pull down bit lines, each of the plurality of pull down bit lines coupling a row of non-volatile memory cells to a pull down node.
3. The non-volatile memory system of claim 1, wherein the operation is a program operation.
4. The non-volatile memory system of claim 3, wherein the adaptive bias decoder adjusts the voltage provided to the source line in response to changes in temperature.
5. The non-volatile memory system of claim 1, wherein the adaptive bias decoder adjusts the voltage provided to the source line in response to changes in temperature.
6. The non-volatile memory system of claim 1, wherein the adaptive bias decoder comprises a resistor comprising a first end and a second end, the first end coupled to an adjustable current source and the second end coupled to the source line.
7. The non-volatile memory system of claim 6, wherein the adaptive bias decoder further comprises a regulator coupled to the first end of the resistor.
8. The non-volatile memory system of claim 1, wherein the adaptive bias decoder adjusts the voltage provided to the control gate line based on a function performed on characterization data.
9. The non-volatile memory system of claim 1, wherein the adaptive bias decoder adjusts the voltage provided to the control gate line based on source line voltage changes.

Attorney Docket Number: 351913-980132

10. The non-volatile memory system of claim 1, wherein the adaptive bias decoder adjusts the voltage provided to the control gate line based on body effect change.

11. The non-volatile memory system of claim 1, wherein the adaptive bias decoder comprises an adjustable current source and an adjustable resistor.

12. The non-volatile memory system of claim 1, wherein the adaptive bias decoder comprises an operational amplifier and one or more adjustable resistors.

13. The non-volatile memory system of claim 1, wherein the adaptive bias circuit further comprises a digital-to-analog converter for converting a digital input to an analog signal applied to the control gate line.

14. The non-volatile memory system of claim 13, wherein the adaptive bias circuit further comprises an analog-to-digital for converting an array output current to digital output bits.

15. The non-volatile memory system of claim 1, wherein the adaptive bias circuit further comprises an output circuit for converting an array output to digital output bits.

16. The non-volatile memory system of claim 1, wherein the adaptive bias circuit further comprises an analog-to-digital for converting an array output current to digital output bits.

17. A non-volatile memory system, comprising:
an array of non-volatile memory cells arranged in rows and columns, each non-volatile memory cell comprising a source and a drain;
a plurality of bit lines, each of the plurality of bit lines coupled to the drain of each non-volatile memory cell in a column of non-volatile memory cells;
a source line coupled to the source of each non-volatile memory cell; and
an adaptive bias decoder for providing a voltage to a word line of the array during an operation, wherein the adaptive bias decoder adjusts the voltage provided to the word line in response to changes in a voltage of the source line.

18. The non-volatile memory system of claim 17, further comprising:
a plurality of pull down bit lines, each of the plurality of pull down bit lines coupling a row of non-volatile memory cells to a pull down node.

Attorney Docket Number: 351913-980132

19. The non-volatile memory system of claim 17, wherein the operation is a read operation.

20. The non-volatile memory system of claim 17, wherein the operation is a program operation.

21. The non-volatile memory system of claim 17, wherein the adaptive bias decoder adjusts the voltage provided to the source line in response to changes in temperature.

22. The non-volatile memory system of claim 17, further comprising an analog-to-digital converter.

23. The non-volatile memory system of claim 17, wherein the adaptive bias decoder comprises a resistor comprising a first end and a second end, the first end coupled to an adjustable current source and the second end coupled to the pull down node.

24. The non-volatile memory system of claim 23, wherein the adaptive bias decoder further comprises a voltage regulator coupled to the first end of the resistor.

25. The non-volatile memory system of claim 23, wherein the adaptive bias decoder further comprises a digital-to-analog converter for converting a digital input to an analog signal applied to the word line.

26. The non-volatile memory system of claim 17, wherein the adaptive bias decoder adjusts the voltage provided to the word line based on a function performed on characterization data.

27. The non-volatile memory system of claim 17, wherein the adaptive bias decoder adjusts the voltage provided to the word line based on source voltage changes.

28. The non-volatile memory system of claim 17, wherein the adaptive bias decoder adjusts the voltage provided to the word line based on body effect change.

29. The non-volatile memory system of claim 17, wherein the adaptive bias decoder adjusts the voltage provided to the word line based on coupling ratio change.

30. A non-volatile memory system, comprising:
an array of non-volatile memory cells arranged in rows and columns, each non-volatile memory cell comprising a source and a drain;
a plurality of bit lines, each of the plurality of bit lines coupled to the drain of each non-volatile memory cell in a column of non-volatile memory cells;

Attorney Docket Number: 351913-980132

a source line coupled to the source of each non-volatile memory cell; and

an adaptive bias decoder for providing a voltage to an erase gate line of the array during an operation, wherein the adaptive bias decoder adjusts the voltage provided to the erase gate line in response to changes in a voltage of the source line node.

31. The non-volatile memory system of claim 30, further comprising:

a plurality of pull down bit lines, each of the plurality of pull down bit lines coupling a row of non-volatile memory cells to a pull down node.

32. The non-volatile memory system of claim 30, wherein the operation is a read operation.

33. The non-volatile memory system of claim 30, wherein the operation is a program operation.

34. The non-volatile memory system of claim 30, wherein the adaptive bias decoder adjusts the voltage provided to the source line in response to changes in temperature.

35. The non-volatile memory system of claim 30, further comprising an analog-to-digital converter.

36. The non-volatile memory system of claim 30, wherein the adaptive bias decoder comprises a resistor comprising a first end and a second end, the first end coupled to an adjustable current source and the second end coupled to the pull down node.

37. The non-volatile memory system of claim 37, wherein the adaptive bias decoder further comprises a voltage regulator coupled to the first end of the resistor.

38. The non-volatile memory system of claim 37, wherein the adaptive bias decoder further comprises a digital-to-analog converter for converting a digital input to an analog signal applied to the erase gate line.

39. The non-volatile memory system of claim 30, wherein the adaptive bias decoder adjusts the voltage provided to the erase gate line based on a function performed on characterization data.

40. The non-volatile memory system of claim 30 wherein the adaptive bias decoder adjusts the voltage provided to the erase gate line based on source voltage modulation.

41. The non-volatile memory system of claim 30, wherein the adaptive bias decoder adjusts the voltage provided to the erase gate line based on body effect change.

Attorney Docket Number: 351913-980132

42. The non-volatile memory system of claim 30, wherein the adaptive bias decoder adjusts the voltage provided to the erase gate line based on coupling ratio change.

43. A non-volatile memory system, comprising:
an array of non-volatile memory cells arranged in rows and columns, each non-volatile memory cell comprising a source and a drain;
a plurality of bit lines, each of the plurality of bit lines coupled to the drain or each non-volatile memory cell in a column of non-volatile memory cells;
a source line coupled to the source of each non-volatile memory cell; and
an adaptive bias decoder for providing a fixed voltage to the source line of the array during operation.

44. The non-volatile memory system of claim 43, wherein the adaptive bias decoder adjusts the voltage provided to the source line in response to changes in temperature.

45. The non-volatile memory system of claim 43, wherein the adaptive bias decoder is a force/sense regulator.

46. The non-volatile memory system of claim 43, wherein the adaptive bias decoder is a buffer regulator.

47. The non-volatile memory system of claim 43, wherein the adaptive bias decoder adjusts the voltage provided to the source line in response to changes in temperature.

FIGURE 1
(PRIOR ART)

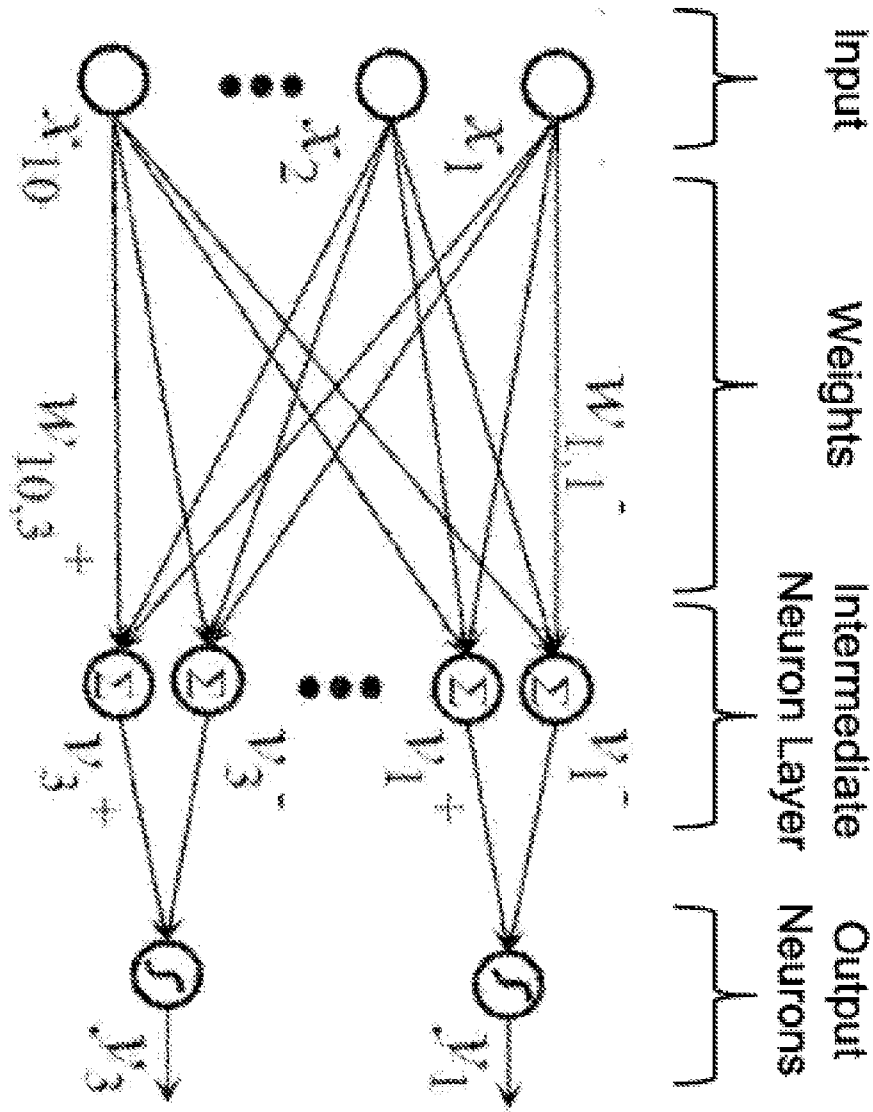


FIGURE 2
(PRIOR ART)

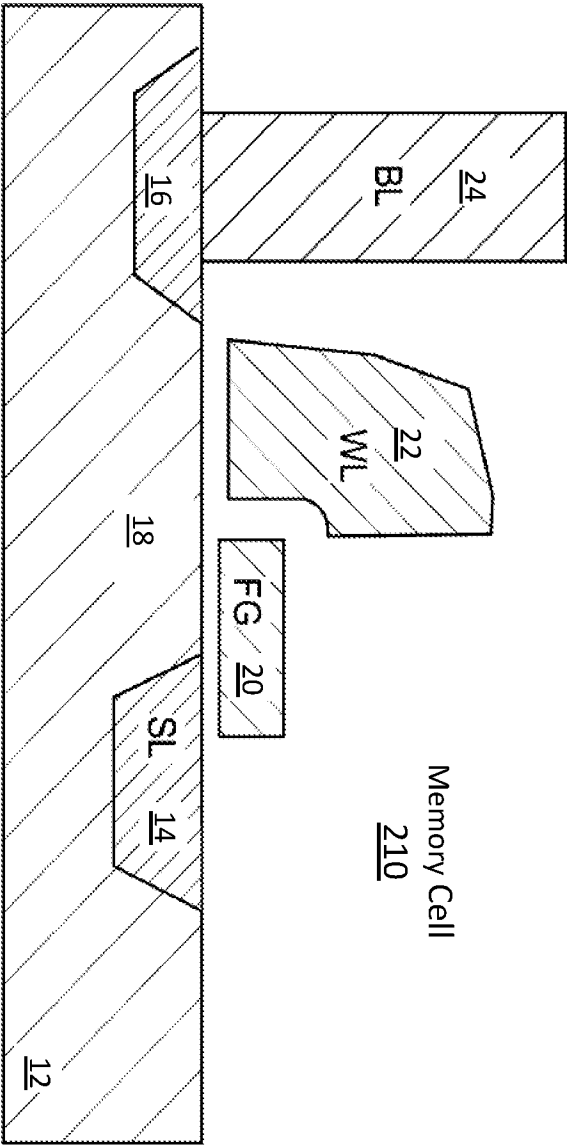


FIGURE 3
(PRIOR ART)

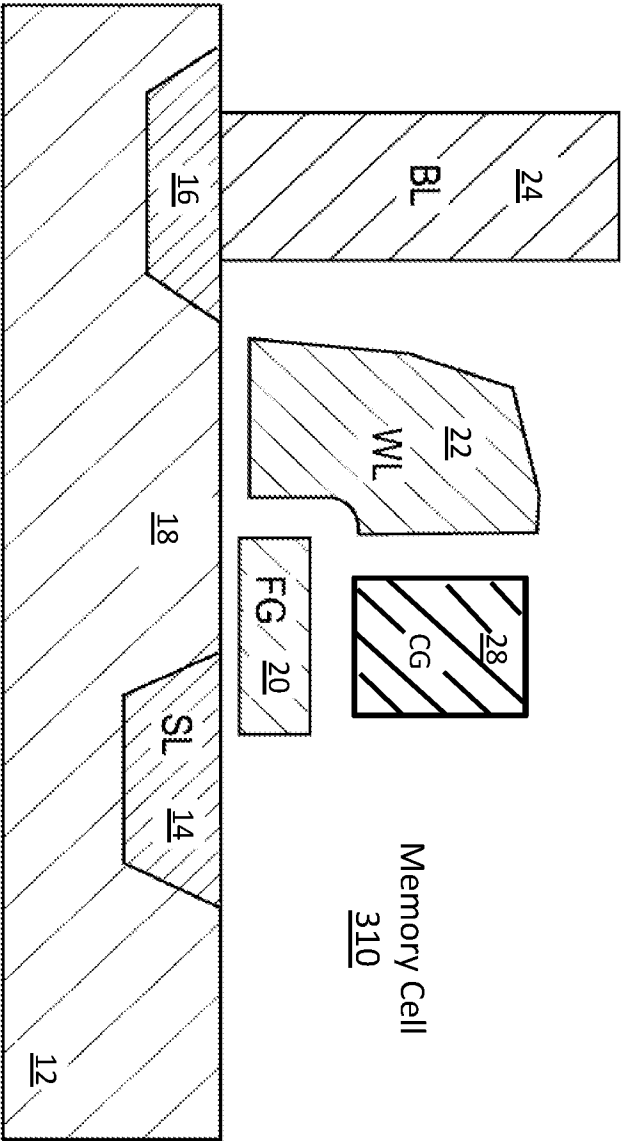


FIGURE 4
(PRIOR ART)

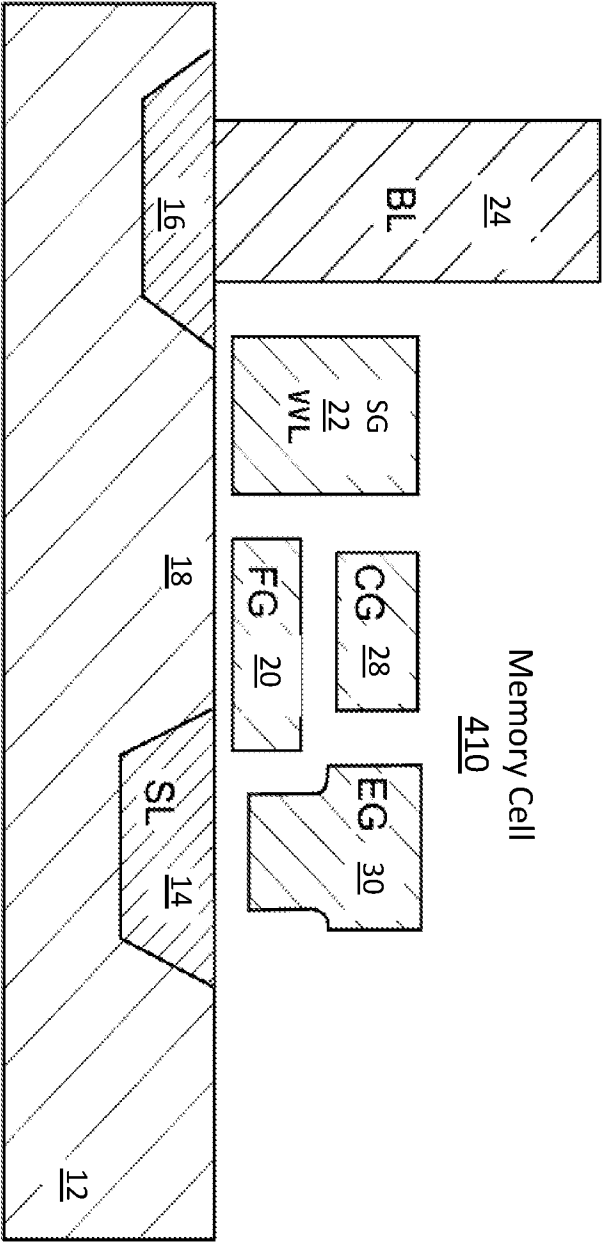


FIGURE 5
(PRIOR ART)

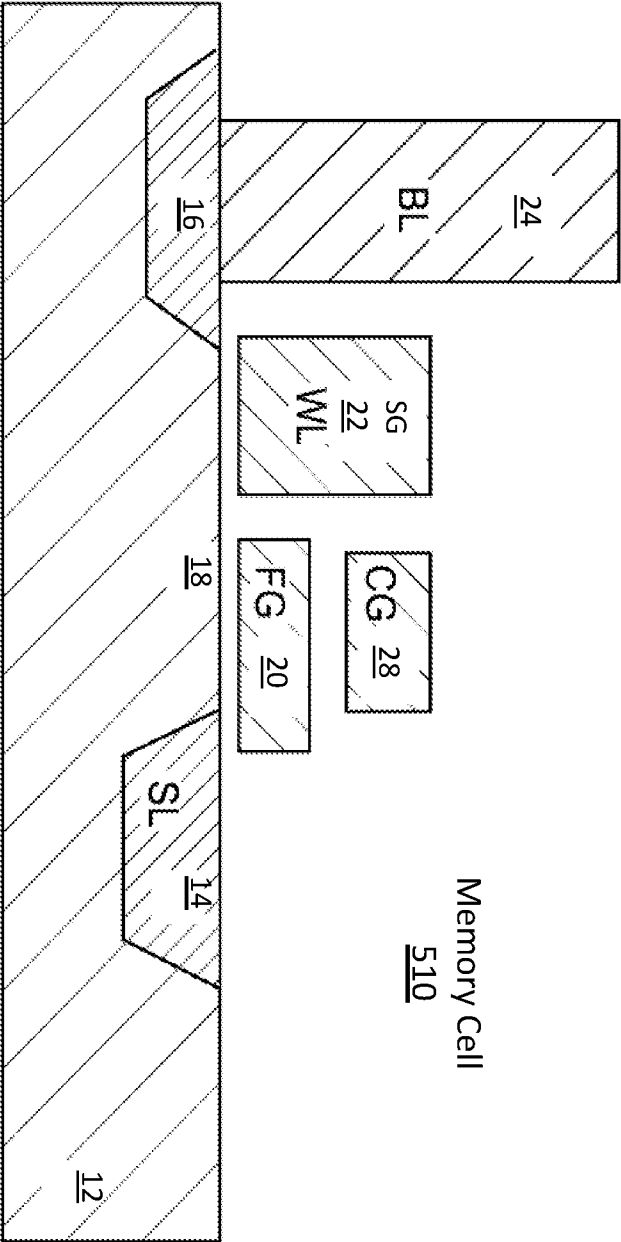


FIGURE 6
(PRIOR ART)

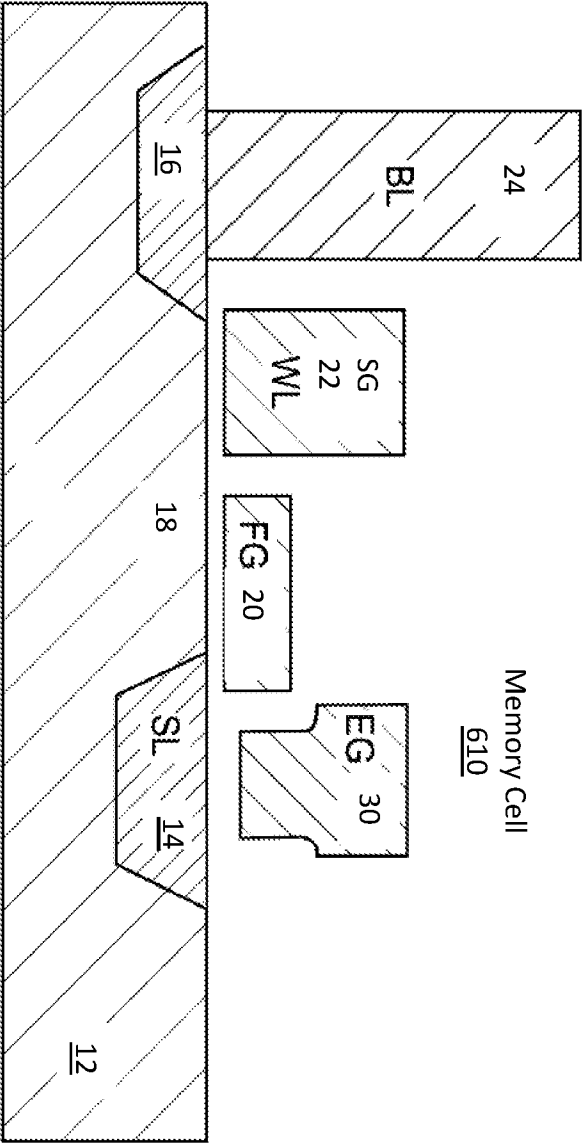


FIGURE 7
(PRIOR ART)

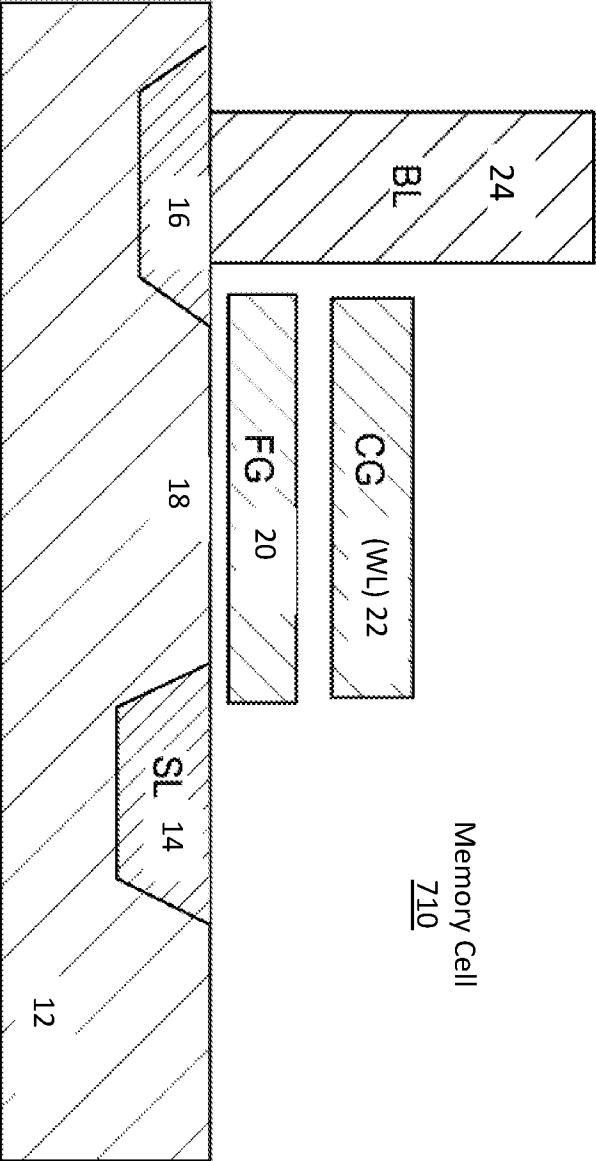


**FIGURE 8
(PRIOR ART)**

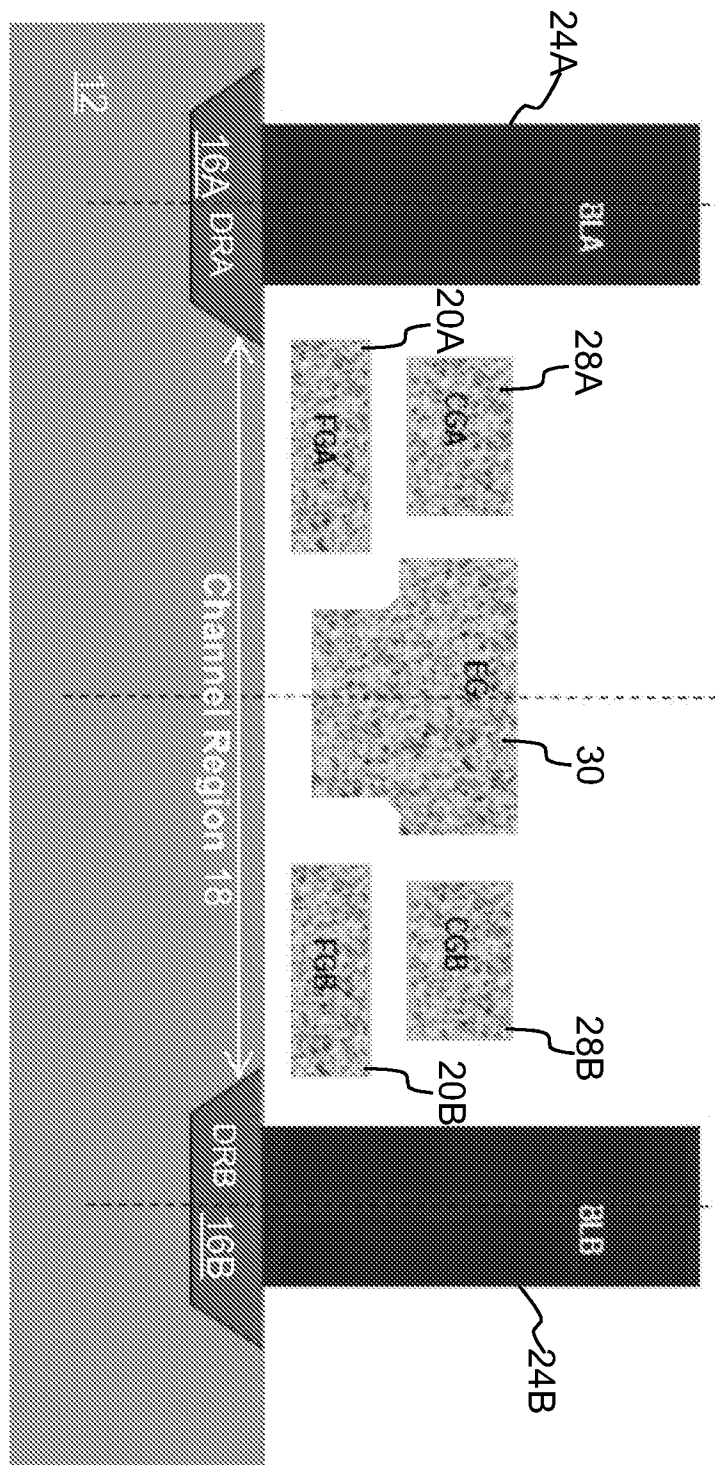
Memory Cell
810

FIGURE 9

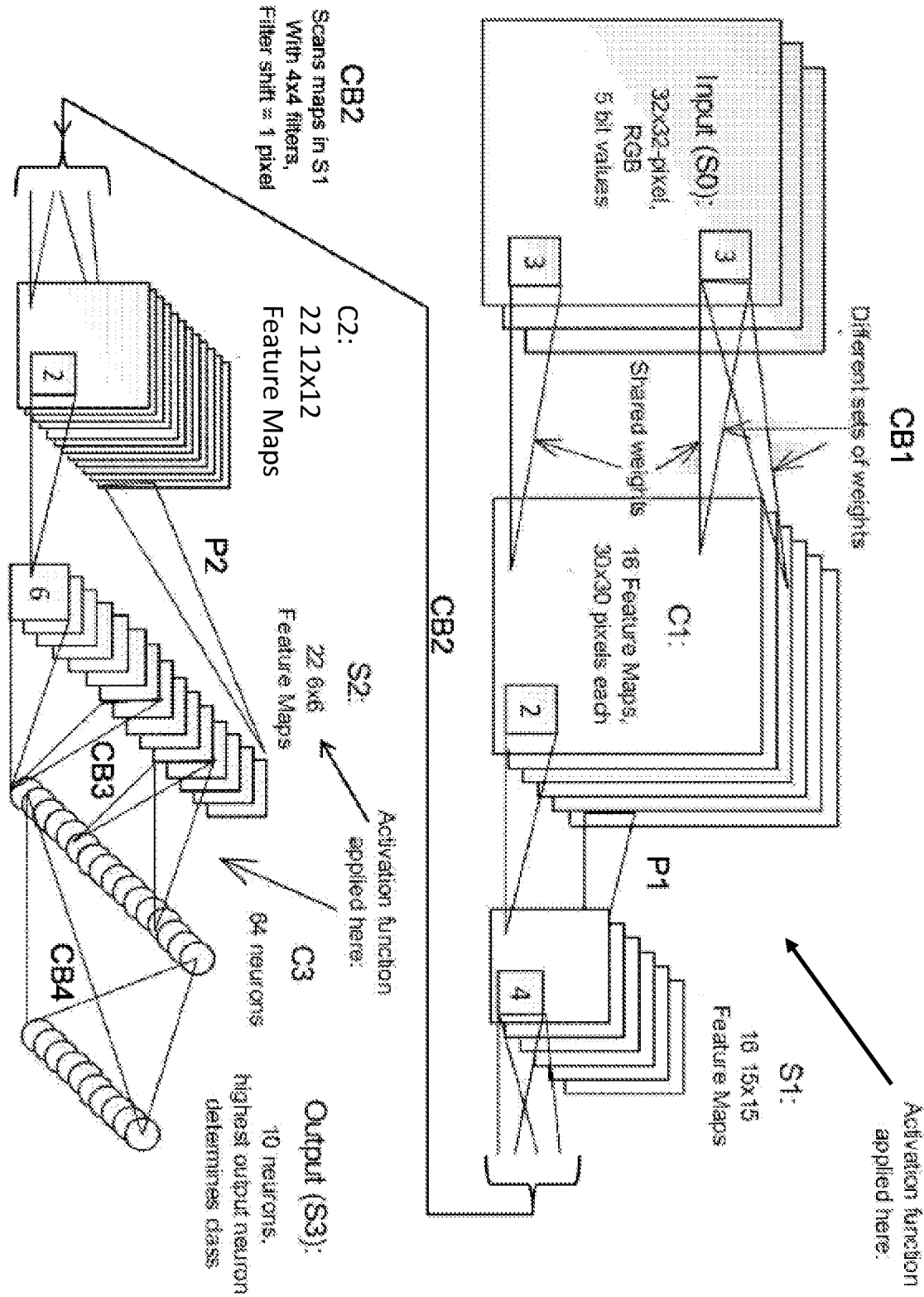


FIGURE 10

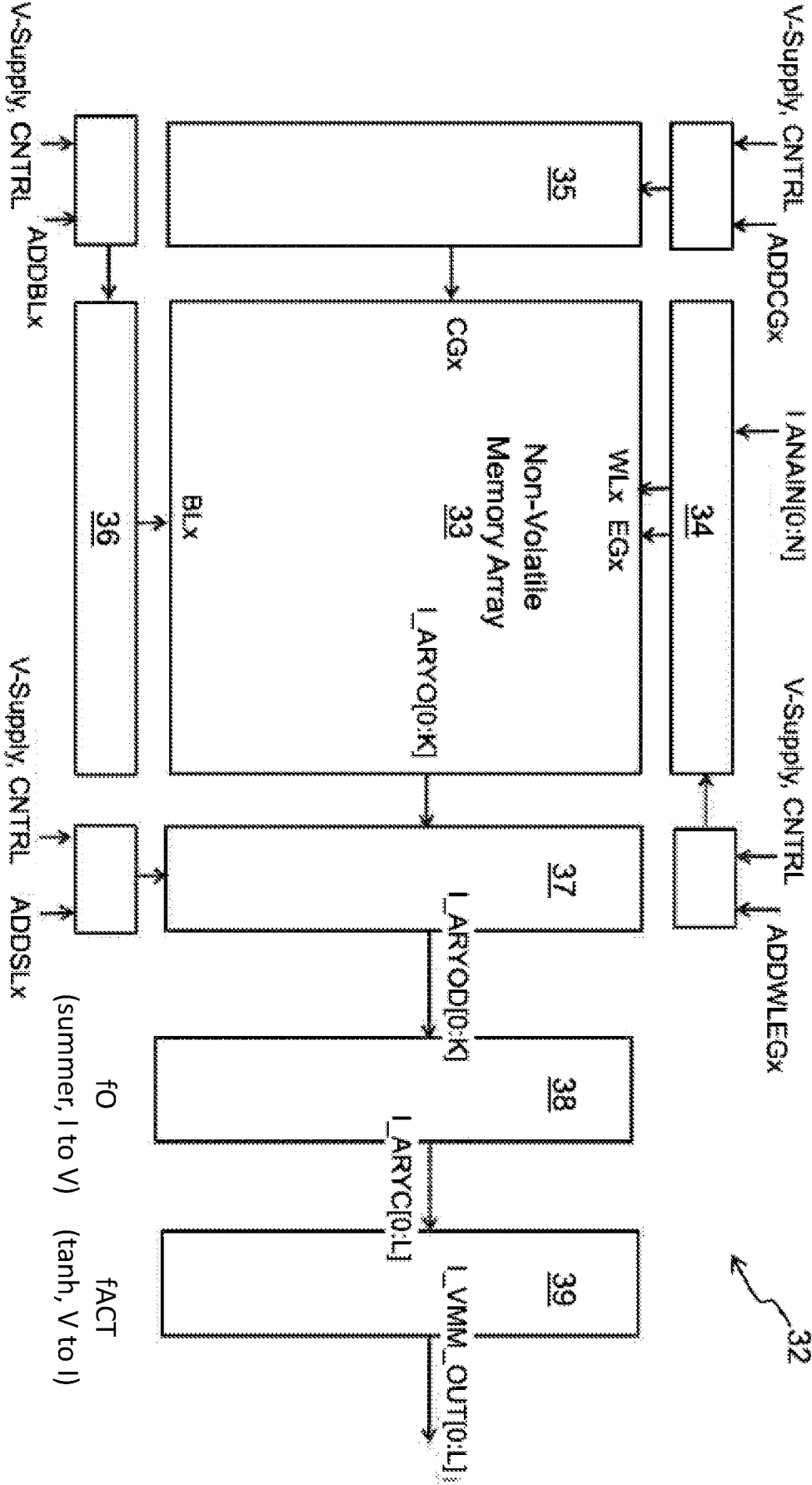


FIGURE 11

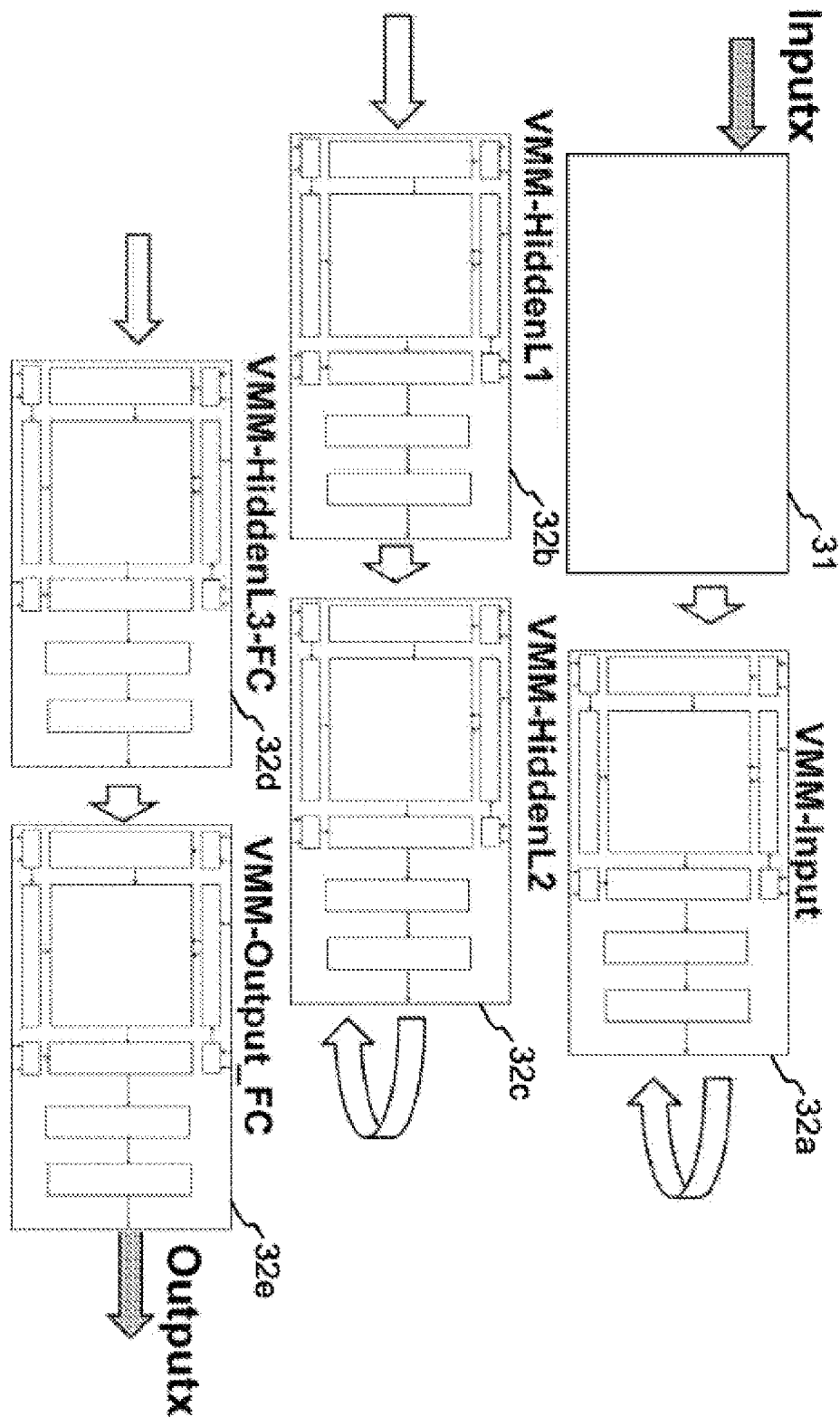


FIGURE 12

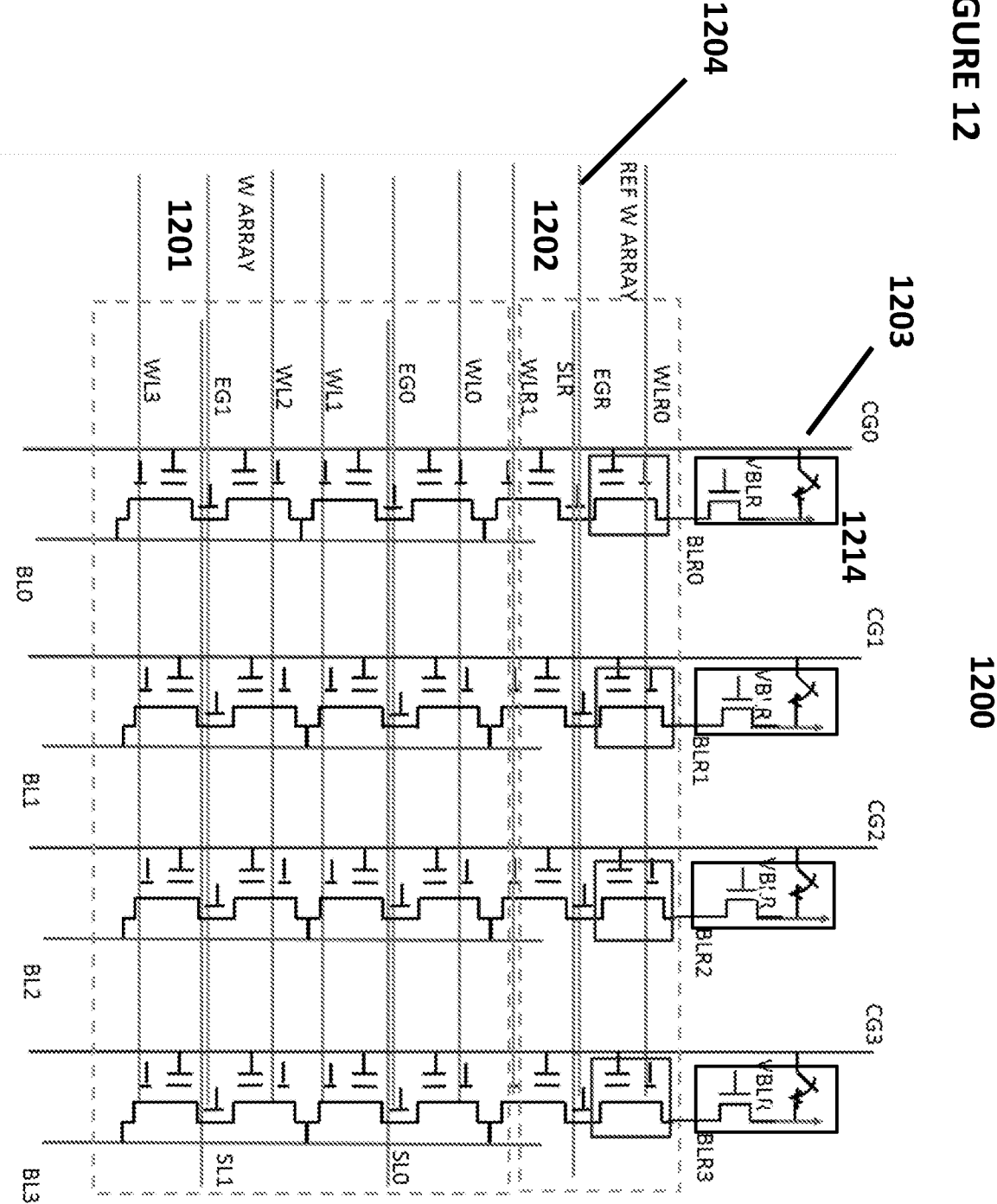


FIGURE 13

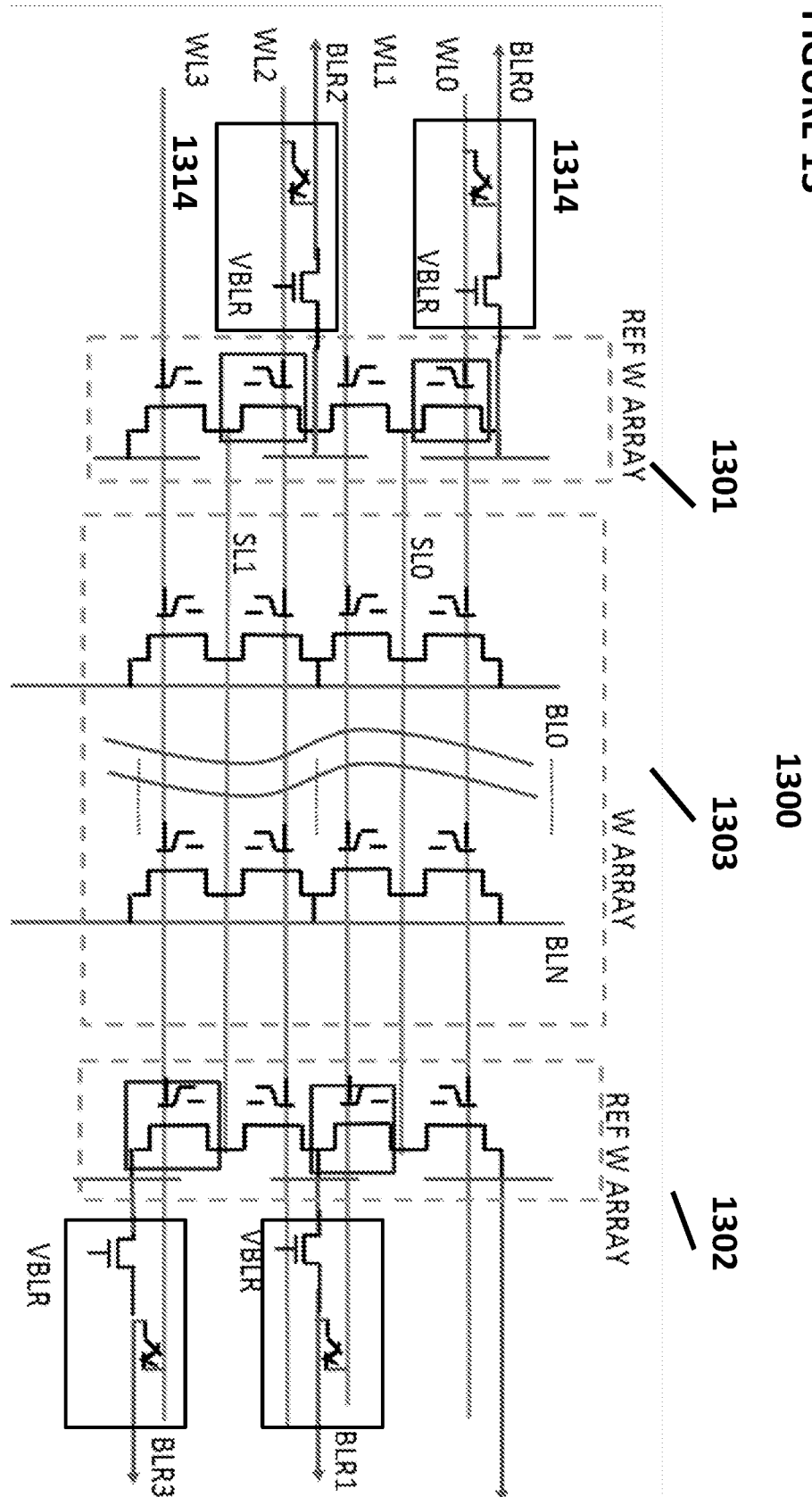


FIGURE 15

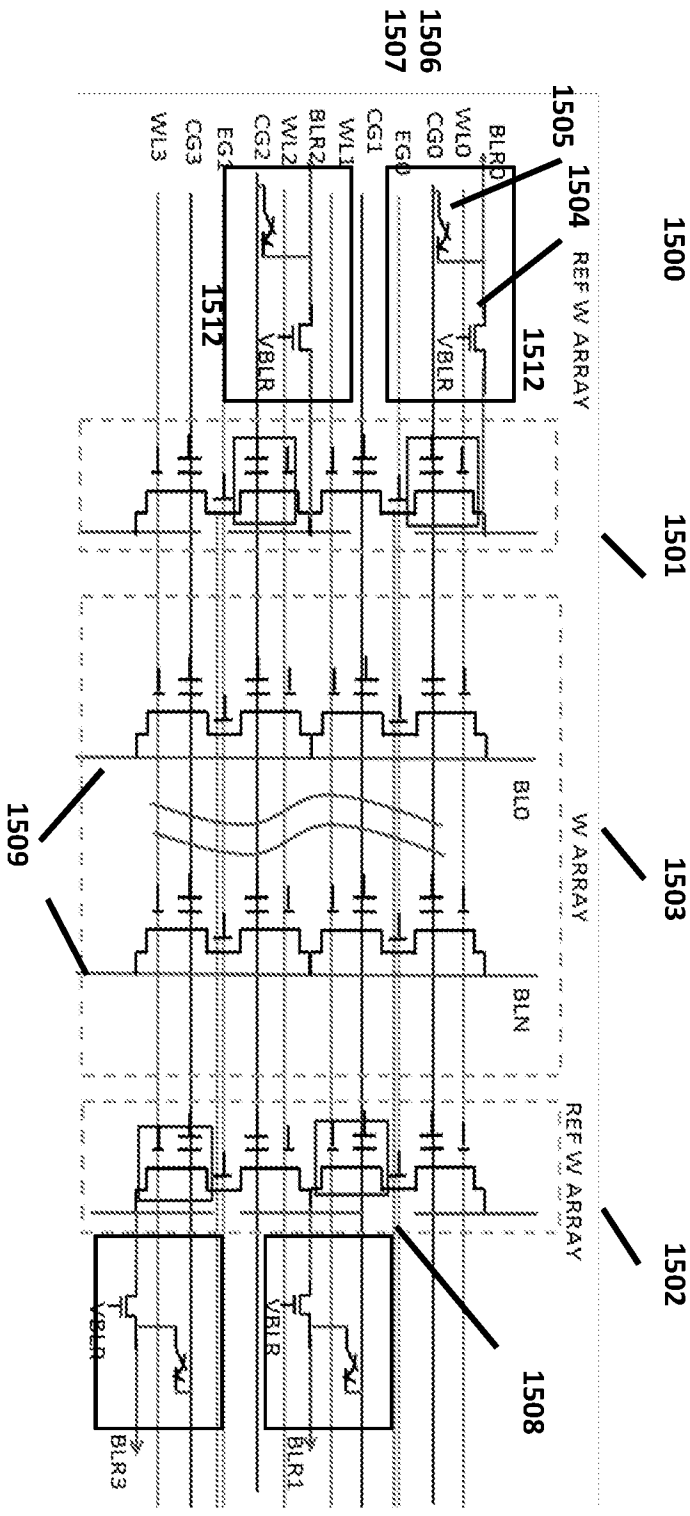
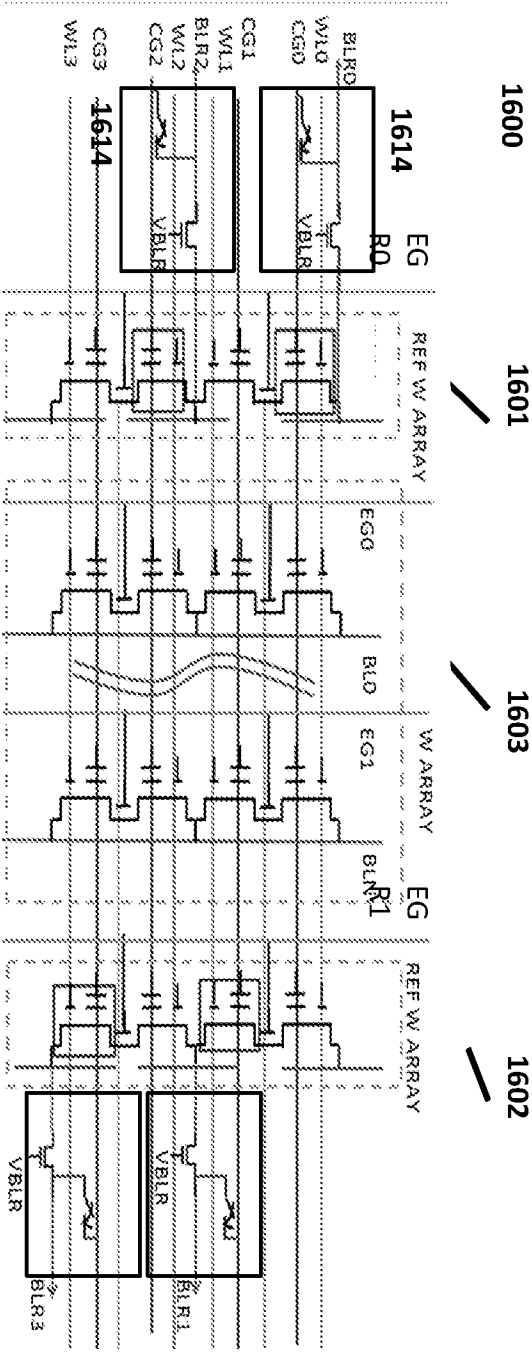


FIGURE 16



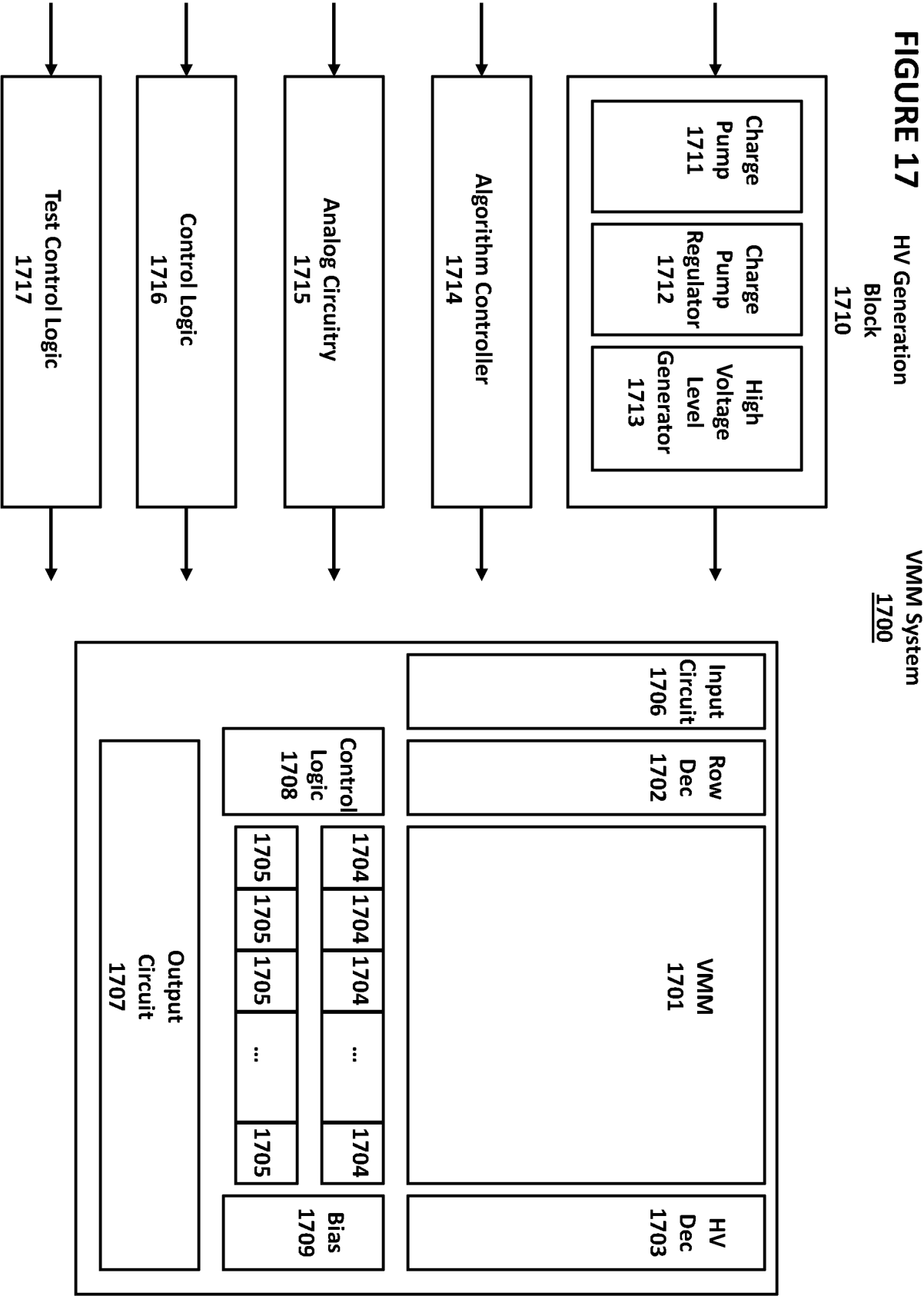


FIGURE 18A
(PRIOR ART)

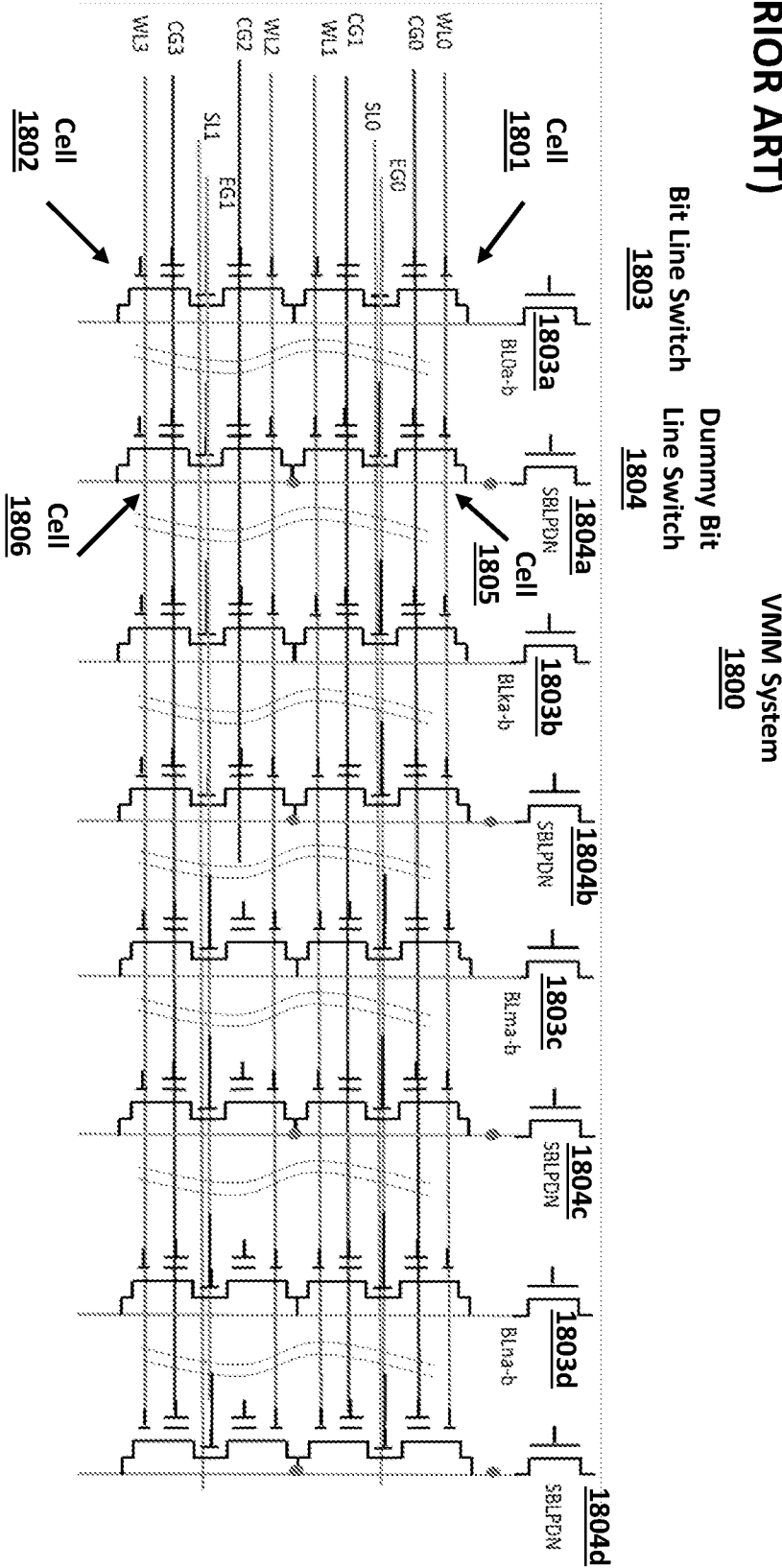


FIGURE 18B
(PRIOR ART)

VMM System
1800

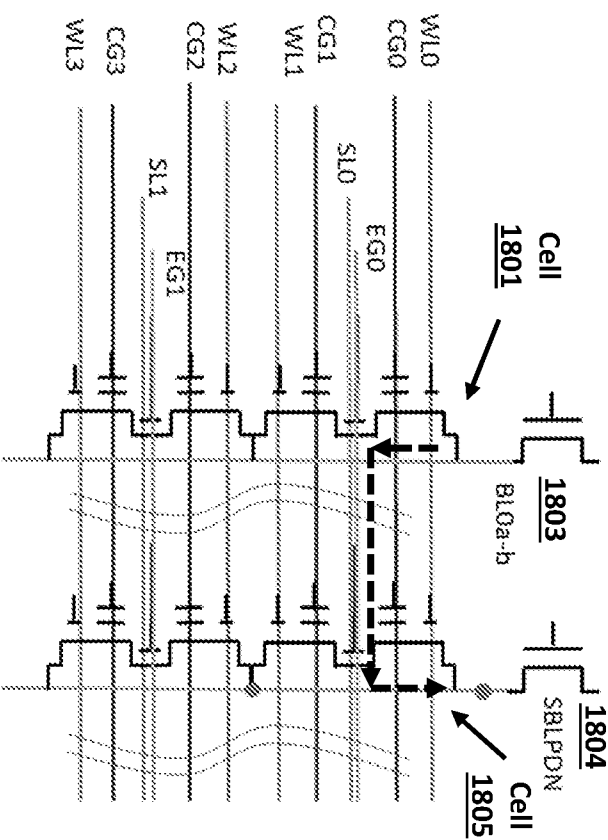


FIGURE 18C
(PRIOR ART)

VMM System
1800

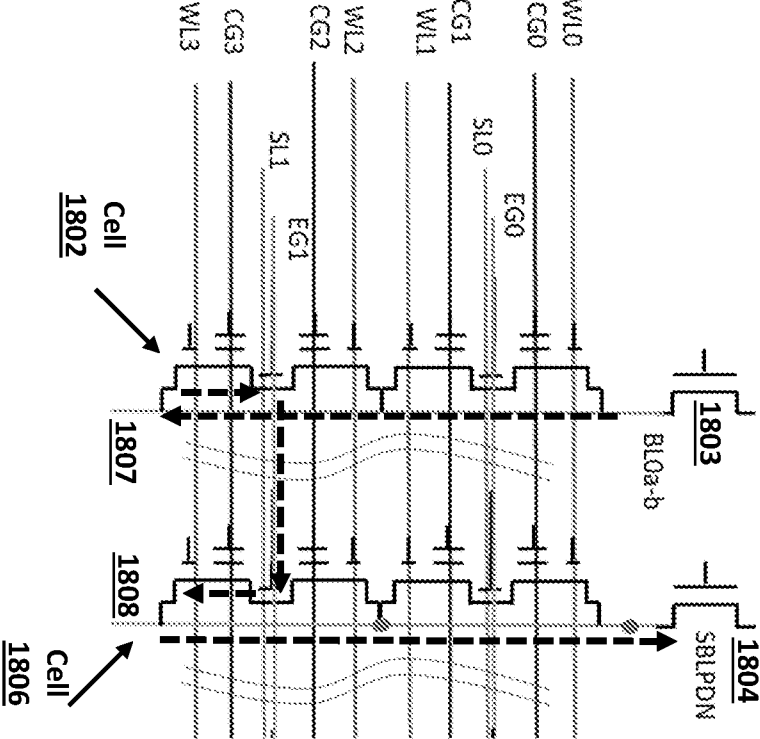


FIGURE 19A

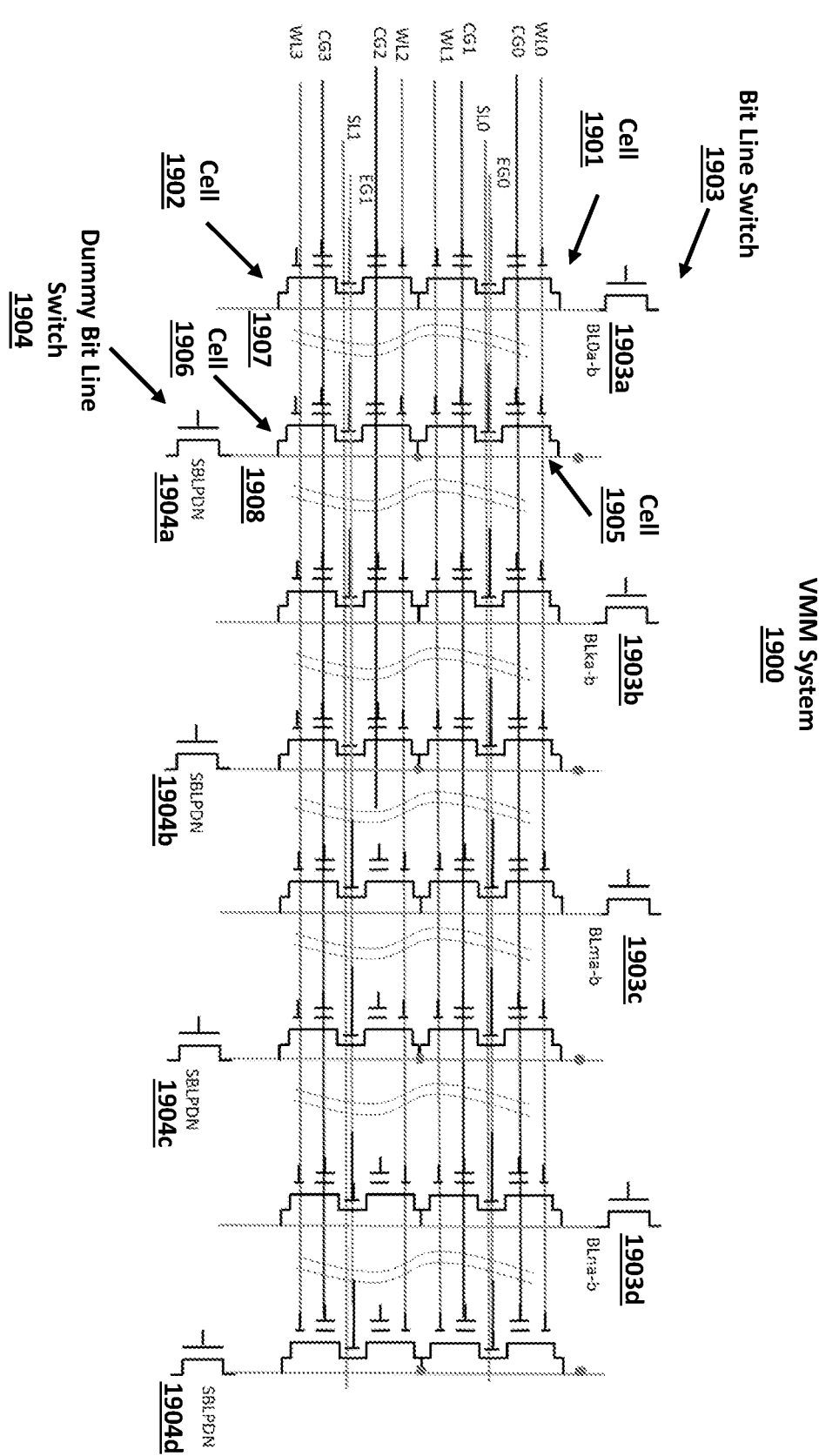


FIGURE 19B

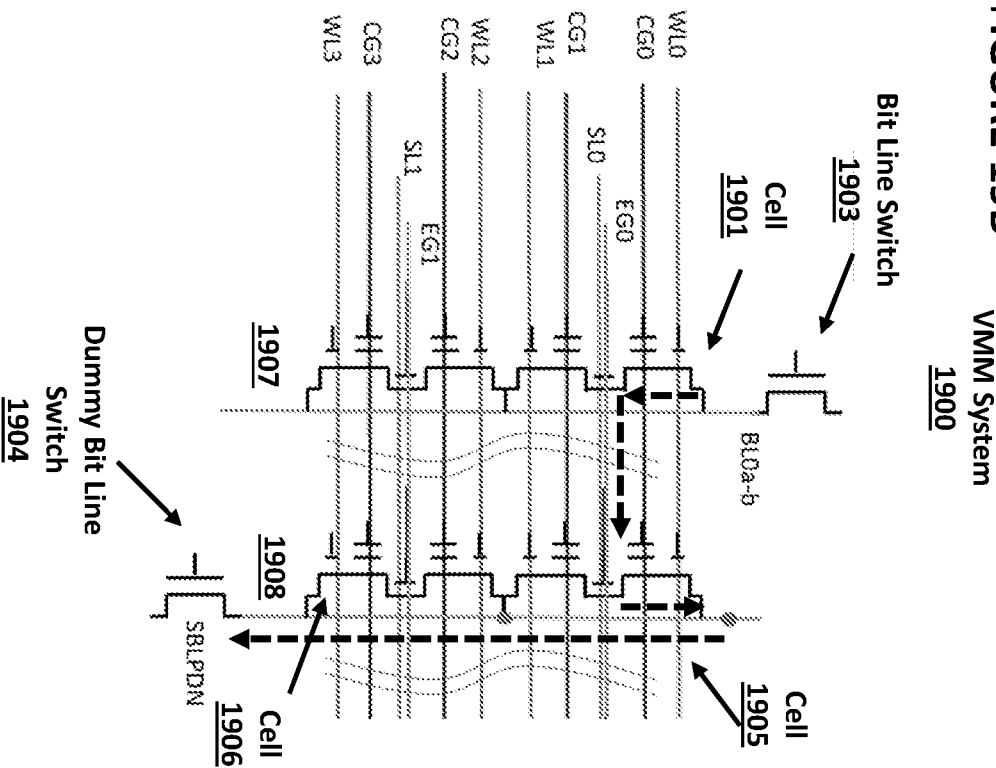


FIGURE 19C

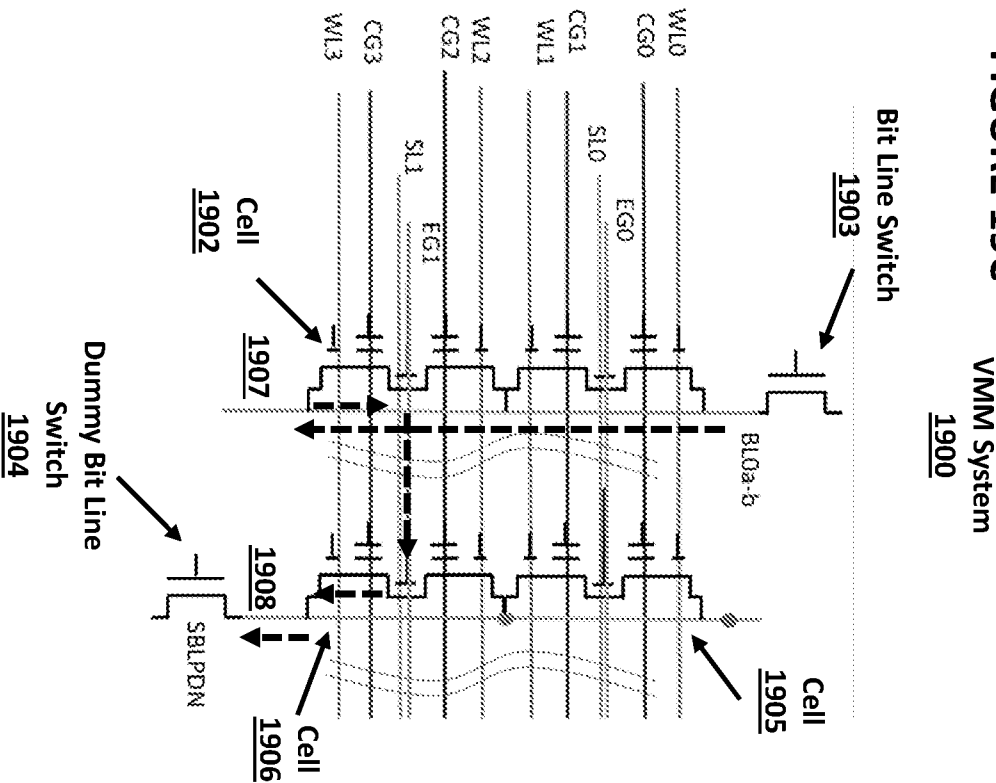


FIGURE 20

VMM System
2000

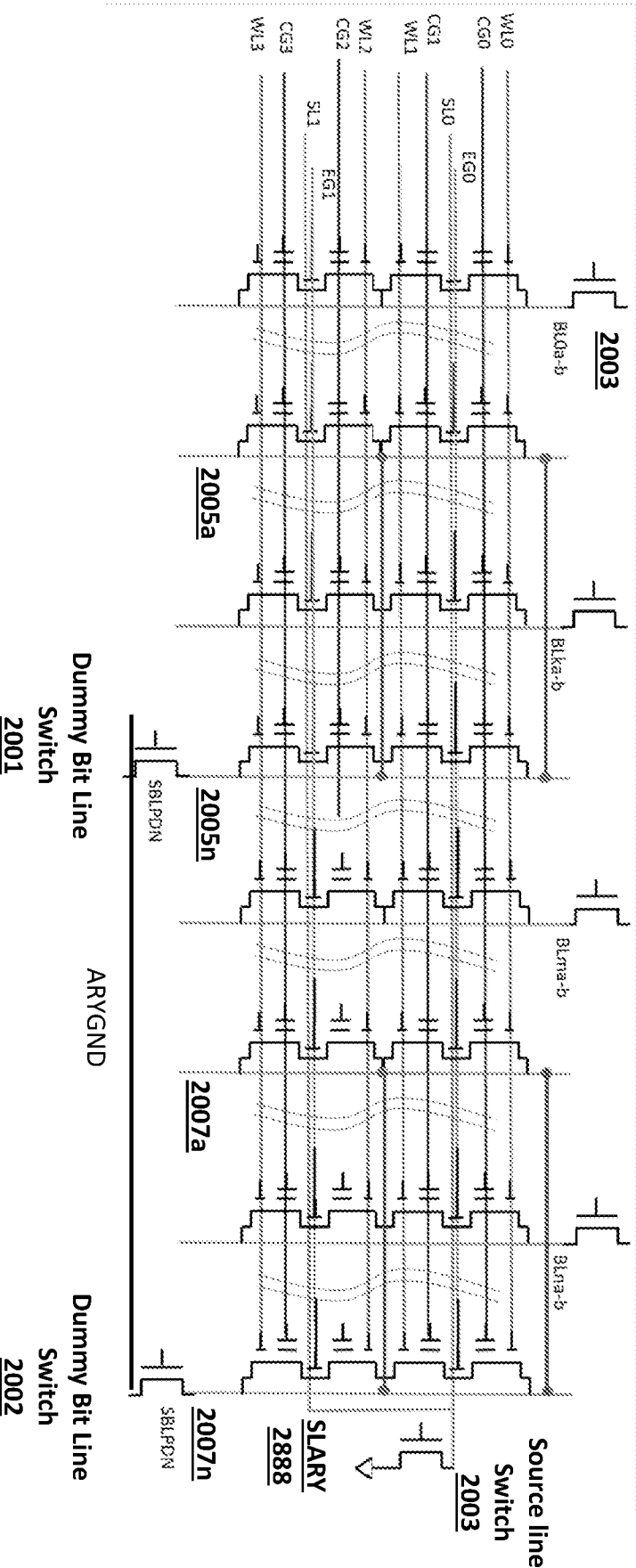


FIGURE 22

VMM System
2200

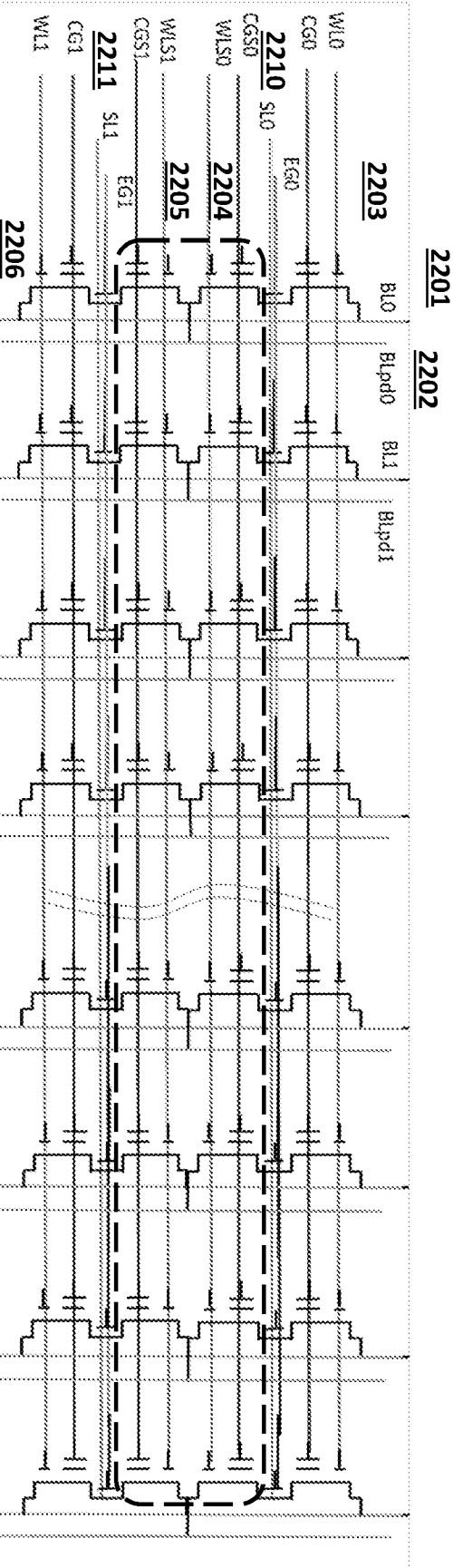


FIGURE 23

VMM System
2300

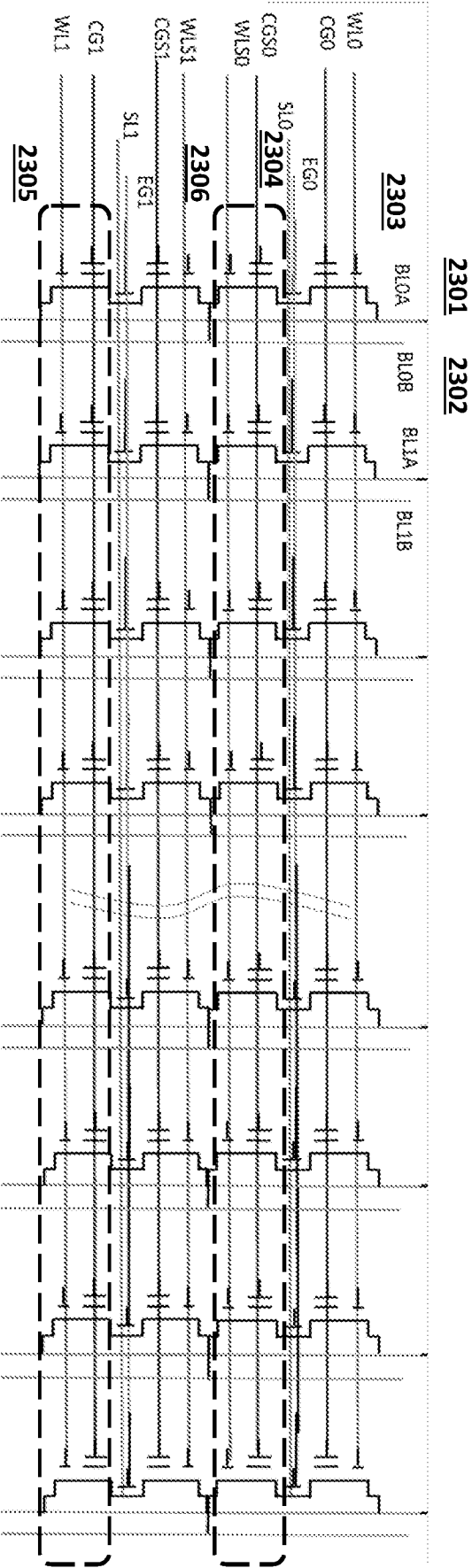


FIGURE 24

VMIM System
2400

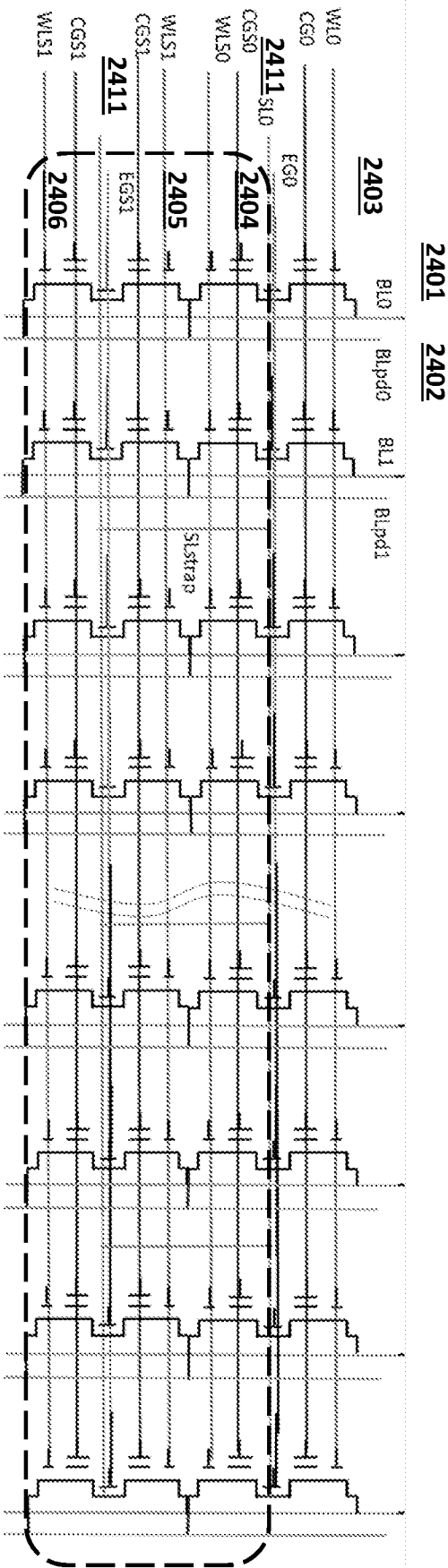


FIGURE 25

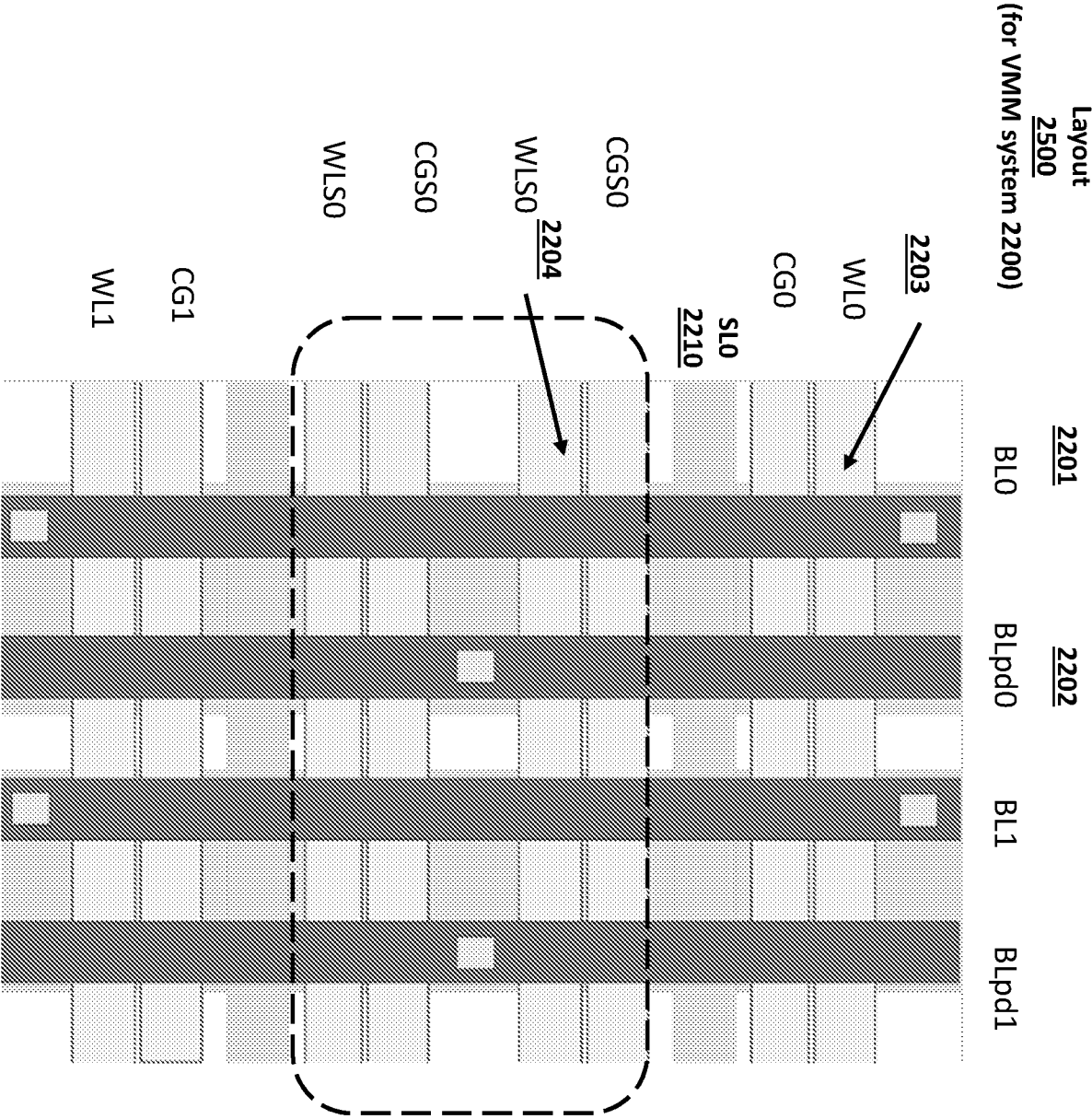


FIGURE 26

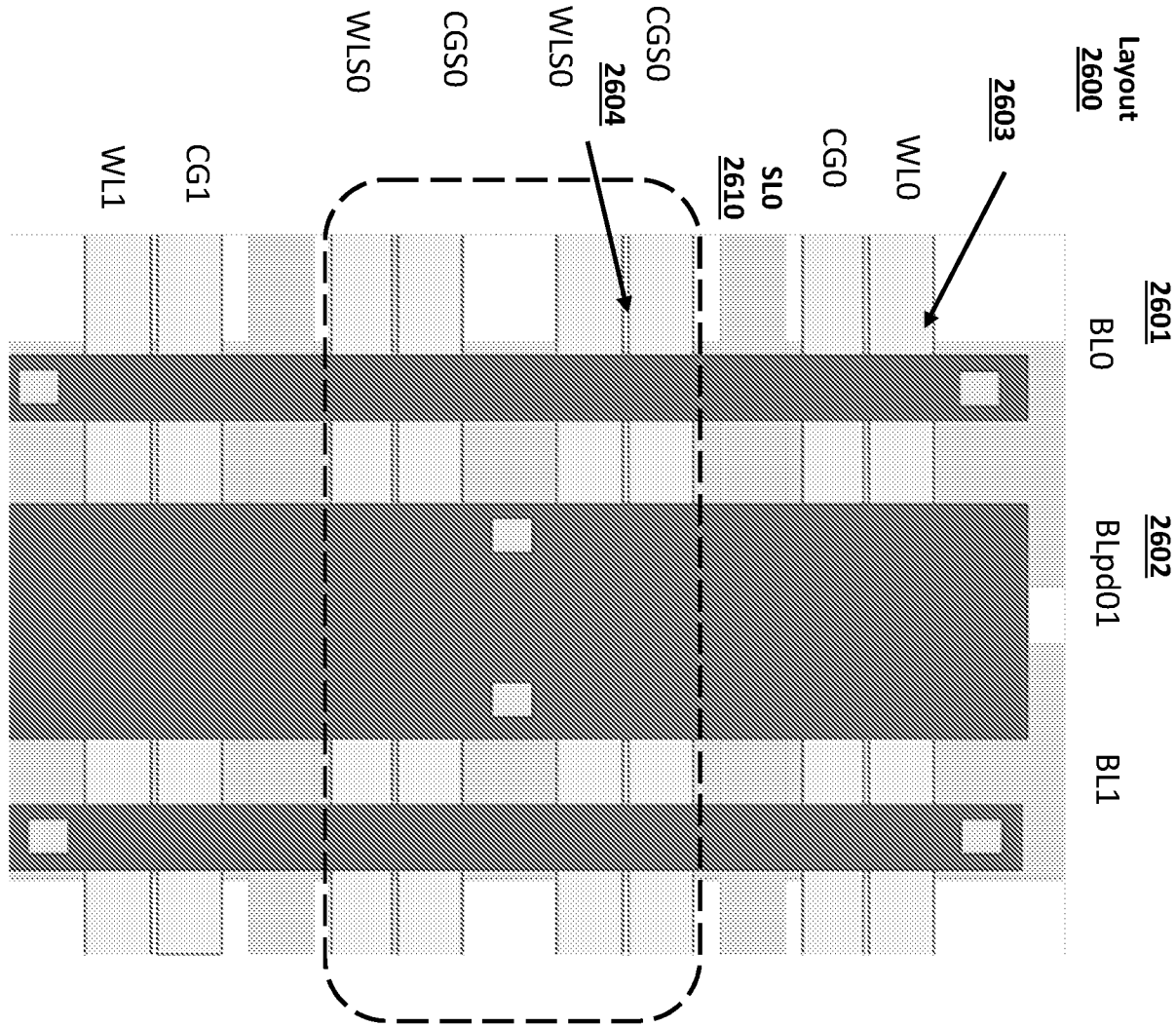


FIGURE 27A

VMM System
2700

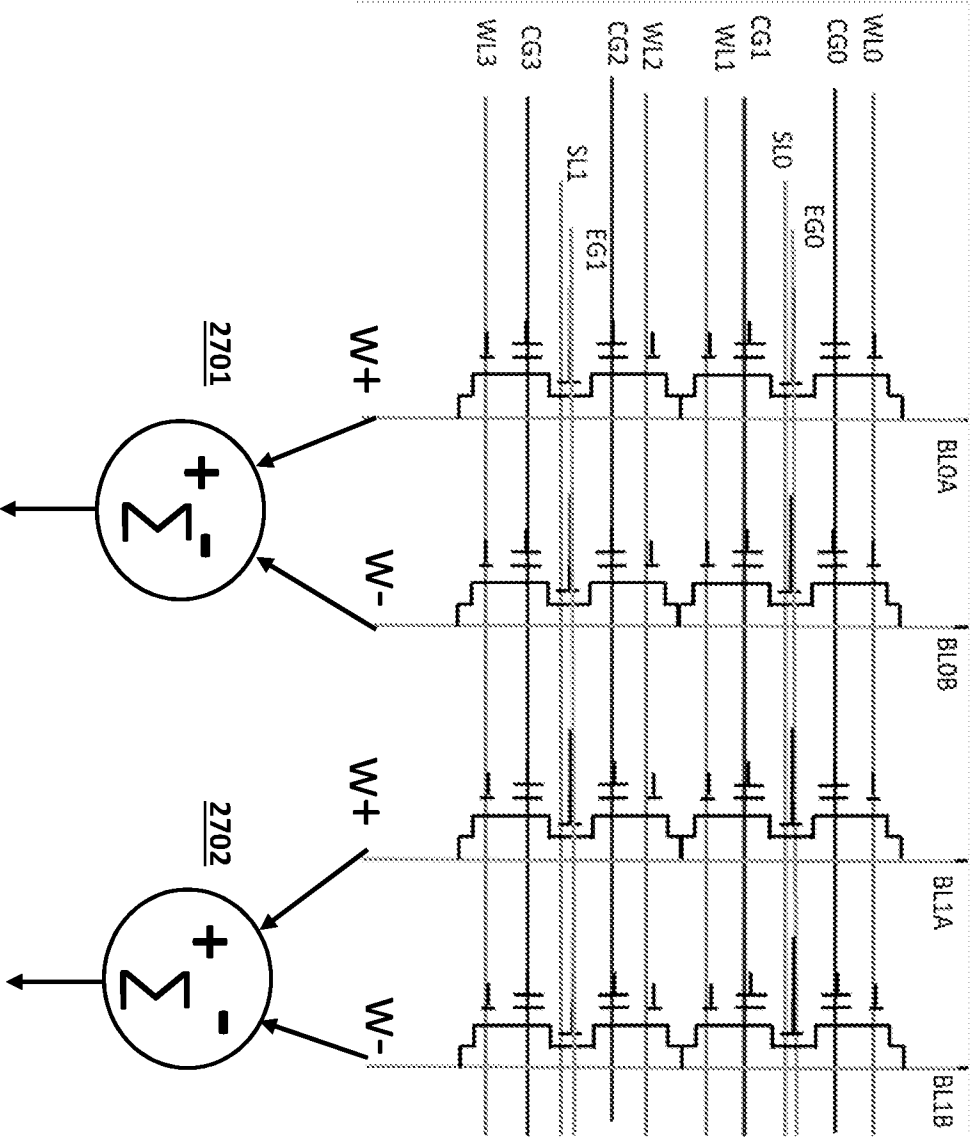
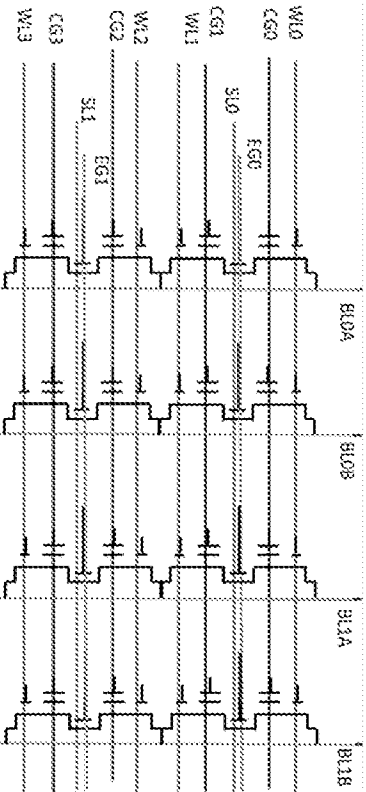


FIGURE 27B

VMM System
2710

W+ array

2711



W- array

2712

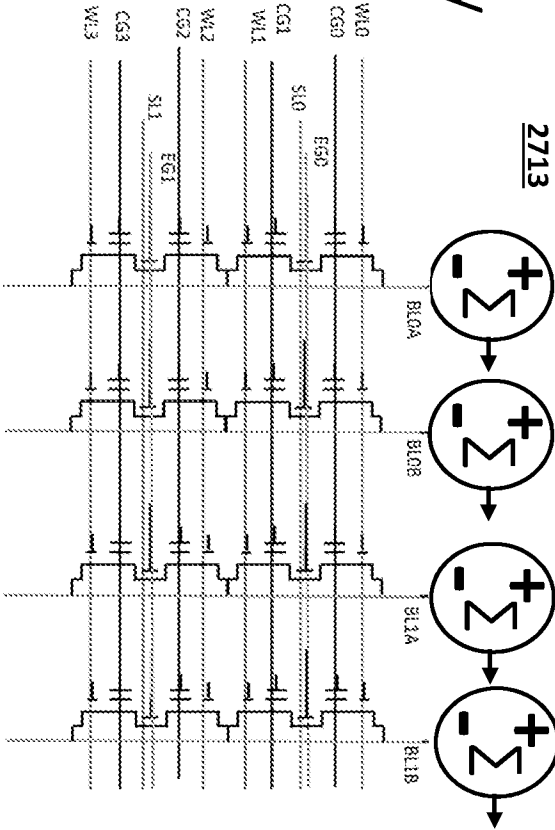


FIGURE 27C
positive input array
2751

negative input array
2752

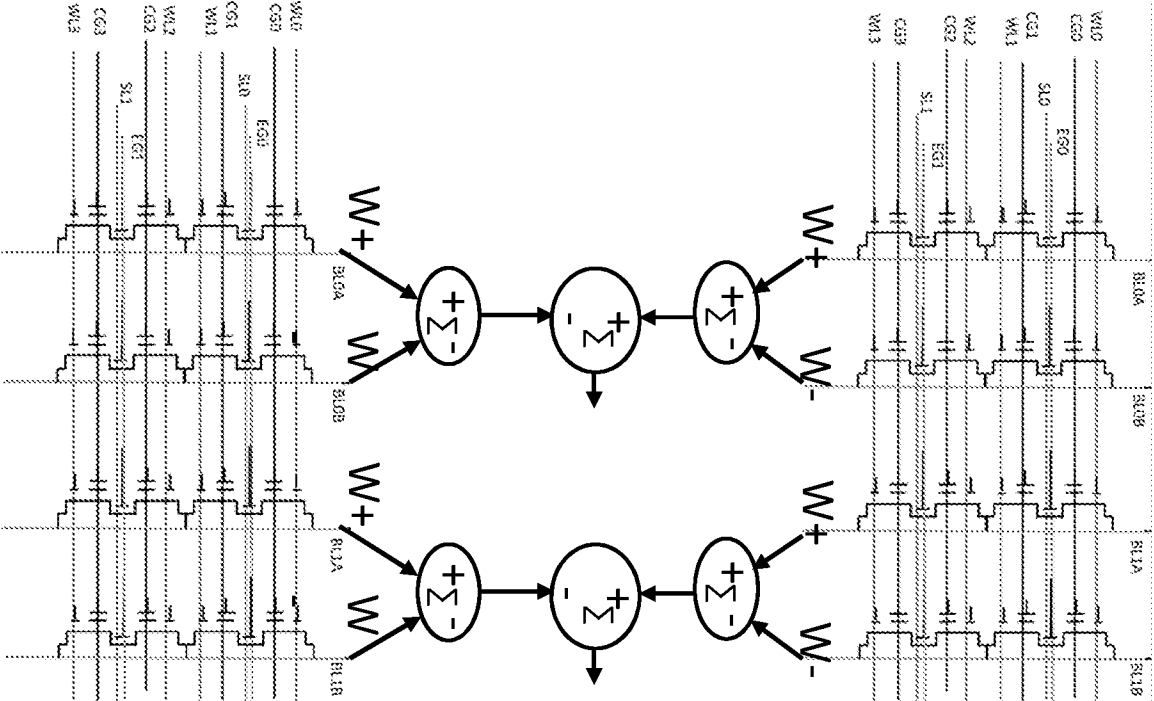
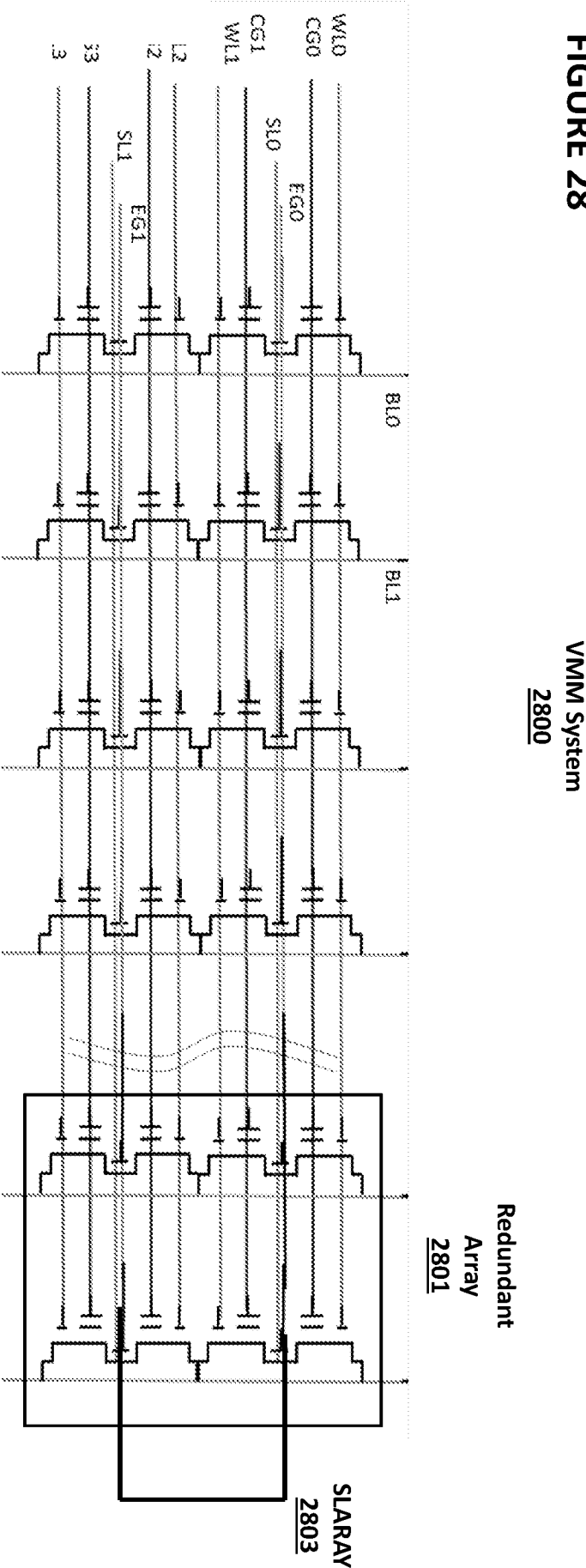


FIGURE 28



One or few SL for whole array, SLARY supplied
from external, e.g., 0v or 15mV

VMM System

2900



FIGURE 30

VMM System
3000

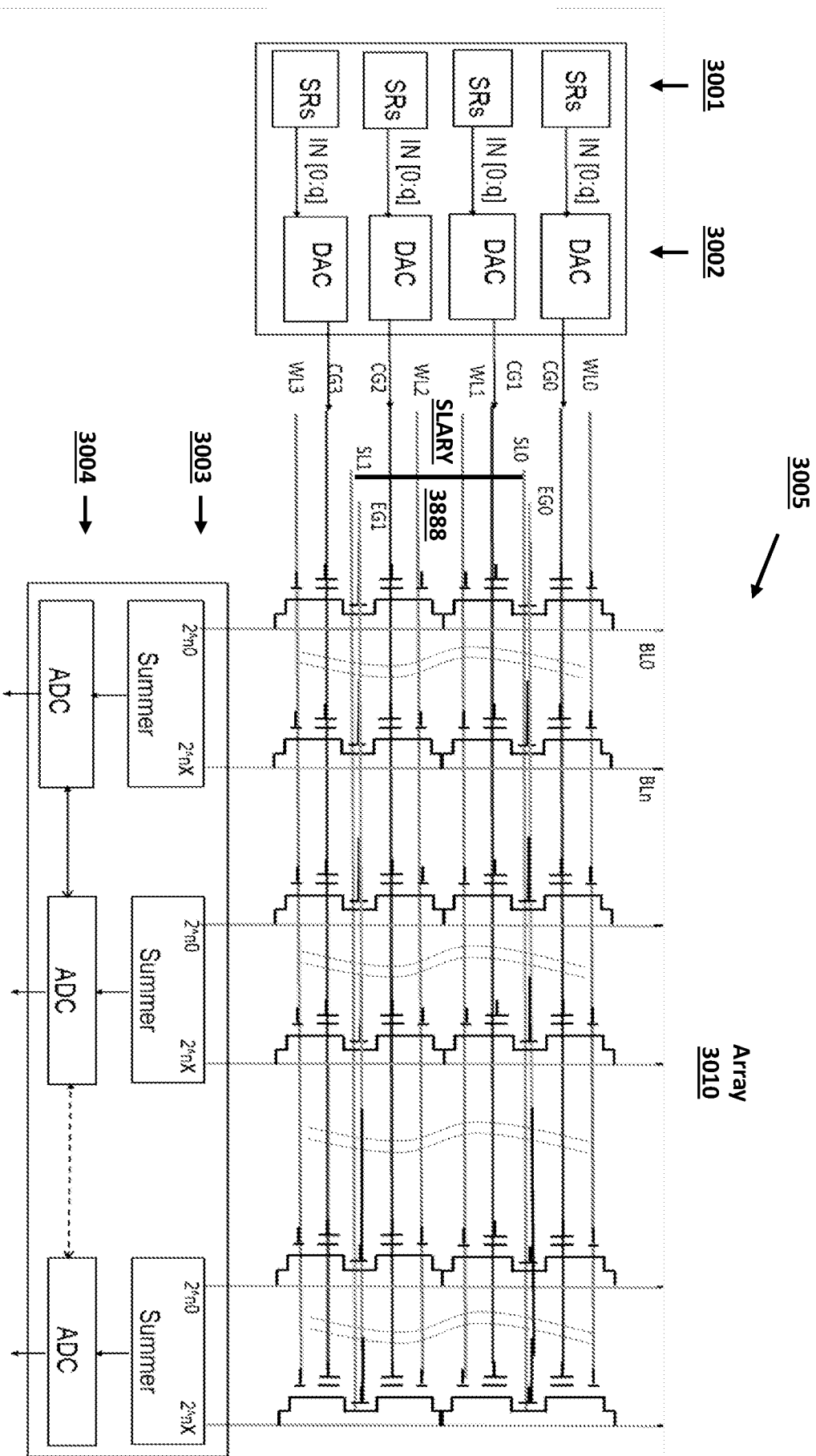


FIGURE 31

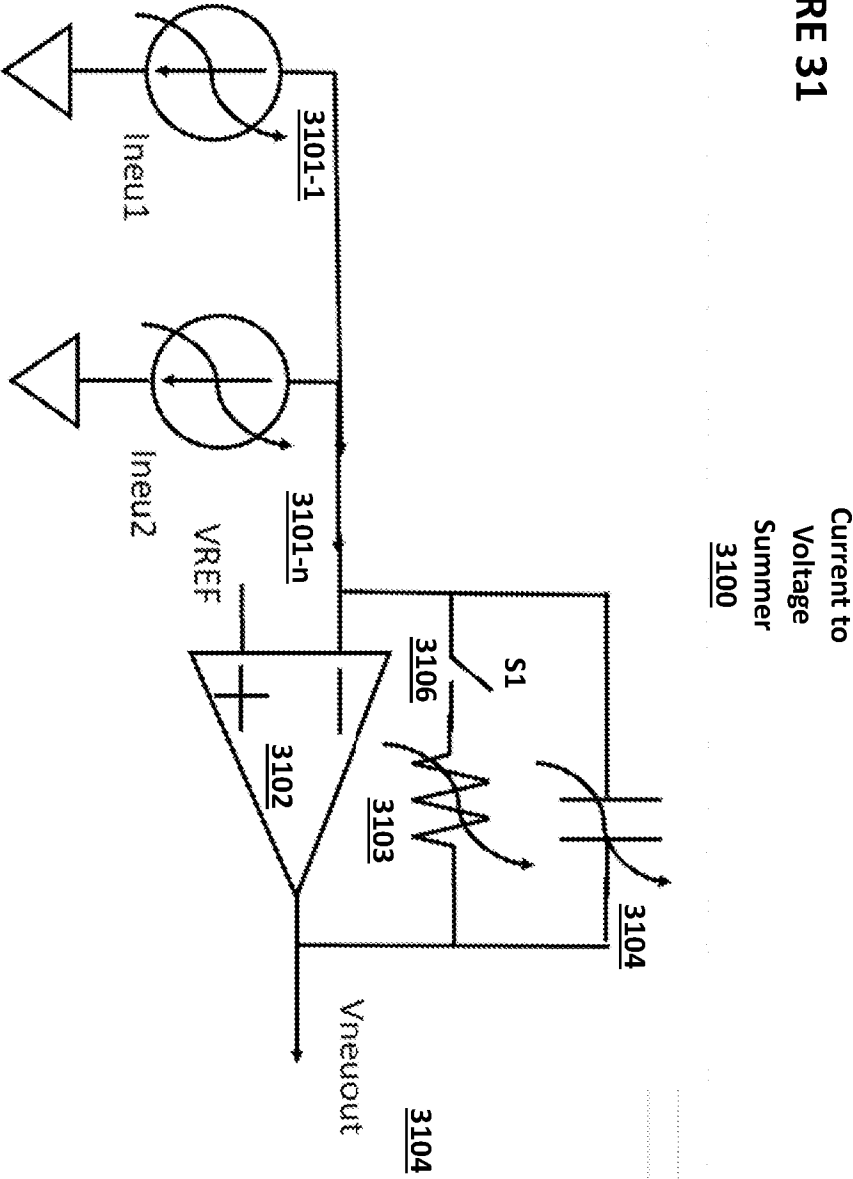


FIGURE 32

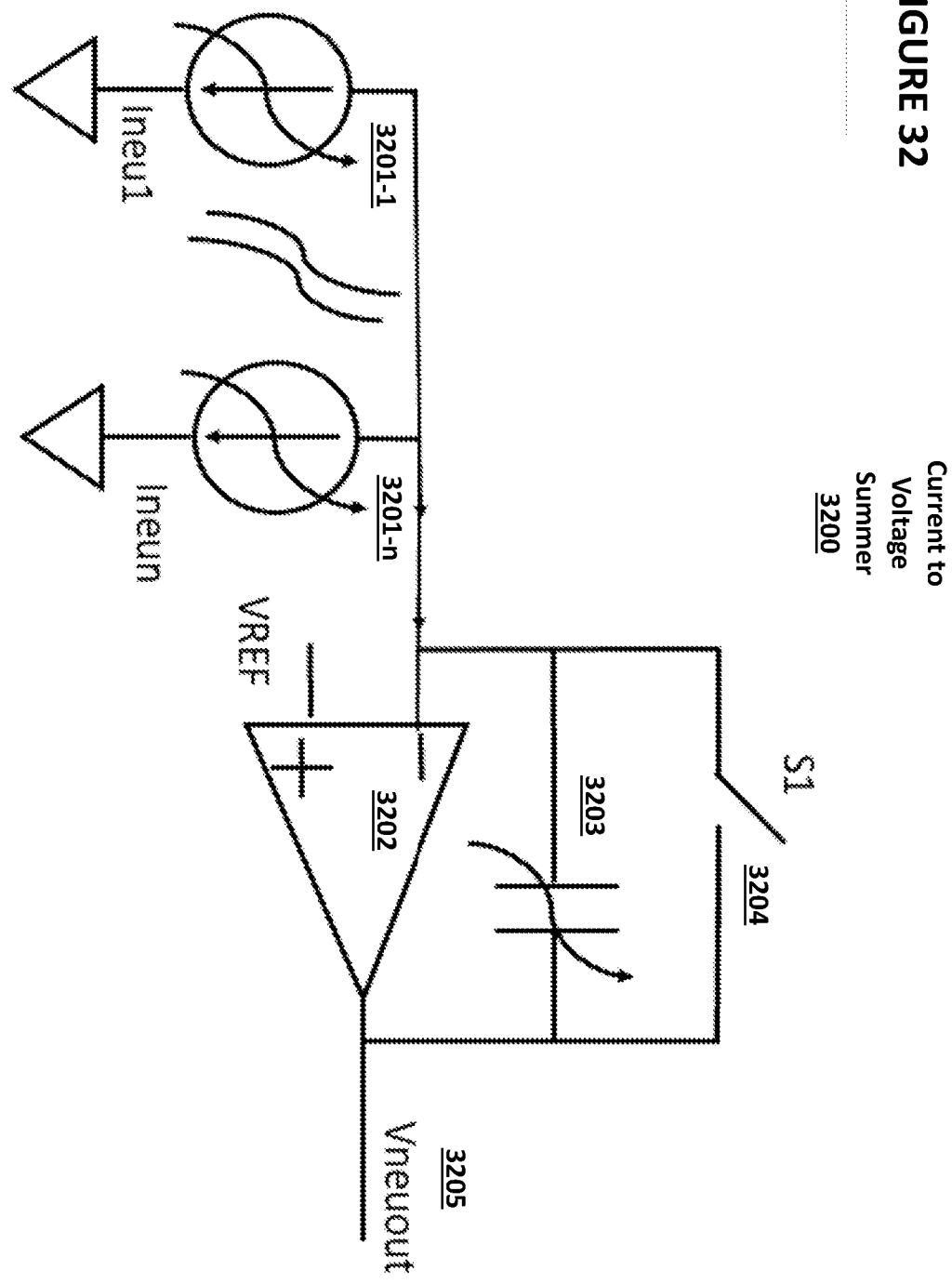


FIGURE 33A

Voltage
Summer
3300

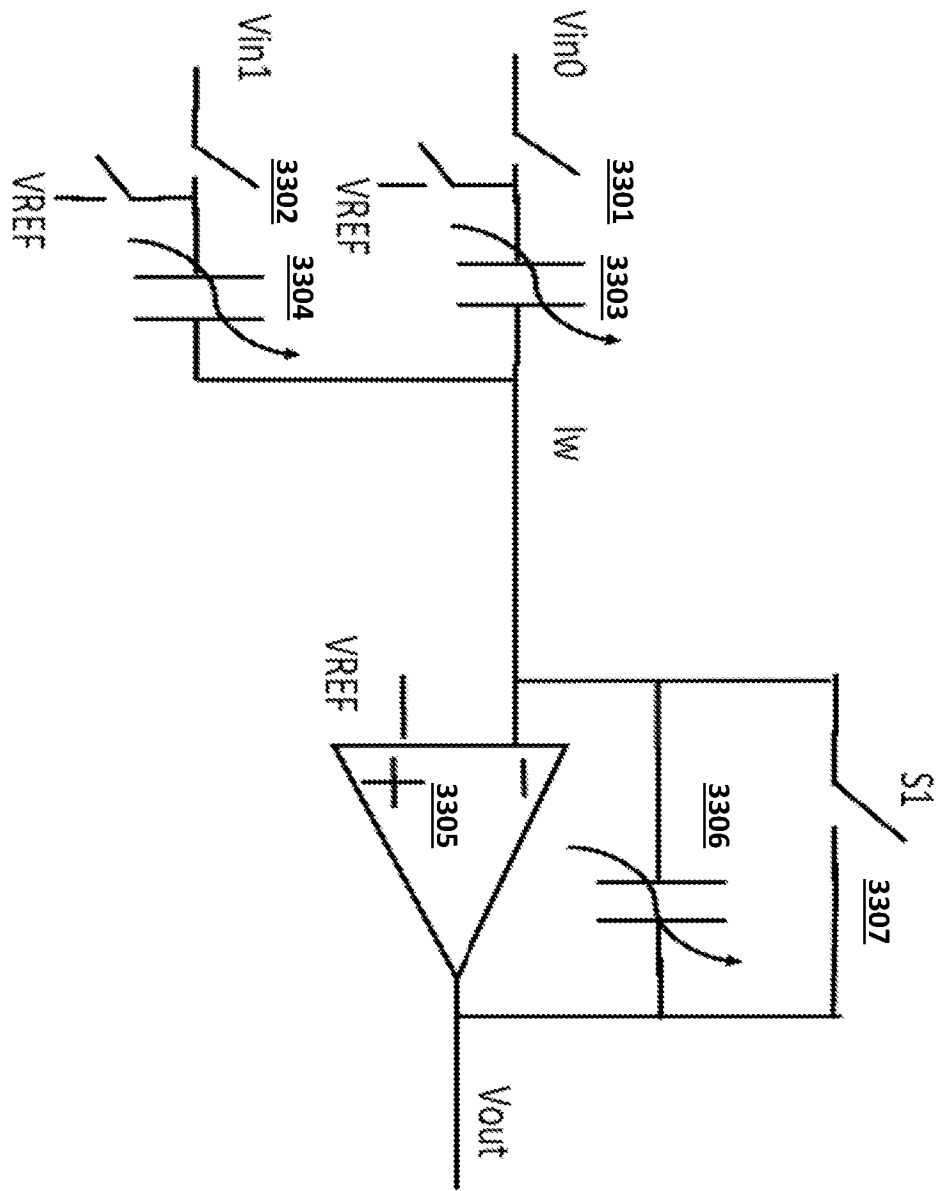


FIGURE 33B

Voltage
Summer
3350

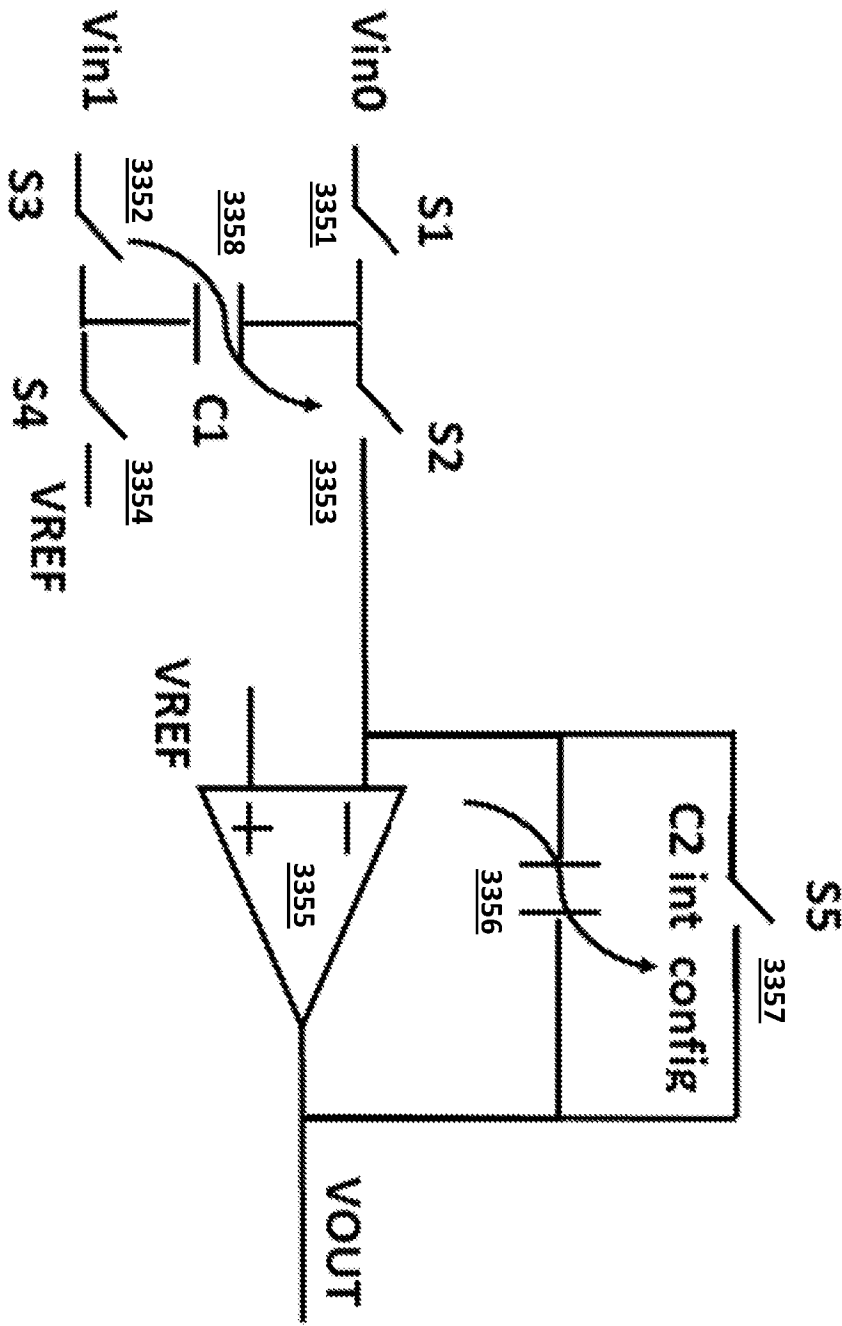


FIGURE 34A

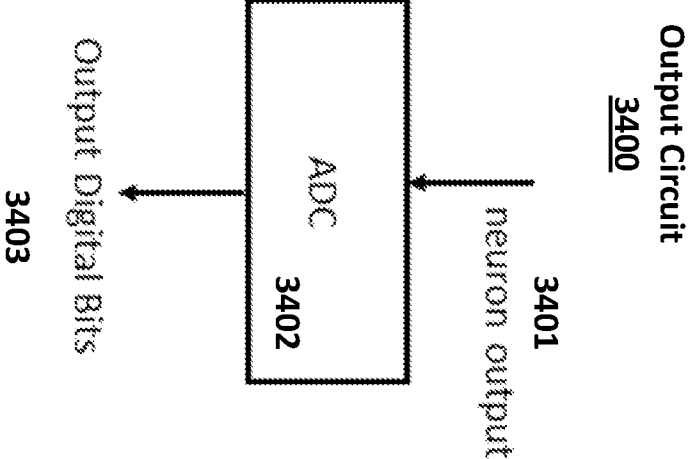


FIGURE 34B

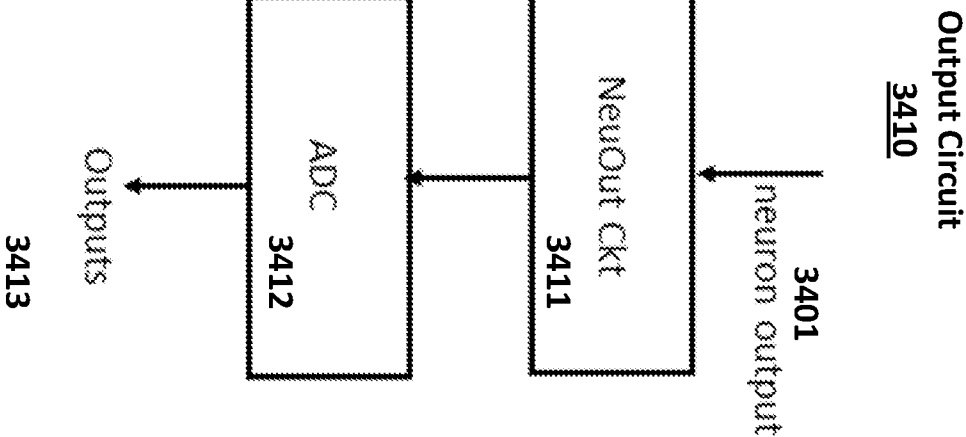


FIGURE 34C

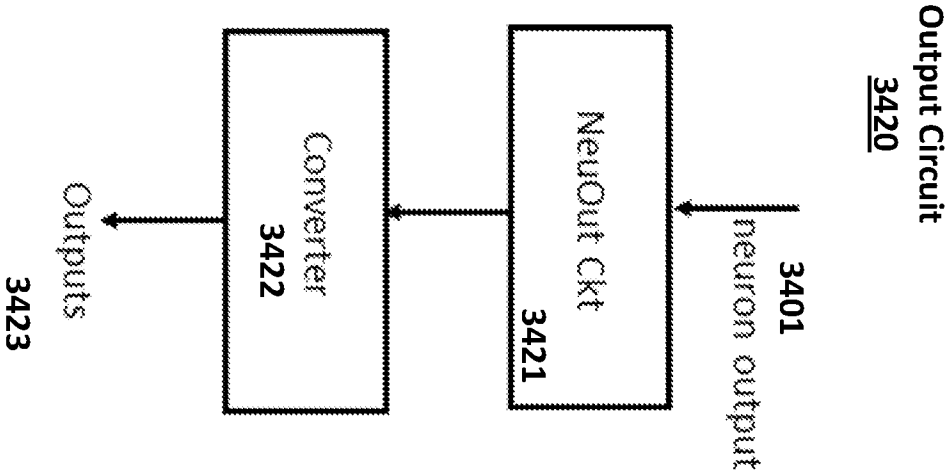


FIGURE 35

Neuron Output Circuit

3500

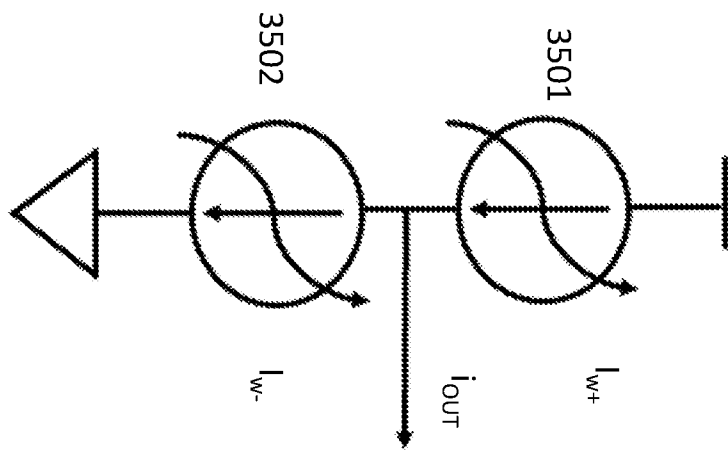


FIGURE 36

Serial ADC Circuit
3600

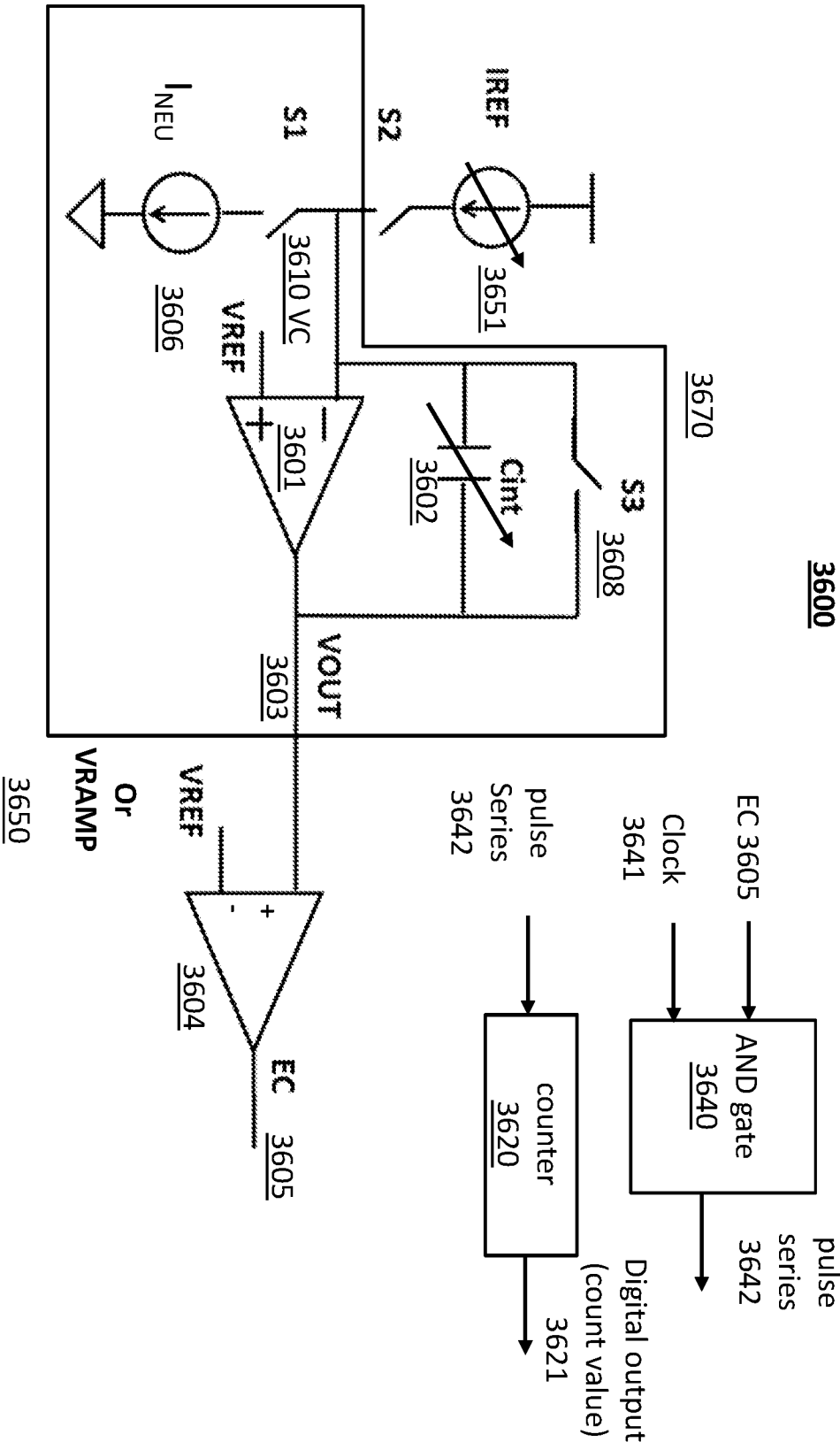


FIGURE 37

SAR ADC Circuit
3700

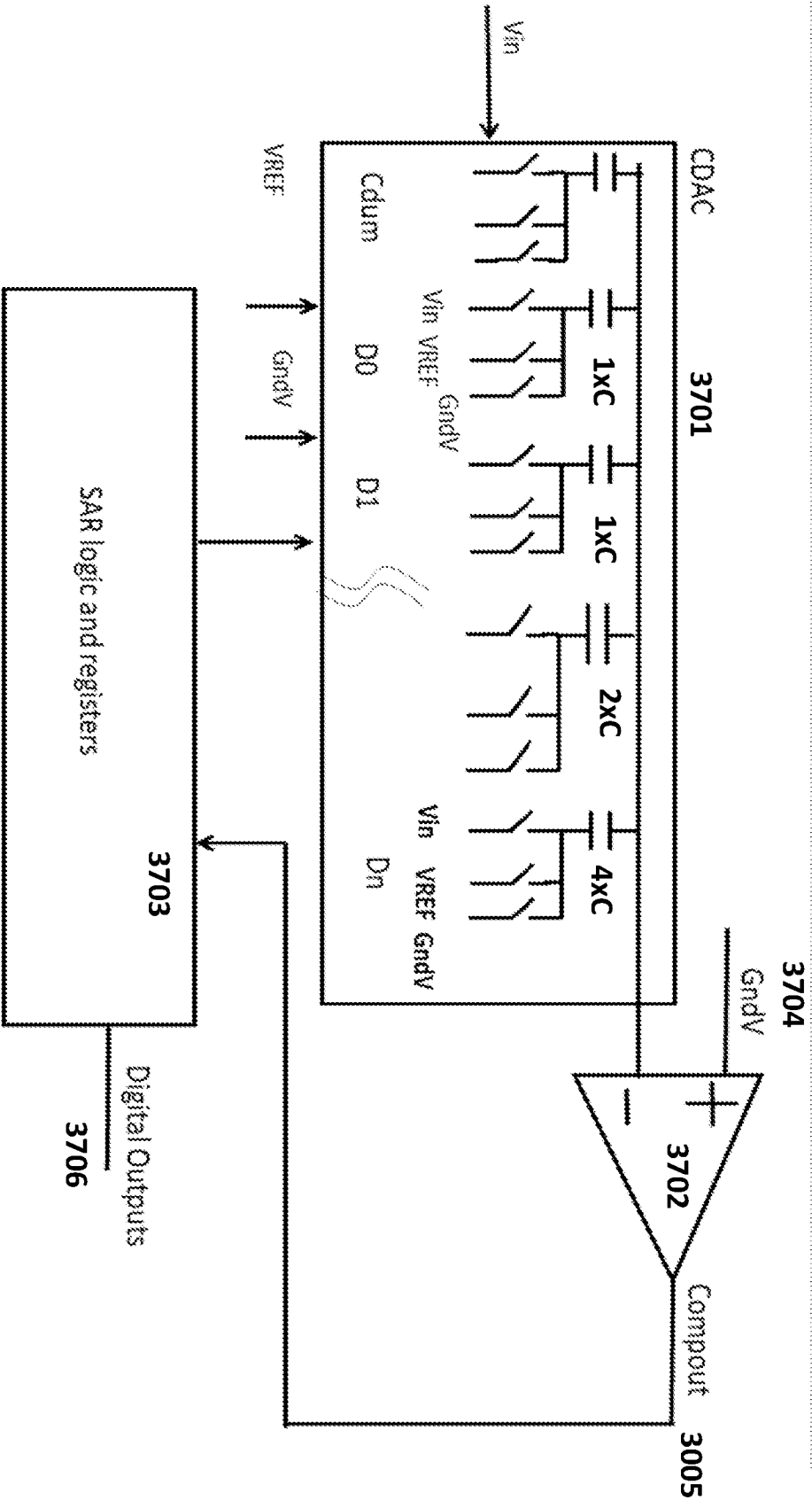


FIGURE 38
Combo SAR ADC Circuit
3800

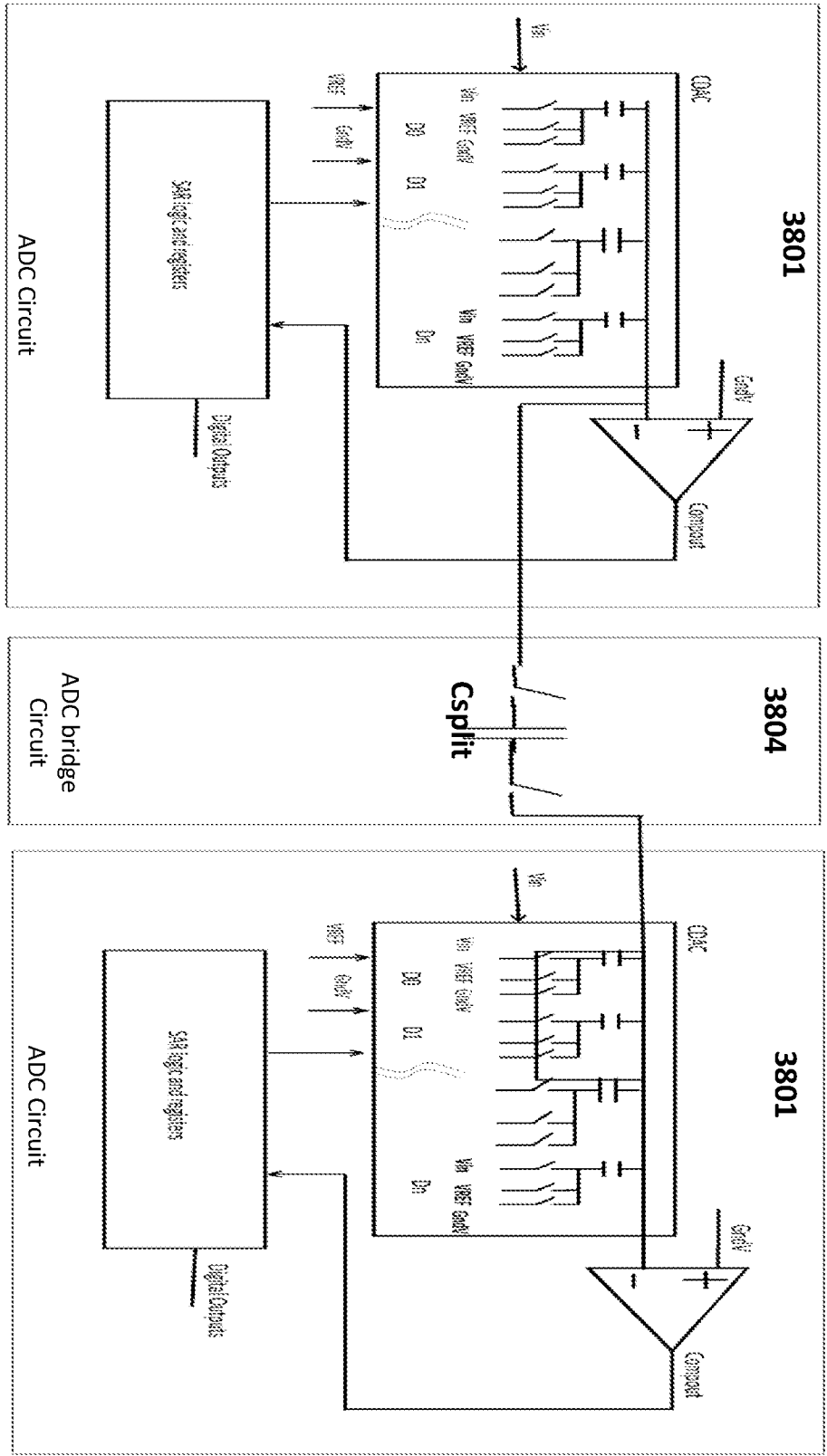


FIGURE 39

Pipelined SAR ADC Circuit
3900

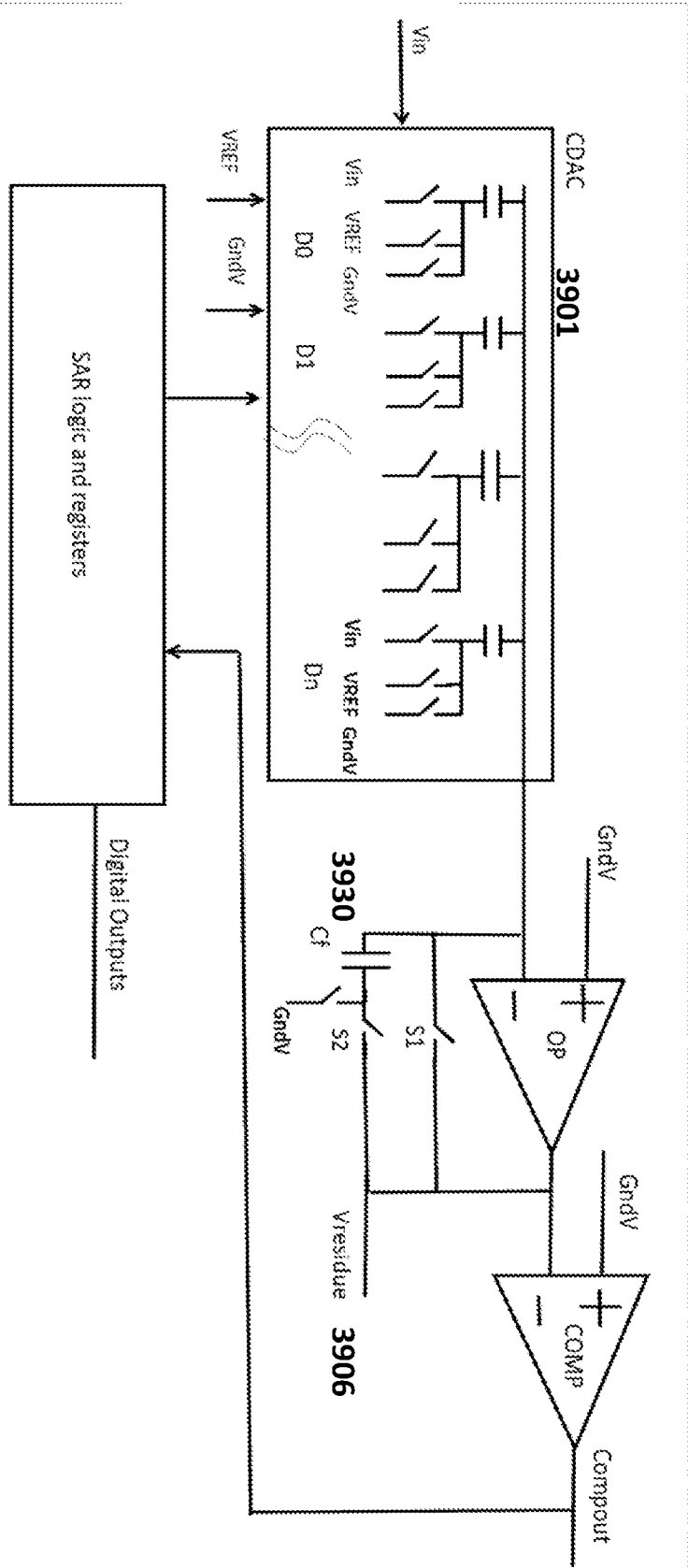


FIGURE 40

Desired Voltage Difference Between
Control Gate and Source Line
4000

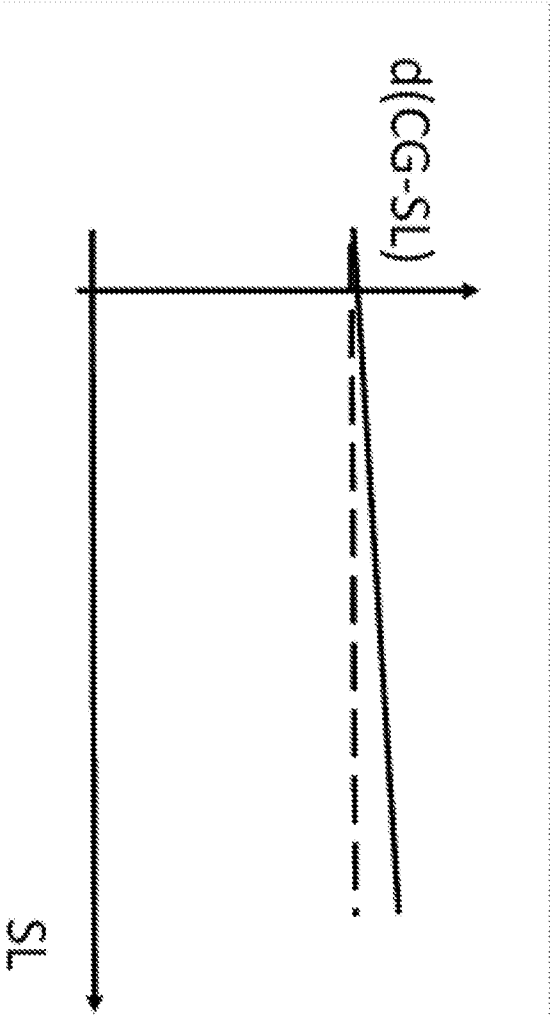


FIGURE 41

Desired Voltage Difference Between
Word Line and Source Line
4100

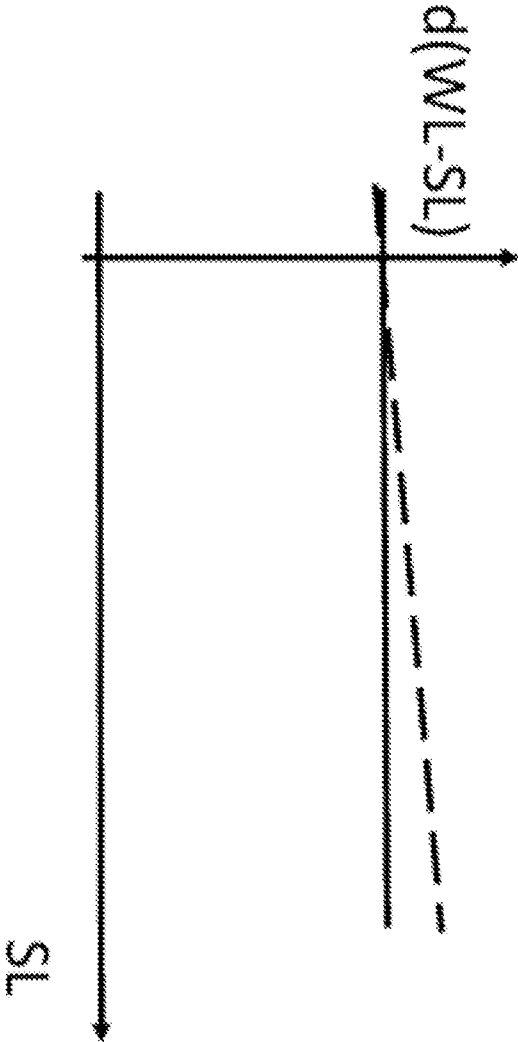


FIGURE 42

Desired Voltage Difference
Between Bit Line and Source Line
4200

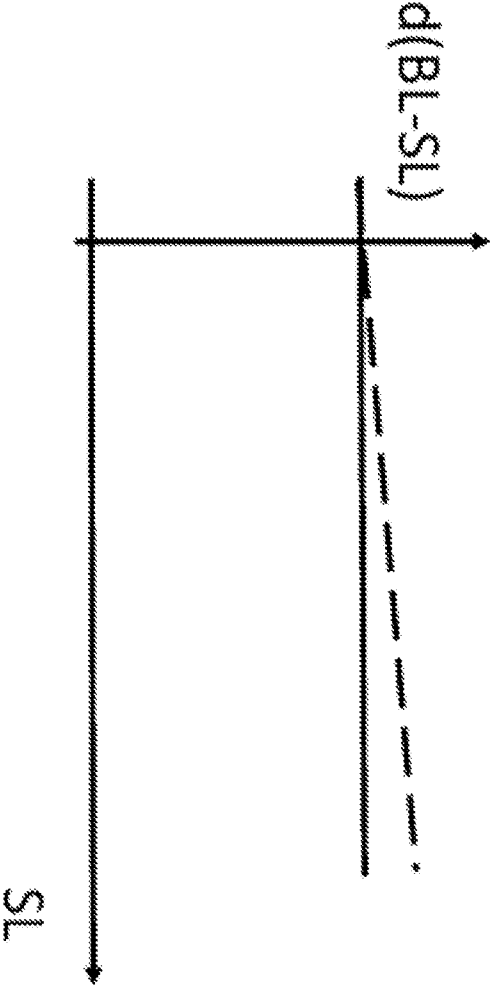


FIGURE 43

Change in Voltage v.
Temperature
4300

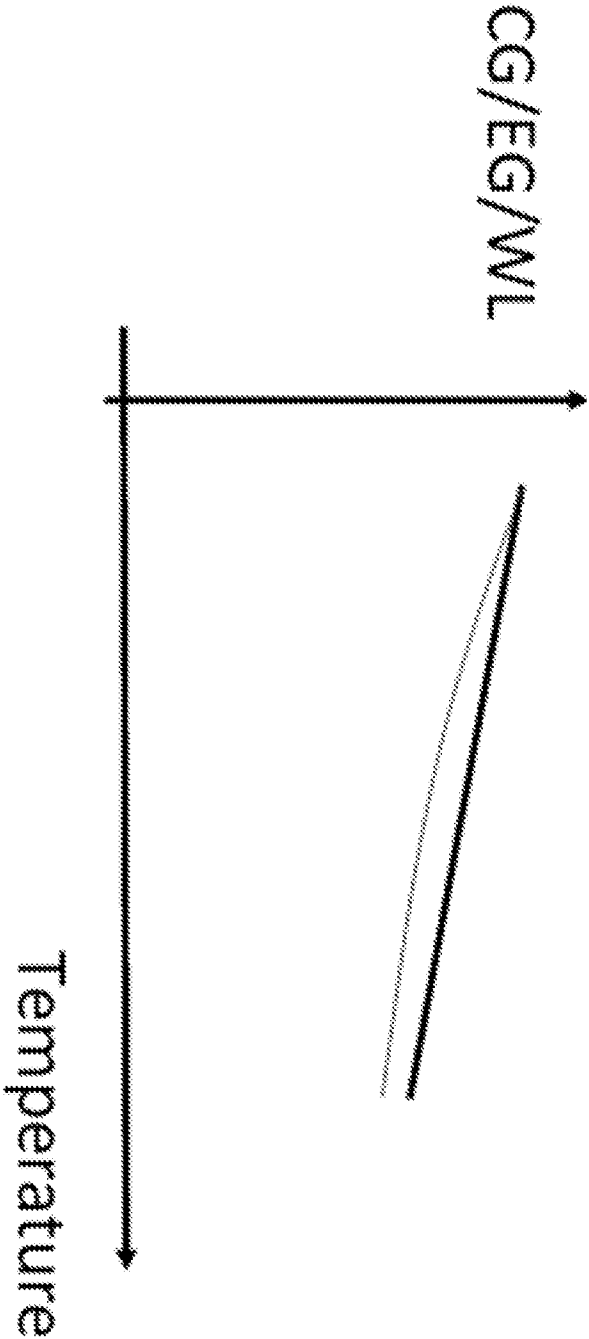


FIGURE 44A

4410

Adaptive Bias Circuit

4400

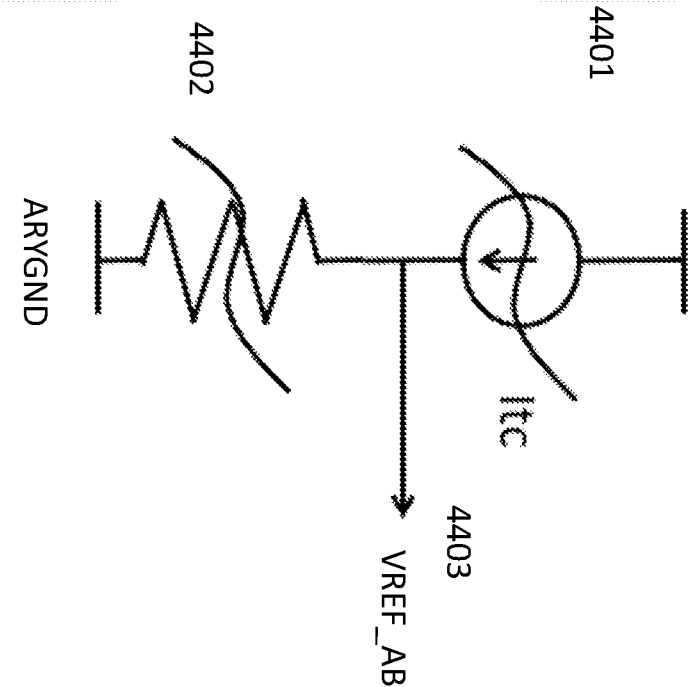


FIGURE 44B

4420

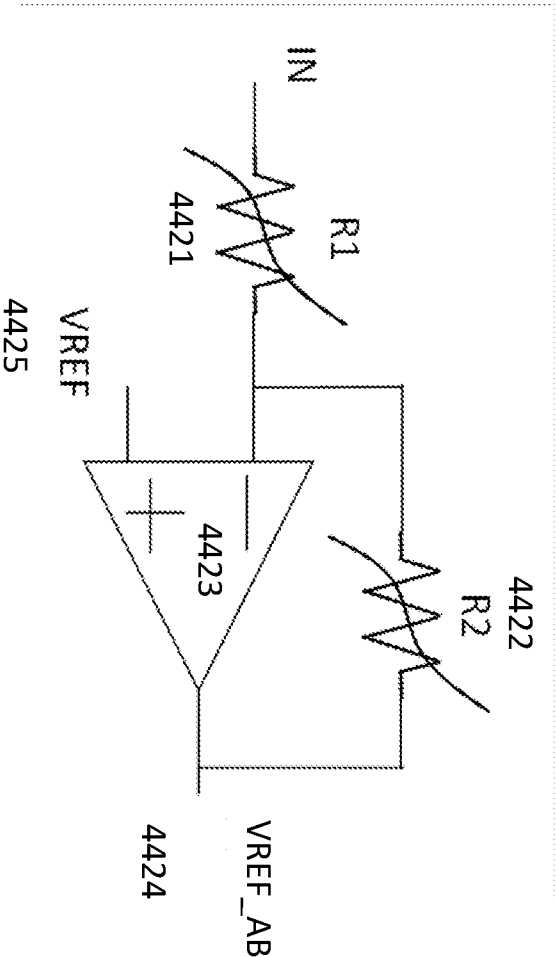
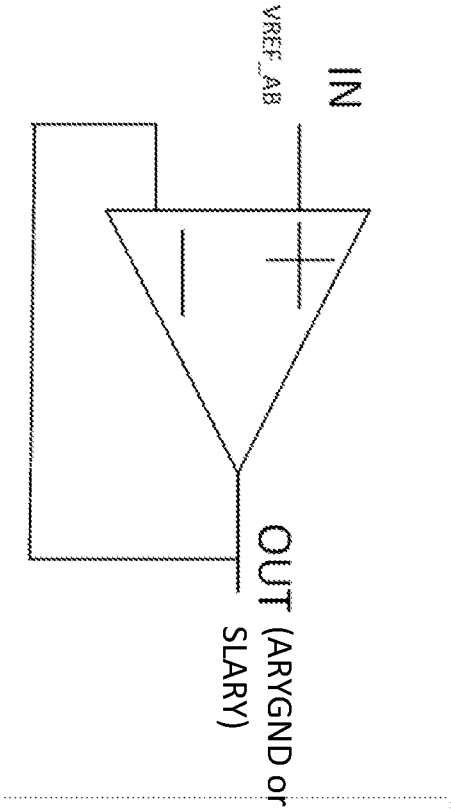


FIGURE 45A

4510



Regulator

4500

FIGURE 45B

4520

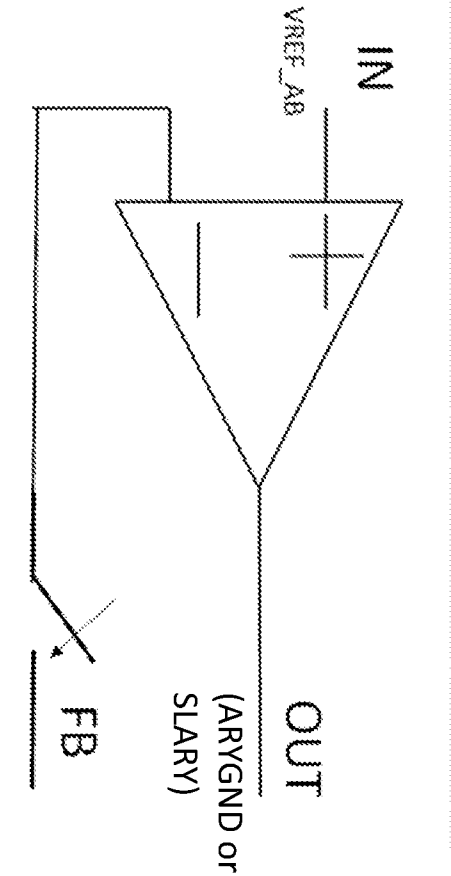


FIGURE 46A

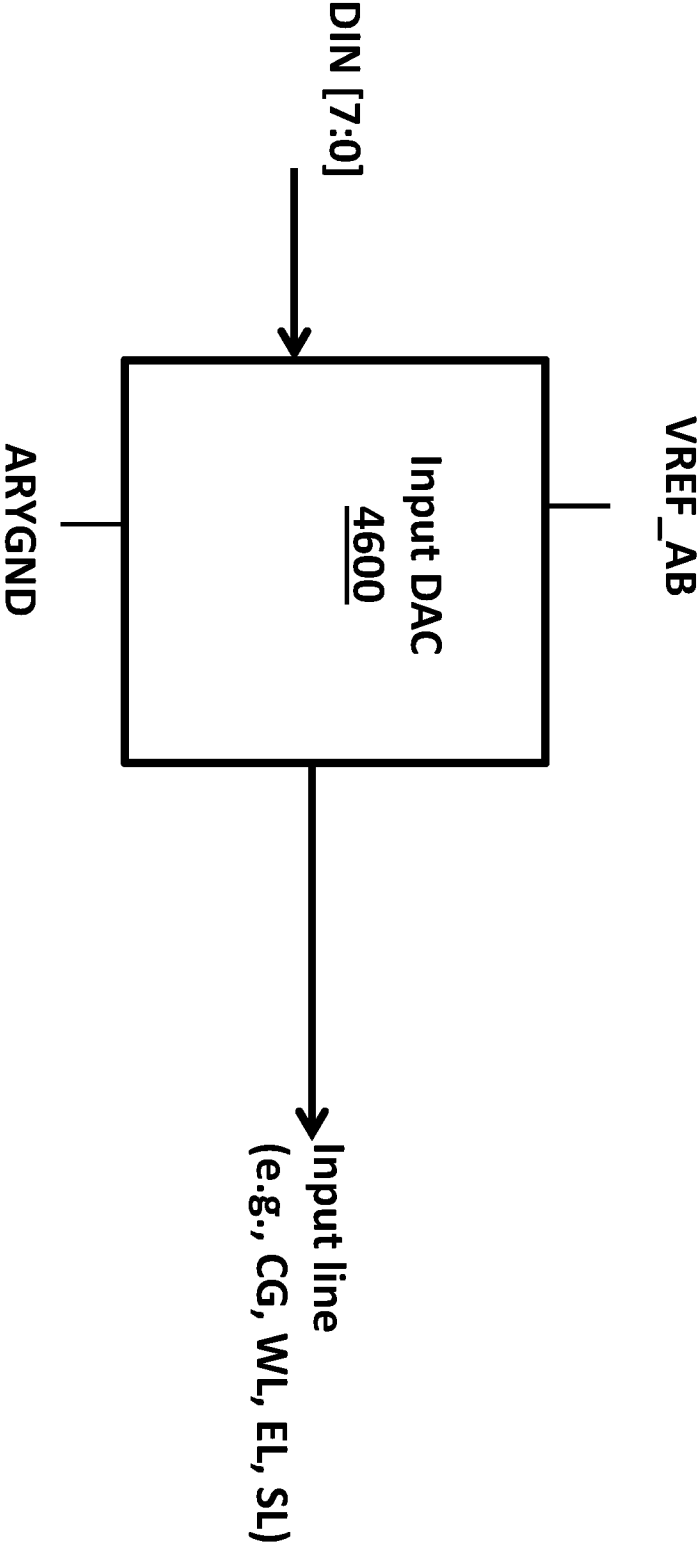


FIGURE 46B

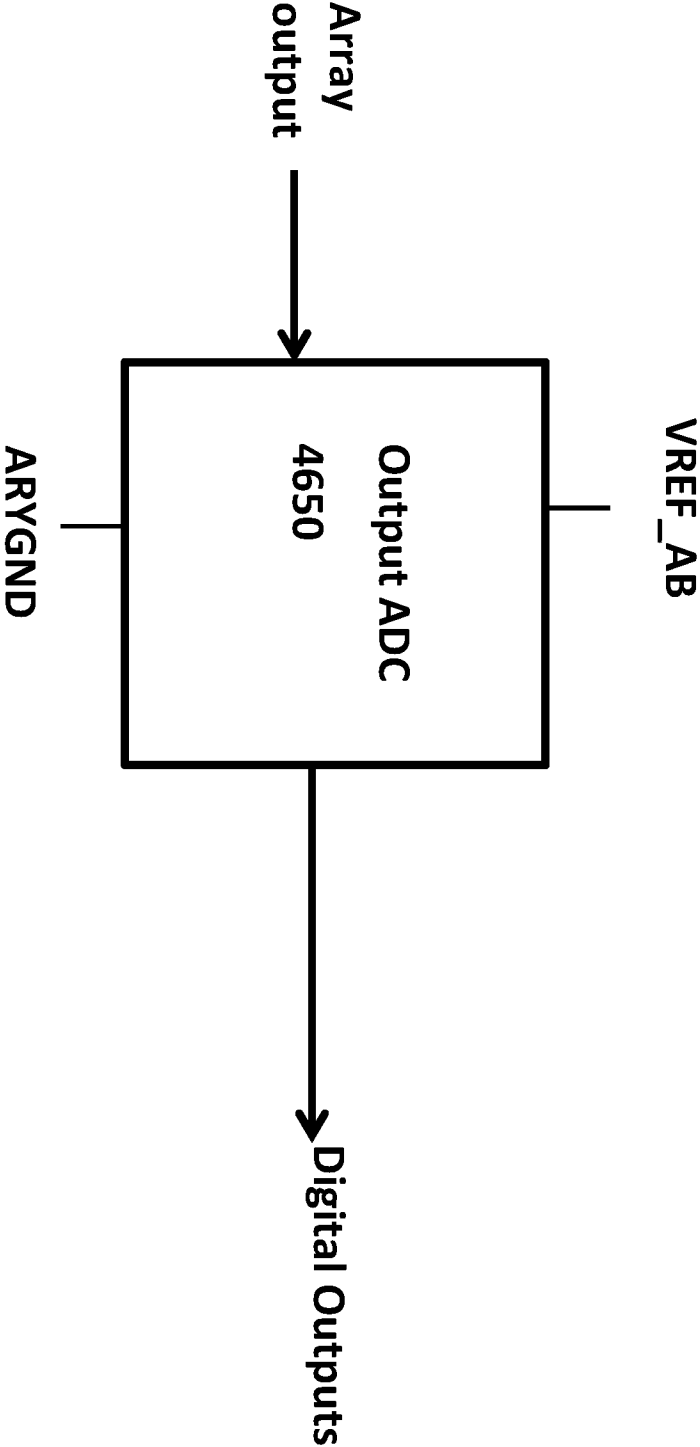


FIGURE 47

Adjustable Bias Row Decoder

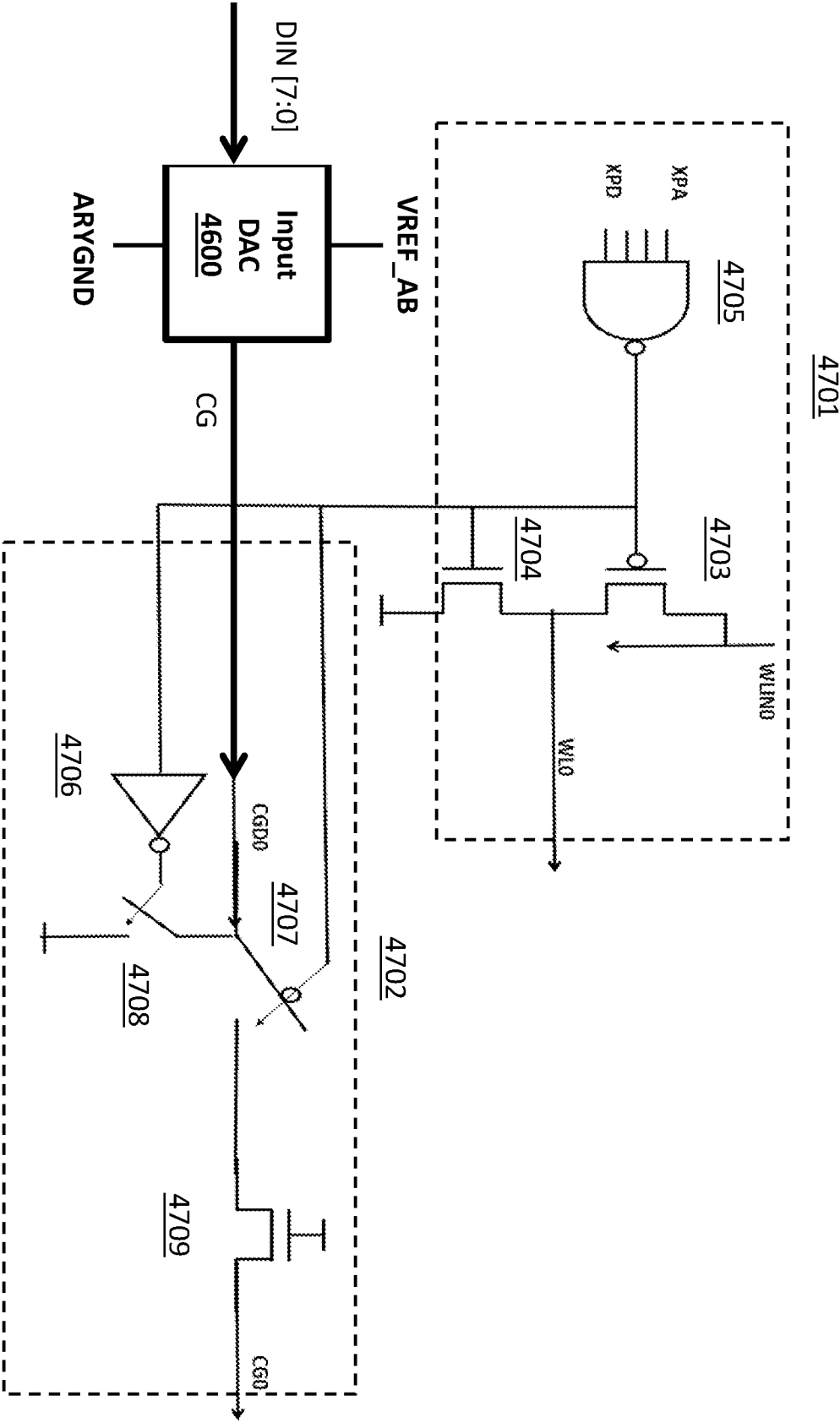


FIGURE 48

Current to
Voltage
Summer
4800

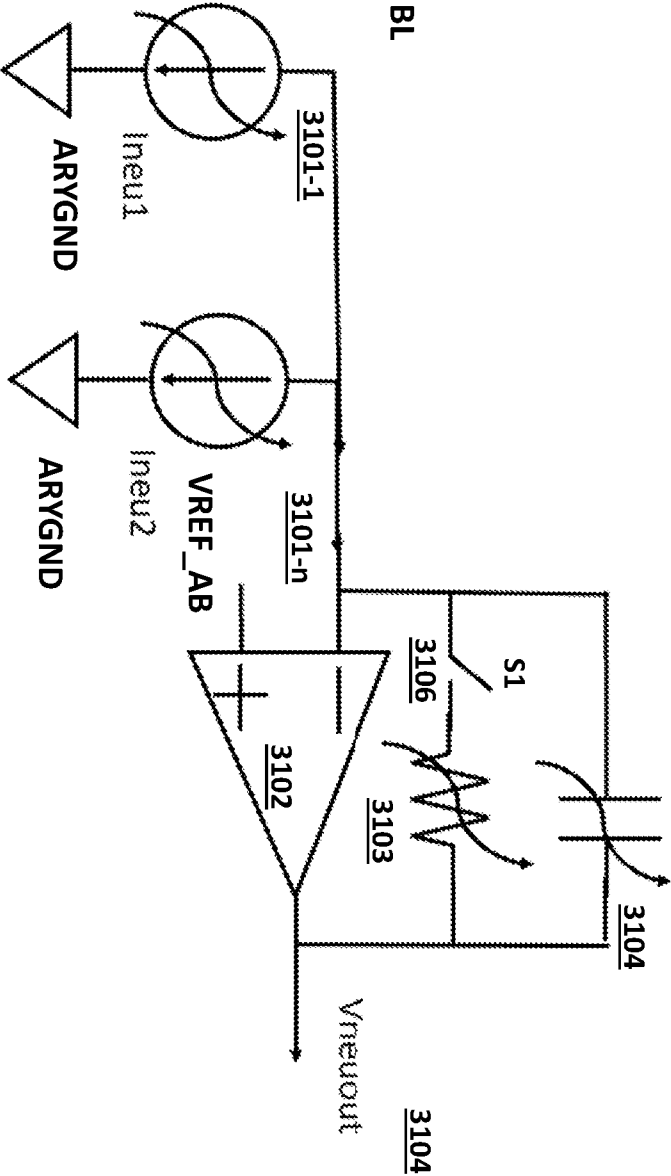


FIGURE 49

Current to Voltage Summer

4900

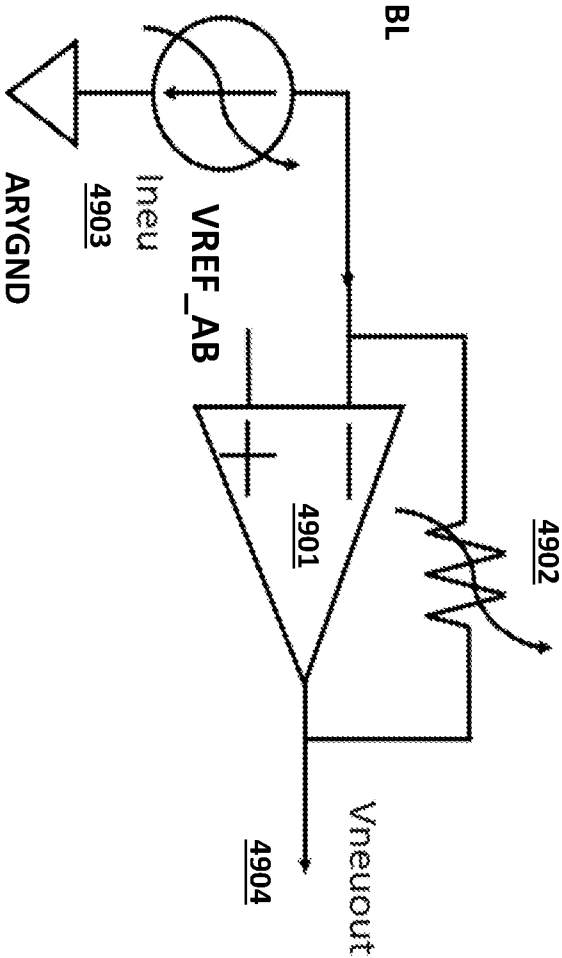


FIGURE 50

Current to Voltage
Summer
5000

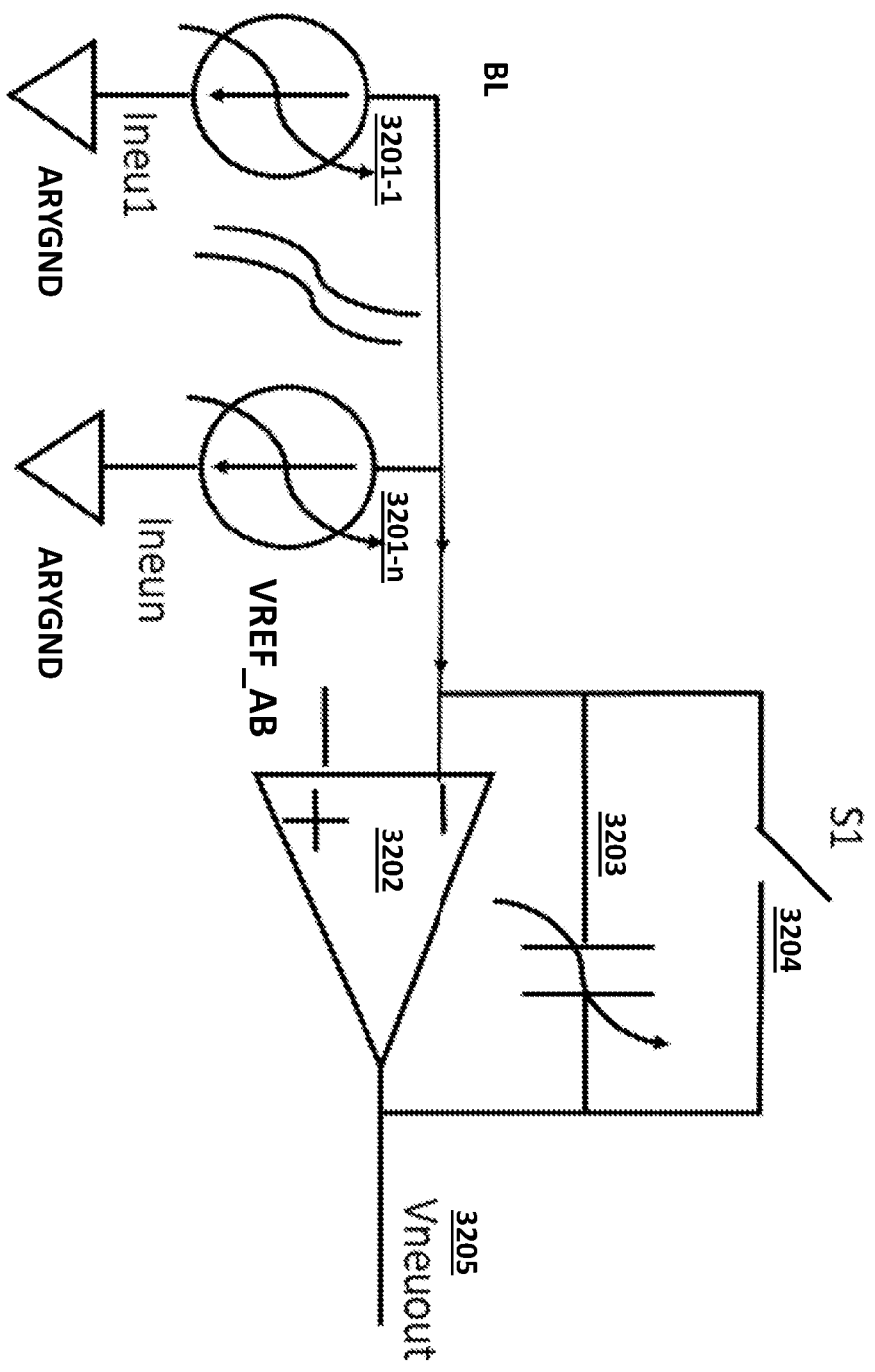


FIGURE 51

Voltage
Summer
5100

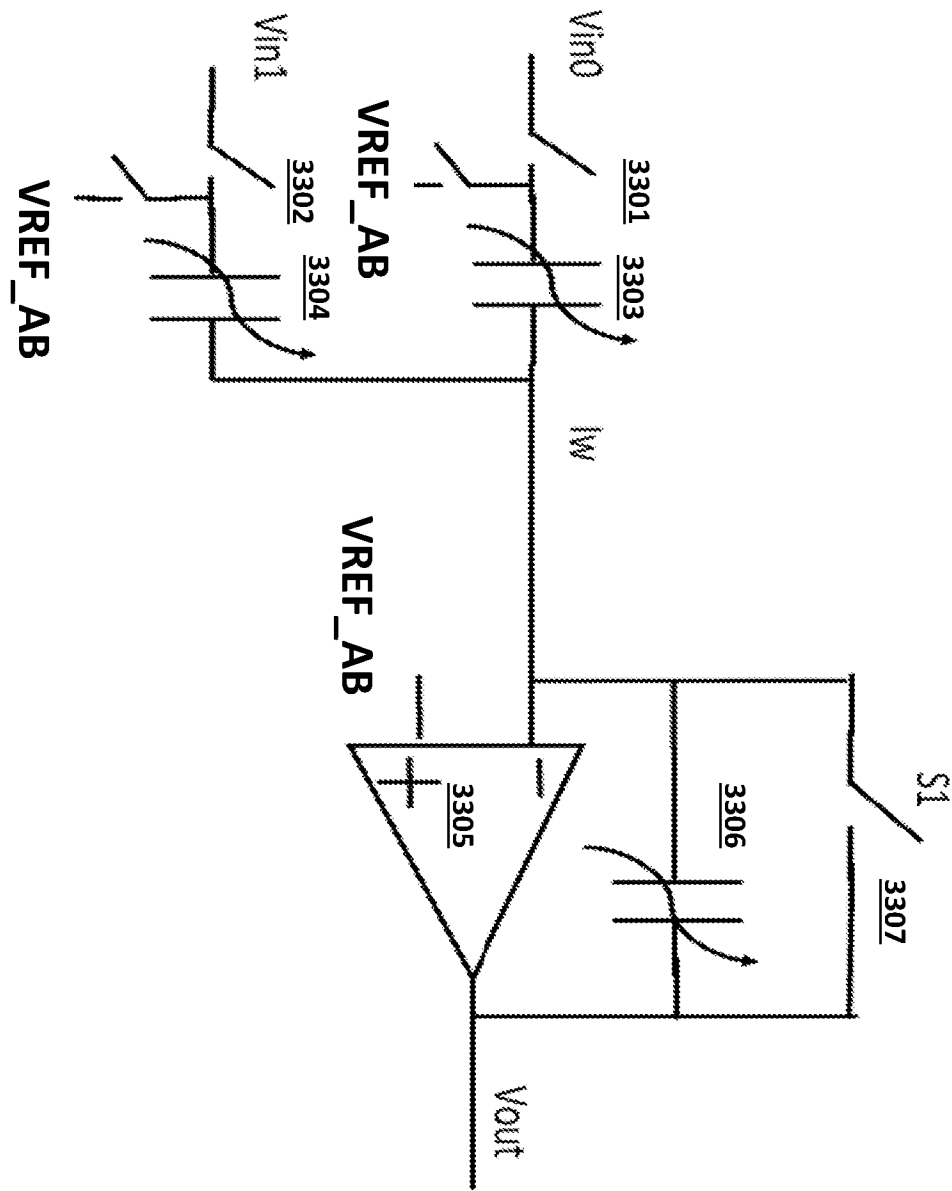


FIGURE 52

Voltage
Summer
5200

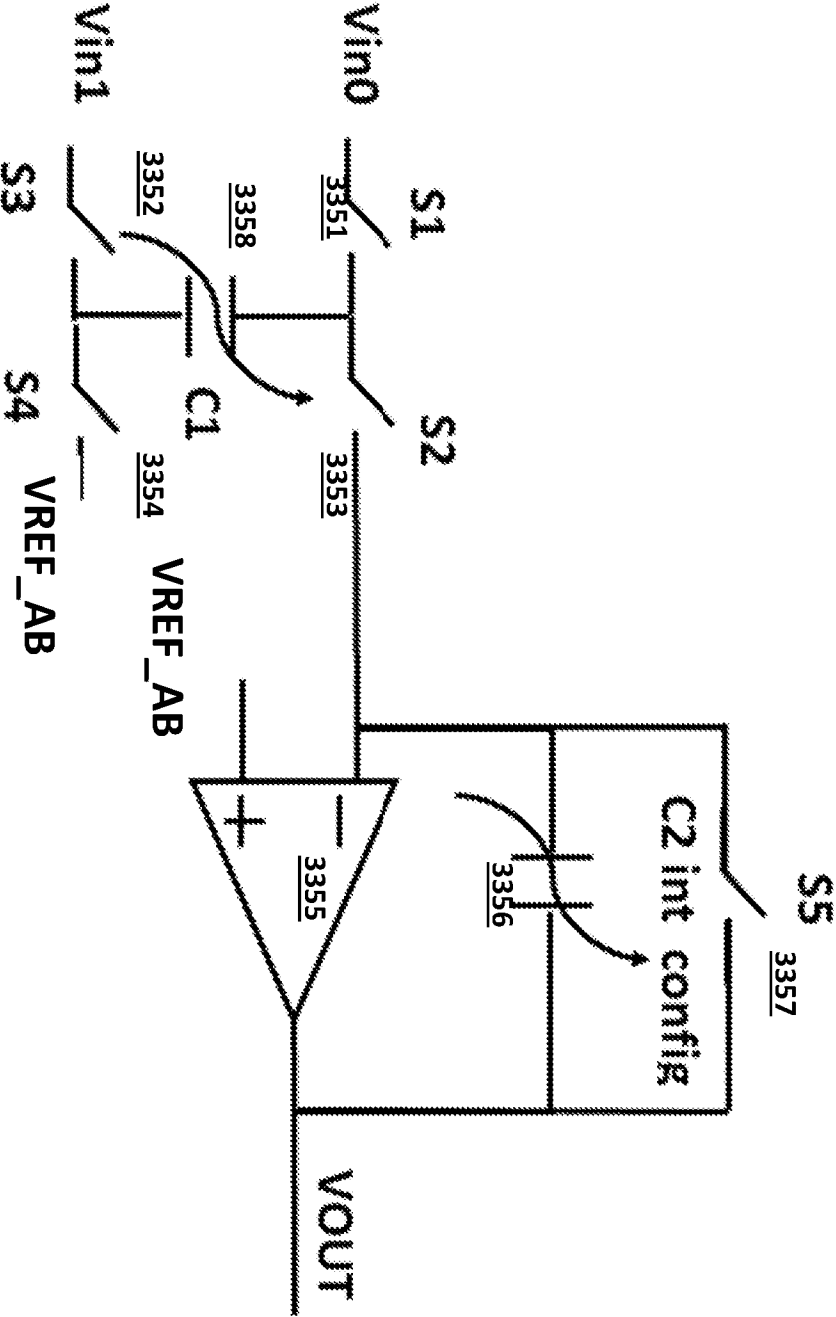
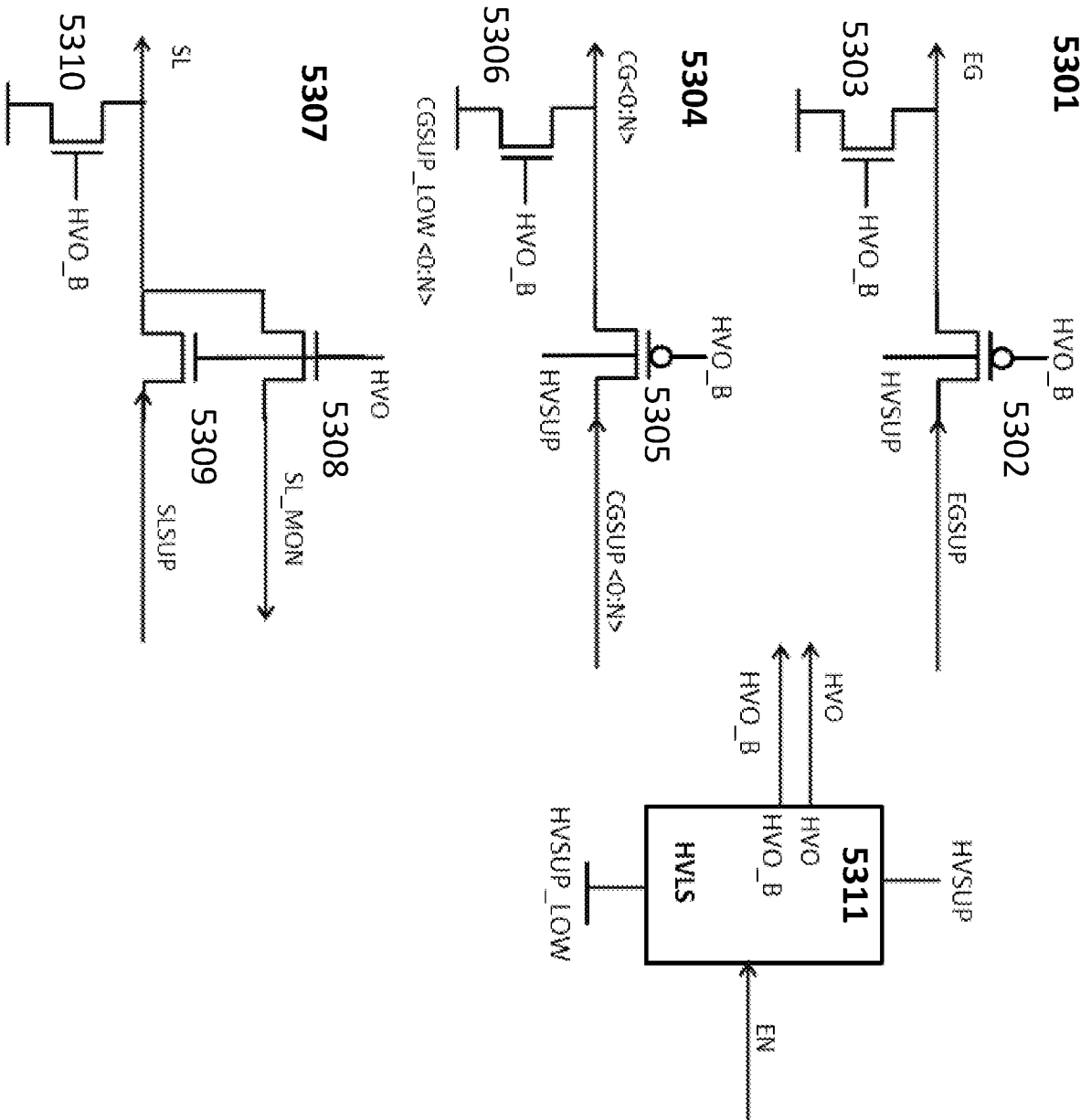


FIGURE 53



INTERNATIONAL SEARCH REPORT

International application No
PCT/US2021/012158

A. CLASSIFICATION OF SUBJECT MATTER INV. G11C16/04 G11C16/08 G11C16/24 G11C16/30 ADD.		
According to International Patent Classification (IPC) or to both national classification and IPC		
B. FIELDS SEARCHED		
Minimum documentation searched (classification system followed by classification symbols) G11C		
Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched		
Electronic data base consulted during the international search (name of data base and, where practicable, search terms used) EPO-Internal, INSPEC, WPI Data		
C. DOCUMENTS CONSIDERED TO BE RELEVANT		
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	EP 1 866 932 A1 (SANDISK CORP [US]) 19 December 2007 (2007-12-19) paragraph [0080] - paragraph [0107]; figures 9-12 -----	1-47
A	EP 3 291 238 A1 (SEMICONDUCTOR MFG INTERNATIONAL CORPORATION (SHANGHAI) [CN] ET AL.) 7 March 2018 (2018-03-07) paragraph [0041] - paragraph [0060]; figure 3 -----	1-47
☐ Further documents are listed in the continuation of Box C. ☒ See patent family annex.		
* Special categories of cited documents : "A" document defining the general state of the art which is not considered to be of particular relevance "E" earlier application or patent but published on or after the international filing date "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) "O" document referring to an oral disclosure, use, exhibition or other means "P" document published prior to the international filing date but later than the priority date claimed "T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention "X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art "&" document member of the same patent family		
Date of the actual completion of the international search 19 March 2021		Date of mailing of the international search report 29/03/2021
Name and mailing address of the ISA/ European Patent Office, P.B. 5818 Patentlaan 2 NL - 2280 HV Rijswijk Tel. (+31-70) 340-2040, Fax: (+31-70) 340-3016		Authorized officer Lecoutre, Renaud

INTERNATIONAL SEARCH REPORT

Information on patent family members

International application No

PCT/US2021/012158

Patent document cited in search report	Publication date	Patent family member(s)	Publication date
EP 1866932	A1	19-12-2007	AT 515773 T 15-07-2011
		CN 101176164 A 07-05-2008	
		EP 1866932 A1 19-12-2007	
		JP 2008535140 A 28-08-2008	
		KR 20080009073 A 24-01-2008	
		TW 200707442 A 16-02-2007	
		US 2006221693 A1 05-10-2006	
		US 2007115721 A1 24-05-2007	
		WO 2006107706 A1 12-10-2006	

EP 3291238	A1	07-03-2018	CN 107799146 A 13-03-2018
		EP 3291238 A1 07-03-2018	
		US 2018061502 A1 01-03-2018	
